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### **REVIEW**

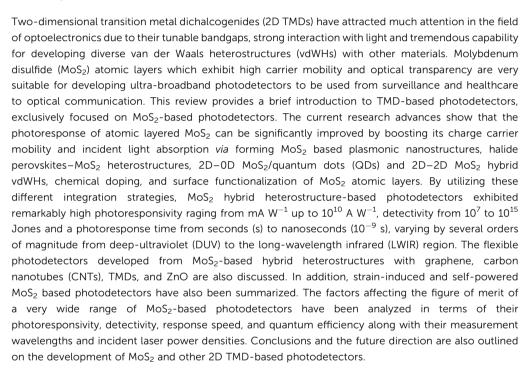
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## A review of molybdenum disulfide (MoS<sub>2</sub>) based photodetectors: from ultra-broadband, selfpowered to flexible devices

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Dr Hari Singh Nalwa is a distinguished independent scientist and scholar working in the fields of nanotechnology and materials science. Dr Nalwa has authored more than 170 scientific articles, 26 book chapters, and 125 volumes of scientific books, as well as 18 patents in cross-disciplinary research areas of nanotechnology, materials science and polymer science. Dr Nalwa's research interests include ferroelectric polymers, conducting polymers, organic nonlinear optical materials for integrated optics, low- and high-dielectric constant materials for microelectronics packaging, 3D printing, two-dimensional (2D) nanomaterial-based bulk heterojunction and dye-sensitized solar cells, and multifunctional sensors for wearable technology. He received the "Award of Excellence" from the Association of American Publishers for the "Handbook of Nanostructured Materials and Nanotechnology," a 5-volume set (Academic Press, 2000), and "Best Reference Work Award" from the American Society for Engineering Education for "The Encyclopedia of Nanoscience and Nanotechnology," a 10-volume set (American Scientific Publishers, 2004). He is Founder, President, and Chief Executive Officer (CEO) of American Scientific Publishers (http://www.aspbs.com), which he established in 2000.

#### Introduction

Advances in the fields of electronics, optoelectronics and photonics have created a great demand for new functional materials that possess ease of synthesis, processing and fabrication and enable desired tailoring of the physical and chemical properties by chemical functionalization and/or formation of hybrid structures for potential applications in electronic and optoelectronic devices. 1,2 In this context, earth-abundant two-dimensional (2D) nanomaterials, including graphene3-12 and transition metal dichalcogenides (TMDs),13-20 have emerged as novel functional materials of choice due to their low-cost production, easy processing and easy deposition on different substrates with precise thickness control of the atomic layers via mechanical and chemical exfoliation, chemical vapor deposition (CVD) and atomic layer etching (ALE) methods. Flexible graphene nanosheets have been explored for developing wearable and portable devices, including field-effect transistors (FETs), 21,22 sensors, 23-25 supercapacitors, 26-28 lithium-ion batteries,29 triboelectric nanogenerators,30 solar cells31-33 and photodetectors.34,35 Following the research progress of graphene, a similar wide range of applications for flexible atomic layered TMDs have been anticipated and are now slowly emerging, from wearable electronics to optoelectronics.<sup>36-40</sup> Flexible photodetectors are becoming a key component of optoelectronic technology for a wide range of applications in the fields of surveillance, soft robotics, sensors for wearable and portable healthcare and sports, light-emitting diodes (LEDs), high-speed optical communication, and biomedical imaging.34,35,41 Flexible photodetectors are gaining much attention for use in wearable optoelectronics, for which many different types of nanostructures, such as atomic layered nanosheets, nanowires (NWs), fibers, quantum dots and 3D networks of inorganic and organic materials and their nanohybrids, have been studied. These nanostructures have been used as phototransistors, photoconductors and photodiodes for developing photodetectors from a wide variety of nanomaterials, including silicon (Si) and germanium (Ge), 42,43 selenium (Se),44 GaP and InP, 45,46 CdS, 47,48 ZnSe, 49 ZnO and its hybrids with PbS, ZnS, CdO, gold (Au) and polymers, 50-55 ZnGa<sub>2</sub>O<sub>4</sub>, 56 Zn<sub>2</sub>GeO<sub>4</sub> and  ${\rm In_2Ge_2O_7,^{57}~CuInSe_2,^{58,59}~In_2S_3,^{60}~In_2Se_3,^{61}~Sb_2S_3,^{62}~Sb_2Se_3,^{63}~Bi_2S_3,^{64}}$ SnS, 65 SnS<sub>2</sub>, 66 ZrS<sub>3</sub>, 67 Zn<sub>3</sub>P<sub>2</sub>, 68 PbI<sub>2</sub>, 69 MoO<sub>3</sub>, 70 GaS, 71 SnO<sub>2</sub>, 72 ZnTe, 73 GaTe,74 perovskites,75,76 their hybrid composites with ZnO, gold, poly(diketopyrrolopyrrole-terthiophene) (PDPP3T) conjugated polymer, and graphene,77-80 polythiophene,81 carbon nanotubes (CNTs),82 graphene nanocomposites with CNTs83 and with ZnO quantum dots,84 transition-metal trichalcogenides (MX3, where M represents a transition metal, Ti, Zr, Hf, Nb, or Ta, and X is a chalcogen, S, Se, or Te), e.g., hafnium trisulfide (HfS<sub>3</sub>), 85 HfS<sub>3</sub> and HfSe<sub>3</sub> nanocomposites with graphene, 86 and graphene-based materials.87-89 The important parameters including photoresponsivity, specific detectivity, noise equivalent power (NEP), photogain, external quantum efficiency (EQE), linear dynamic range (LDR), and response speed of photodetectors have already been well defined in the literature; here, these parameters are discussed in reference to the nanomaterial-based photodetectors and especially for the MoS2 atomic layer-based hybrid photodetectors.

Many research articles have been published on atomically thin layered MoS<sub>2</sub> based photodetectors, however, a comprehensive review summarizing the recent developments in MoS2 photodetectors is completely lacking in the scientific literature. This review briefly introduces TMDs, including the applications of MoS<sub>2</sub> atomic layers in developing photodetectors. The tuning of optoelectronic properties by boosting the carrier mobility of and incident light absorption by MoS2 atomic layers through the use of plasmonic and halide perovskite-MoS2 hybrid heterostructures, 2D-0D and 2D-2D MoS<sub>2</sub> heterostructures, interface coupling effect (ICE), or chemical doping of MoS2 films is discussed in order to evaluate the performance of MoS2 photodetectors from the perspective of their based phototransistors, photoconductors and photodiode components. Particular emphasis is placed on atomic layered MoS2-based ultrabroadband photodetectors, from their fundamental development to self-powered to flexible photodetectors for wearable optoelectronics. The performance of pristine MoS<sub>2</sub> atomic layers and MoS<sub>2</sub> hybrid heterostructures with graphene, CNTs, TMDs, ZnO and surface functionalized MoS2 atomic layers for developing flexible photodetectors is discussed in terms of their broadband photoresponsivity, detectivity, NEP, photogain, EQE, photoresponse speed, mechanical flexibility and environmental stability. Strain-induced and self-powered MoS2 based hybrid photodetectors has also been summarized. Finally, the challenges in developing flexible photodetectors from TMDs are analyzed. This review should be a useful source for and inspire a wide range of audience, including researchers working in the fields of optoelectronics, sensors, materials science, nanotechnology, physics, electrical engineering, and communications.

# 2. Molybdenum disulfide (MoS<sub>2</sub>) for photodetectors

Fig. 1 shows the wide range of the electromagnetic spectrum covered by 2D nanomaterials, from the near-infrared (NIR) and mid-IR (MIR) to the far-IR (FIR), the related applications of these nanomaterials in electronics, optoelectronics and photonics, and the atomic and band structures of 2D materials, including hexagonal boron nitride (h-BN), molybdenum disulfide (MoS2), black phosphorus (BP) and graphene.90 h-BN is an insulator with a large bandgap of 6.0 eV,91-95 whereas MoS<sub>2</sub> 96-98 and BP99-101 are semiconductors with sizeable bandgaps that vary with the number of atomic layers. Graphene is a zero bandgap semimetal102,103 and monolayer graphene exhibits 97.7% optical transparency independent of the optical wavelength in the 450-800 nm spectral region; the transparency decreases proportionally with an increasing number of graphene layers.<sup>104</sup> Monolayer graphene absorbs only 2.3% of incident white light; therefore, the photoresponsivity of monolayer (1L) graphene is rather limited due to the low absorbance in the visible region. The insulating layers of an h-BN dielectric have been used along with other 2D materials, such as graphene, BP and TMDs, including MoS<sub>2</sub>, MoSe2, WS2, WSe2, MoTe2, etc., to develop electronic and optoelectronic devices.105-109 Though graphene-based

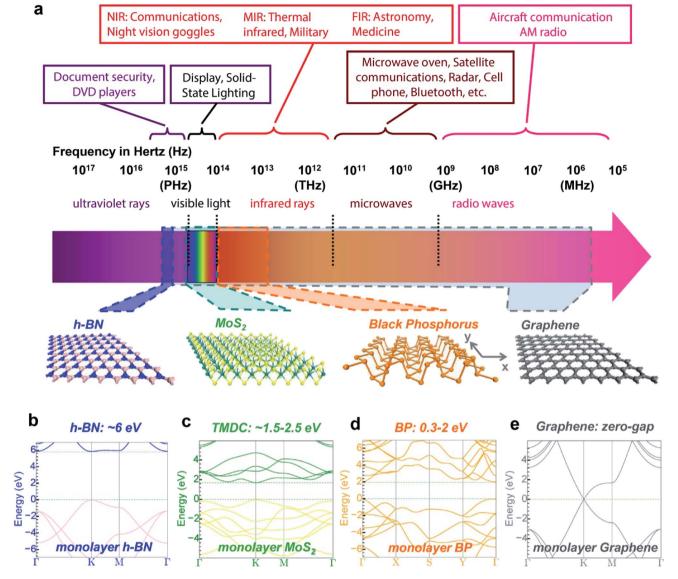


Fig. 1 (a) 2D materials covering a very wide range of the electromagnetic spectrum, from the NIR and MIR to the FIR, and their corresponding applications. The bottom section shows the atomic structures of h-BN, MoS<sub>2</sub>, black phosphorus (BP) and graphene from left to right. The electromagnetic spectral ranges covered by different 2D materials are depicted using colored polygons. (b-e) Band structures and bandgaps of monolayer h-BN (b), MoS<sub>2</sub> (c), BP (d) and gapless graphene (e). Reprinted with permission from ref. 90, copyright © 2014 Macmillan Publishers Limited

materials have been extensively studied for use in photodetectors because of their high carrier mobility and strong interaction with light over a broad spectral range, 110-113 graphene-based photodetectors suffer from low photoresponsivity due to graphene's weak optical absorption. 104,114 Broadband photodetectors utilizing multilayer BP operating over the 532 nm to 3.39 µm wavelength range have been fabricated by Guo et al.115 Comparatively, TMDs have a large electronic density of states, giving rise to high optical absorption and ultrafast charge transfer, making them more suitable for photodetectors. Bernardi et al. 116a reported 5–10% incident sunlight absorption by MoS2, MoSe2, and WS2 monolayers for a thickness of >1 nm, which is higher than the value of 2.3% exhibited by monolayer graphene<sup>104</sup> and one

order of magnitude higher than those of thin films of the conventional semiconductors GaAs and Si, generally used for solar energy applications. Fig. 2(a) compares the computed and measured absorbance of monolayer (1L) MoS2. The computed absorbance of 1L MoS2 was obtained using density functional theory (DFT) calculations, GW method and the Bethe-Salpeter equation (BSE) while experimental absorbance was reported by Mak et al.96 The quantitative agreement was observed between the computed and experimentally measured absorbance of 1L MoS<sub>2</sub>. Fig. 2(b) compares the optical absorbance of MoS2, MoSe2, and WS2 monolayers with that of graphene, clearly showing that TMD monolayers absorb much more sunlight than graphene. The calculated flux of absorbed photons was 4.6, 3.9, 2.3, and 2.0 mA cm<sup>-2</sup> for monolayer

MoSe<sub>2</sub>, MoS<sub>2</sub>, WS<sub>2</sub> and graphene, respectively, compared with 0.3 mA cm<sup>-2</sup> for GaAs and 0.1 mA cm<sup>-2</sup> for Si in the form of 1 nm thin films. A monolayer TMD can absorb as much sunlight as a 50 nm thick Si film. Wang *et al.*<sup>116b</sup> summarized the band-gaps of different atomic layered 2D nanomaterials including MoS<sub>2</sub>, MoSe<sub>2</sub>, MoTe<sub>2</sub>, WSe<sub>2</sub>, WSe<sub>2</sub>, ReSe<sub>2</sub>, ReSe<sub>2</sub>, SnSe<sub>2</sub>, SnSe<sub>2</sub>, HfSe<sub>2</sub>, HfSe<sub>2</sub>, ZrSe<sub>2</sub>, ZrSe<sub>2</sub>, In<sub>2</sub>Se<sub>3</sub>, black AsP, black phosphorus (BP), and h-BN with their corresponding photodetection range, varying from near ultraviolet (NUV) to long infrared (LIR) as shown in Fig. 2(c). MoS<sub>2</sub>, WSe<sub>2</sub>, SnS<sub>2</sub>, and black phosphorus show a broadband spectral range from NUV

wavelength to mid-infrared (MIR) wavelength. The optical absorbance of MoS<sub>2</sub> thin films can be further extended by developing diverse hybrid heterostructures.

The figure-of-merit for a photodetector is generally evaluated in terms of their photoresponsivity (R), specific detectivity ( $D^*$ ), noise equivalent power (NEP), and the photoresponse time. The photoresponsivity is an electrical response to an incident light illumination and detectivity is associated with the lowest required optical power intensity for a photodetector to differentiate signal from the actual noise. The intensities of dark and photo currents generated as a function of applied bias voltage

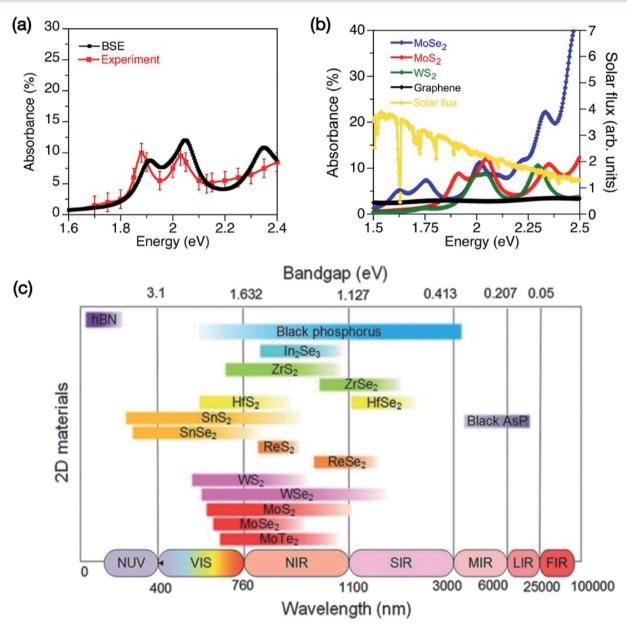


Fig. 2 (a) A comparison of the computed absorbance obtained by Bethe–Salpeter equation (BSE) with experimentally measured absorbance of a MoS<sub>2</sub> monolayer. (b) A comparison of the optical absorbance of MoS<sub>2</sub>, MoSe<sub>2</sub>, and WS<sub>2</sub> monolayers with that of graphene along with the incident AM1.5G solar flux. Reprinted with permission from ref. 116a, copyright © American Chemical Society. (c) Band-gaps of different atomic layered 2D nanomaterials (MoS<sub>2</sub>, MoSe<sub>2</sub>, MoTe<sub>2</sub>, WSe<sub>2</sub>, ReSe<sub>2</sub>, ReSe<sub>2</sub>, SnSe<sub>2</sub>, SnSe<sub>2</sub>, HfSe<sub>2</sub>, ZrSe<sub>2</sub>, ZrSe<sub>2</sub>, In<sub>2</sub>Se<sub>3</sub>, black AsP, black phosphorus (BP) and h-BN) with their corresponding photodetection range varying from near ultraviolet (NUV) to long infrared (LIR). Reprinted with permission from ref. 116b, copyright © Wiley.

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Review

and the values of photoresponsivity and detectivity at different operation wavelengths and optical power intensity are compared. The photoresponse rise and decay times are also measured to find out the speed of a photodetector. TMDs, such as MoS<sub>2</sub>, WS<sub>2</sub>, MoSe<sub>2</sub>, and WSe<sub>2</sub>, show a tunable bandgap that change from a direct bandgap in monolayers to an indirect bandgap in multilayers. Therefore, the optoelectronic

properties of atomically thin layered TMDs can be tailored by utilizing their variable bandgaps and by improving the optical absorption by forming hybrid heterostructures. The large family of atomic layered TMDs is very attractive for their application in broadband photodetectors. For example, the internal quantum efficiency (IQE) of 85% for MoS<sub>2</sub>, <sup>117</sup> IQE of 70% with an ultrafast photoresponse time of 5.5 ps for WSe<sub>2</sub>, <sup>118</sup> IQE of 91% for WSe<sub>2</sub>/

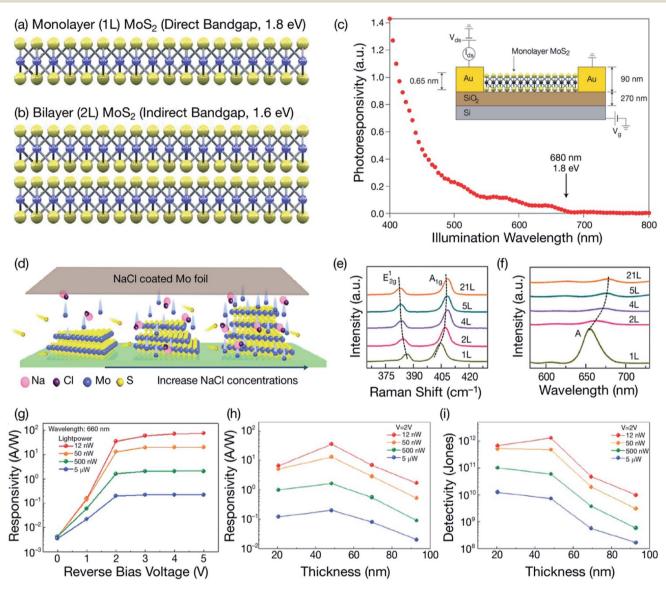


Fig. 3 (a and b) Schematic illustration of monolayer and bilayer MoS<sub>2</sub> on an atomic scale. The blue balls represent Mo atoms, while the yellow balls represent S atoms in MoS2. The direct bandgap of 1.8 eV observed in monolayer (1L) MoS2 transits to the indirect bandgap of 1.6 eV for bilayer (2L) MoS<sub>2</sub> and to 1.2 eV for multilayer (ML) MoS<sub>2</sub>.96-98 In a bilayer (2L), MoS<sub>2</sub> single layers are bound by van der Waals forces having a nanoscale distance between the adjacent layers. (c) Photoresponsivity of a monolayer MoS<sub>2</sub> photodetector measured as a function of illumination wavelength in the 400 nm to 800 nm range. The photodetector shows an increasing photoresponsivity as the illumination wavelength is decreased from 680 nm to 400 nm. The monolayer MoS<sub>2</sub>-based photodetectors can be used over a broad spectral range. The inset shows the structural view of a monolayer (6.5 Å thick) MoS<sub>2</sub> photodetector deposited on a back gate substrate with Au electrodes. Reprinted with permission from ref. 171, copyright © 2013 Macmillan Publishers Limited. (d) Schematic of NaCl-assisted layer-controlled low pressure CVD growth of MoS<sub>2</sub> flakes. (e) Layer-dependent Raman spectra of MoS<sub>2</sub> flakes showing the variation in the modes with increasing layer thickness. (f) Layer-dependent PL spectra of MoS<sub>2</sub> flakes. Reprinted with permission from ref. 174, copyright @ American Chemical Society. (g) Photoresponsivity of the MoS<sub>2</sub>/Si heterojunction photodetector as a function of reverse bias voltage at a 660 nm illumination wavelength under different incident laser powers. (h) Photoresponsivity of the MoS<sub>2</sub>/Si photodetector as a function of the thickness of MoS<sub>2</sub> flakes at a bias voltage of 2.0 V under different incident powers. (i) Detectivity of the MoS<sub>2</sub>/Si photodetector as a function of the thickness of MoS<sub>2</sub> flakes. Reprinted with permission from ref. 175, copyright @ American Chemical Society.

MoSe<sub>2</sub> heterostructures, <sup>119</sup> photoresponsivity of 2578 A W<sup>-1</sup> for monolayer WSe<sub>2</sub>/nitrogen-doped graphene quantum dots (N-GQDs),120 ultrafast charge transfer of 50 fs for MoS2/WS2 heterostructures after photoexcitation, 121 and, interestingly, photo responsivity as high as  $1 \times 10^{10}$  A W<sup>-1</sup> at 130 K and  $5 \times 10^{8}$  A W<sup>-1</sup> at room temperature for a monolayer graphene/multilayer MoS<sub>2</sub> hybrid structure illuminated at 632 nm with a power of 376 fW  $\mu$ m<sup>-2</sup> with a response time of 1 × 10<sup>3</sup> s, <sup>122</sup> demonstrate the suitability of atomic layered TMDs for developing optoelectronic devices, including photodetectors, 123,124 LEDs, 125,126 and solar cells.127-132

The bandgap in TMDs can be adjusted by changing the number of layers, which allows tuning of the optical response over a broad range of wavelengths, from the ultraviolet (UV)visible to NIR. 133-135 Furthermore, the high carrier mobility and strong interaction of TMDs with light make these 2D materials interesting for optoelectronic applications. Atomically thin layered TMDs, including MoS<sub>2</sub>, <sup>136-140</sup> MoSe<sub>2</sub>, <sup>141-144</sup>  $MoTe_{2},^{145,146} WS_{2},^{147,148} WSe_{2}/WS_{2},^{149} WSe_{2},^{120,150} WSe_{2}/h-BN,^{151}$ HfS<sub>2</sub>, 152,153 ReS<sub>2</sub>, 154,155 ReSe<sub>2</sub>, 156,157 SnS<sub>2</sub>, 158,159 and WSe<sub>2</sub>/SnSe<sub>2</sub>, 160 and the doped MoS2 heterostructures161 have been studied for use in broadband photodetectors. Among 2D TMDs, MoS<sub>2</sub> atomic layers have also been extensively investigated for developing MoS<sub>2</sub> hybrid heterostructure-based photodetectors in combination with other materials, including MoS<sub>2</sub>/Si, <sup>162</sup> AuNPs/ MoS<sub>2</sub>, 163 MoS<sub>2</sub>/WS<sub>2</sub>, 164 MoS<sub>2</sub>/WSe<sub>2</sub>, 165 graphene/MoS<sub>2</sub>/WSe<sub>2</sub>/graphene, 165 MoTe<sub>2</sub>/MoS<sub>2</sub>, 166 GaTe/MoS<sub>2</sub>, 167 PdSe<sub>2</sub>/MoS<sub>2</sub>, 168 MoS<sub>2</sub>/ graphene,169 and MoS<sub>2</sub>/BP.170 The formation of hybrid heterostructures with other materials facilitates the modification of electronic and optoelectronic properties in order to improve the photoresponse of MoS<sub>2</sub>-based photodetectors.

Several studies have demonstrated that the bandgap in MoS<sub>2</sub> can be tuned by changing the number of layers (thickness), from 1.8 eV for monolayer MoS2 to 1.2 eV for multilayer MoS<sub>2</sub>.96-98 This strategy could be used to adjust the optical response of MoS2 over a broad spectral range. Mak et al.96 reported the strongest direct bandgap photoluminescence (PL) in monolayer (1L) MoS2, with 1000-fold enhancement of the PL intensity compared with bilayer (2L) MoS2 as well as strong emergence of photoconductivity near the direct bandgap of 1.8 eV in monolayer MoS<sub>2</sub> and approximately 1.6 eV in bilayer MoS<sub>2</sub>. These results confirm the occurrence of an indirect to direct bandgap transition using photoconductivity spectroscopy. Fig. 3(a and b) shows a schematic illustration of monolayer and bilayer MoS2 on an atomic scale. In a bilayer (2L), MoS<sub>2</sub> single layers are bound by van der Waals (vdW) forces having a nanoscale distance between the adjacent layers. Atomic layer MoS<sub>2</sub> consisting of S-Mo-S atomic structures bonded through vdW forces show strong photodetection over a broad optical spectral range from the UV to IR. Lopez-Sanchez et al.171 reported a photoresponsivity of 880 A W-1 and a detectivity of  $2.5 \times 10^{10}$  Jones (Jones = cm Hz<sup>1/2</sup> W<sup>-1</sup>) for monolayer  $MoS_2$  at a bias gate voltage  $(V_{BG})$  of -70 V and a  $V_{ds}$  of 8 V for a 561 nm wavelength under a 150 pW incident power (2.4 imes $10^{-1}$  mW cm<sup>-2</sup>), along with a photoresponse in the 400–680 nm wavelength range, as shown in Fig. 3(c). CVD-grown monolayer MoS<sub>2</sub> phototransistors exhibit a photoresponsivity as high as

 $2200 \,\mathrm{AW}^{-1}$ , a photogain of 5000 and a response time of 500 s at room temperature.172 Pang et al.173 developed a MoS2-based tribotronic phototransistor by combining a few-layer MoS2 phototransistor with a sliding mode triboelectric nanogenerator (TENG). The photoresponsivity of the MoS<sub>2</sub> tribotronic phototransistor increased from 221.03 A W<sup>-1</sup> to 727.87 A W<sup>-1</sup> with increasing sliding distance from 0 mm to 8 mm under 10 mW cm<sup>-2</sup> laser power intensity and a 1.0 V drain voltage. This result indicates that the photoresponsivity of the MoS2 phototransistor can be tuned by controlling the sliding distance, enabling self-powered photodetection with a TENG.

The number of MoS<sub>2</sub> atomic layers also significantly affects the electronic and optoelectronic properties. Yang et al. 174 reported the thickness-controlled growth of MoS2 using the NaClassisted low pressure CVD method, where the number of layers of MoS<sub>2</sub> flakes was precisely controlled by simply increasing the concentration of the NaCl promoter. The Raman and PL spectra of 1L, 2L, 4L, 5L, and 21L MoS<sub>2</sub> flakes showed an increase in the frequency difference ( $\Delta$ ) between the two characteristic Raman peaks  $(E_{2g}^{1})$  and  $A_{1g}$  vibration modes) from 18.3 to 25.7 cm<sup>-1</sup> and a redshift in the PL peak from 655 nm to 678 nm as the MoS<sub>2</sub> layer thicknesses increased from 1L to 21L (Fig. 3(d-f)). The intensity of the PL emission from MoS2 flakes decreased dramatically with increasing number of layers because of the direct to indirect bandgap transition, and similarly, the bandgap of MoS<sub>2</sub> layers decreased with increasing layer thickness, from 1.8 eV for 1L to 1.5 eV for 2L and 1.2 eV for 25L. The optical transmittance measured at 550 nm gradually decreased with an increasing number of MoS2 layers, ranging from 85.0% to 57.7%, 50.1% and 24.8% for 1L, 2L, 5L and 21L MoS<sub>2</sub>. The UV-B absorptions of 1L, 2L, 5L and 21L MoS2 flakes were over 95%. The thickness-dependent optoelectronic properties of multilayer MoS2 have been studied. The highest values of photoresponsivity and detectivity reached  $1 \times 10^4$  A W<sup>-1</sup> and 8  $\times$  10<sup>12</sup> Jones for monolayer-bilayer (1L-2L) heterojunctions and  $4 \times 10^3$  A W<sup>-1</sup> and  $6 \times 10^{12}$  Jones for monolayer-8-layer (1L-8L) MoS<sub>2</sub> heterojunctions at 660 nm.

In another study, Shin et al. 175 deposited mechanically exfoliated multilayer MoS2 flakes onto a Si layer to develop MoS<sub>2</sub>/Si p-n heterojunction photodiodes; the optoelectronic properties were improved and optimized by controlling the number of layers of MoS<sub>2</sub> flakes. The photoresponse of the MoS<sub>2</sub>/Si photodetector was measured at 405, 520, and 660 nm wavelengths under different incident power intensities and for various thicknesses of multilayer MoS2 flakes. The 2 nm thick MoS<sub>2</sub> flake-based photodiodes showed very poor performance with low photoresponsivities of 3.36  $\times$  10<sup>-3</sup> and 6.64  $\times$  10<sup>-5</sup> A  $W^{-1}$  and detectivities of 2.08  $\times$  10<sup>6</sup> and 4.11  $\times$  10<sup>5</sup> Jones at a 660 nm wavelength under incident optical powers of 50 nW and 50 µW at 2 V, respectively. The thickness-dependent maximum values of the photoresponsivity and detectivity were obtained for 48 nm MoS2 flakes at 12 nW and 2 V. Photoresponsivities of 6.54, 35.7, 6.94, and 1.70 A W<sup>-1</sup> and detectivities of  $2.33 \times 10^9$ ,  $1.52 \times 10^{11}$ ,  $8.31 \times 10^9$ , and  $8.64 \times 10^7$  Jones were measured for the 20, 48, 69, and 92 nm thick multilayer MoS<sub>2</sub> flakes at 2 V, respectively. The thickness-dependent optoelectronic properties for atomic layered MoS2 have been

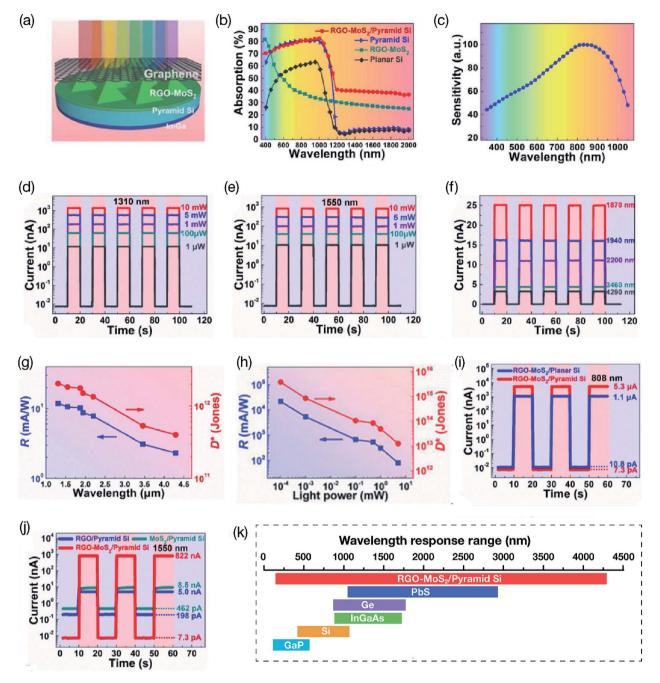


Fig. 4 (a) Schematic illustration of the 3D RGO-MoS<sub>2</sub>/pyramid Si heterojunction-based photodetector. (b) A comparison of the absorption spectra of planar and pyramid Si, RGO (also referred as rGO), and RGO-MoS<sub>2</sub>/Si heterojunction devices. (c) Photosensitivity of the RGO-MoS<sub>2</sub>/ pyramid Si heterojunction-based device between 350 to 1100 nm wavelength region. (d and e) Photocurrent switching behavior of heterojunction device measured under light illuminations at 1310 and 1550 nm at zero bias voltage (V = 0), self-powered devices. (f) Photocurrent switching behavior of heterojunction devices measured under 1870, 1940, 2200, 3460 and 4290 nm (NIR-MIR) light illuminations. (g) Photoresponsivity (R) and specific detectivity (D\*) curves of the heterojunction device measured as a function of wavelength from 1310 nm to 4290 nm at a fixed laser power intensity of 50 mW under zero bias voltage. (h) R and D\* curves of the heterojunction photodetector measured as a function of laser power intensity at 808 nm at the 100 nW laser power under zero bias voltage. (i) A comparison of the photocurrent switching behavior of RGO-MoS<sub>2</sub>/pyramid Si and RGO-MoS<sub>2</sub>/planar Si heterojunction devices measured at 808 nm wavelength under 1 µW laser power intensity. (j) A comparison of the photocurrent switching behavior of RGO-MoS<sub>2</sub>/pyramid Si heterojunction device with RGO/pyramid Si and MoS<sub>2</sub>/pyramid Si devices measured at 1550 nm wavelength under 10 mW laser power intensity. (k) A comparison of the wavelength coverage by the RGO-MoS<sub>2</sub>/pyramid Si heterojunction-based photodetector along with other traditional semiconductor-based photodetectors. The RGO-MoS<sub>2</sub>/pyramid Si hybrid heterojunction-based photodetectors operated from 350 nm to 4.3 μm (UV to MIR) ultra-broadband spectral range due to the bandgap narrowing caused by the S vacancy defects in MoS<sub>2</sub> crystals. Reprinted with permission from ref. 178, copyright © Wiley.

studied. Yang et al. 176 fabricated photodetectors using MoS2 films with thicknesses greater than 6 nm, which showed a fast photoresponse time of <1 ms and a current  $I_{\rm on}/I_{\rm off}$  ratio of  $\sim 10^4$ . The MoS<sub>2</sub> photodetector developed from a 9 nm thick MoS<sub>2</sub> film showed an 8 nA current at a 3 V bias voltage in the dark. The current increased to 1.47 and 13.5 µA at 30 and 140 µW, respectively. The current  $I_{\rm on}/I_{\rm off}$  ratio of the MoS $_2$  photodetector increased from  $\sim 10^1$  to  $\sim 10^4$  for the 2 nm to 9 nm thick MoS<sub>2</sub> film but decreased by two orders of magnitude to 10<sup>2</sup> for the 32 nm thick film. Therefore, a MoS<sub>2</sub> film with a 9 nm thickness was used as the active layer for fabricating a MoS2 photodetector. The current of the MoS2 photodetector measured by irradiating it with 532 nm laser light at a 3 V bias showed a rapid increase to 25 µA and then decreased to 8 nA after turning off the laser light. Fig. 3(g-i) shows the photoresponsivity of the MoS<sub>2</sub>/Si heterojunction photodetector as a function of reverse bias voltage and thickness of MoS2 flakes under different incident powers. The photodetector based on 48 nm thick MoS<sub>2</sub> flakes showed a low noise equivalent power (NEP) value of 7.82 imes 10<sup>-15</sup> W Hz<sup>-1/2</sup> at a 10 Hz frequency and a reverse bias voltage of 4.0 V, lower than the NEP of  $3 \times 10^{-14}$  W  $Hz^{-1/2}$  for the Si avalanche photodiode.177 Ling et al.139 also studied thicknessdependent photoresponse of MoS2 photodetectors. The photoresponsivity increased from 0.4 A W<sup>-1</sup> for bilayer MoS<sub>2</sub> photodetector to 1.8 A W<sup>-1</sup> for 5L MoS<sub>2</sub> at 850 nm wavelength under a bias voltage of 5 V because of the enhanced photoabsorption. The EQE value of a 5L MoS2 photodetector was found to increase from 30% at 1 V to 263% at 5 V. The 2L MoS<sub>2</sub> photodetector showed detectivity over 109 Jones, much higher compared with 3L and 5L MoS2 photodetectors due to the low dark current. As seen from the above studies, multilayer MoS2 is more appealing for developing broadband photodetectors due to its smaller indirect bandgap and extended optical spectral range compared with monolayer MoS2, although further improvement of the photoresponsivity and detectivity is still needed.

# 3. Strategies for boosting the performance of MoS<sub>2</sub> photodetectors using hybrid heterostructures

The outstanding features of atomic layered MoS<sub>2</sub>, such as the high optical transparency and carrier mobility, ultrafast photoresponse, and photodetection from the UV to IR, make MoS<sub>2</sub> highly desirable for developing broadband photodetectors. However, the low optical absorption by MoS<sub>2</sub> atomic layers hinders in achieving the high performance of photodetectors; therefore, different strategies have been applied to improve the photoresponse by generating abundant photo-excited carriers. Though the absorption of light by the MoS<sub>2</sub> atomic layers is an intrinsic property, the light absorption can be further enhanced in MoS<sub>2</sub> hybrid heterostructures by utilizing the supplementary light absorption of secondary integrated components in the hybrid structures. In addition to the incident light absorption, the carrier mobility of MoS<sub>2</sub> can be dramatically increased by forming hybrid heterostructures and nanocomposites with

a diverse range of inorganic, organic and polymeric materials to develop MoS<sub>2</sub> hybrid heterostructure-based high-performance ultrabroadband photodetectors. The large bandgap and limited absorption of visible light (~10%) displayed by monolayer MoS<sub>2</sub> hinder the attainment of a high power conversion efficiency, which eventually restricts the application of MoS<sub>2</sub> atomic layers in broadband photodetectors. The intrinsic photoresponse of atomic layered MoS<sub>2</sub> is rather constrained; therefore, different strategies have been explored to boost the carrier mobility and optical absorption of MoS2 layers to improve the overall optoelectronic properties by maneuvering the electronic band structure. Different strategies such as control of atomic-layer thickness, hybrid heterostructures formation, chemical doping, surface functionalization, strain and defect engineering have been used for boosting the performance of MoS2 photodetectors which are discussed throughout this article.

Diverse MoS<sub>2</sub> hybrid heterostructures with other inorganic, organic and 2D nanomaterials have been developed for extending the light absorption wavelengths and improving the charge transfer process. For example, Xiao et al.178 reported oxide (RGO)-MoS<sub>2</sub>/pyramid reduced graphene heterostructure-based photodetectors where 3L graphene and indium-gallium (In-Ga) alloy were used as top and bottom electrodes, respectively. Fig. 4 shows a schematic illustration of the 3D RGO-MoS<sub>2</sub>/pyramid Si heterojunction-based photodetector, a comparison of the absorption spectra of planar and pyramid Si, RGO (also referred to as rGO), and RGO-MoS<sub>2</sub>/Si heterojunction devices, photosensitivity between 350 to 1100 nm wavelength region, photocurrent switching behavior under light illuminations, wavelength and laser-power dependent photoresponsivity (R) and specific detectivity  $(D^*)$  of RGO-MoS<sub>2</sub>/Si heterojunction-based photodetector under zero bias voltage and wavelength range covered by the RGO-MoS<sub>2</sub>/ pyramid Si heterojunction-based photodetector. The photoof RGO-MoS<sub>2</sub>/Si heterojunction photodetector increased from 180 to 276 mV as the light power intensity was increased from 100 nW to 1 mW, which evidenced the selfpowered operation of this photodetector at zero bias voltage (V=0). Furthermore, hetero-junction photodetector showed the photoresponsivity of 21.8 A  $\mathrm{W}^{-1}$  and detectivity of 3.8  $\times$  10<sup>15</sup> Jones at an 880 nm wavelength and a very broad optical spectrum range from the UV (350 nm) to mid-IR (4.3 µm). The selfdriven heterojunction photodetectors exhibited photoresponsivity values of 2 to 11 mA W<sup>-1</sup> and detectivity of 0.4 to 2  $\times$  10<sup>12</sup> Jones in the NIR-MIR (1870-4290 nm) range. The origin of high photoresponse over such an ultra-broadband range lies on several factors. In this RGO-MoS<sub>2</sub>/pyramid Si heterostructure, the light absorption was increased by the pyramid Si structure while highly conductive RGO assisted in enhancing the charge separation and transfer process. The RGO-MoS<sub>2</sub>/Si heterojunction shows maximum photoresponse at 800-900 nm. The light-harvesting by nanostructured pyramid Si surface was found to be 20% higher compared to planar Si in the 400 to 1000 nm spectral range. The photocurrent of RGO-MoS<sub>2</sub>/ pyramid Si device (5.3 µA) was found to be five times higher than that of the RGO-MoS<sub>2</sub>/planar Si device (1.1 µA) at 808 nm.

Both pyramid and planar Si substrates barely absorb light over 1100 nm due to the bandgap of 1.1 eV. The integration of pyramid Si nanostructured surface assisted in extending the light absorption of the heterojunction in the NIR range. On the other hand, the RGO-MoS<sub>2</sub> composite exhibits strong light absorption up to 2 µm and dominant photovoltaic property at 1310 and 1550 nm where the corresponding current  $I_{\rm on}/I_{\rm off}$ ratios of 1.9  $\times$  10<sup>6</sup> and 1.2  $\times$  10<sup>6</sup> and detectivity values of 2.04  $\times$  $10^{12}$  and  $1.8 \times 10^{12}$  Jones were measured, respectively. Electron-hole pairs are generated in the RGO-MoS<sub>2</sub>/Si heterojunction under light illumination and then get separated at the heterojunction interface due to the built-in-electric field. The RGO-MoS<sub>2</sub>/pyramid Si heterojunction device also displayed faster rise/decay times of 2.8 µs/46.6 µs compared with 32.6 µs/ 87.8 µs for the MoS<sub>2</sub>/pyramid Si device due to the increased conductivity and internal electric field. The defects in MoS<sub>2</sub> assist in absorbing the light from NIR to MIR wavelength range, as a result photoexcited carriers from MoS2 are transferred to the RGO layer, giving rise to the photocurrent in the NIR-MIR region. Therefore, the RGO-MoS<sub>2</sub>/pyramid Si heterojunctionbased photodetector was able to operate from 350 nm to 4.3 μm (UV to MIR) ultrabroad spectral range due to the bandgap narrowing caused by the S vacancy defects in MoS2 crystals. XPS measurements and theoretical calculation also confirmed the existence of S vacancies where Mo/S atomic ratios of 1:2, 1:1.87 an 1:163 yielded bandgaps of 1.18, 0.30 and 0.28 eV, respectively, indicating a dramatic reduction in the bandgap of MoS<sub>2</sub>. These results demonstrated that the formation of a hybrid heterostructure and occurring S vacancy defects in MoS<sub>2</sub> crystals contributed to the high performance of the RGO-MoS<sub>2</sub>/pyramid Si heterojunction-based ultra-broadband photodetectors. In another study, Peng et al. 179 used an rGO layer as the conducting channel and a perovskite/MoS2 bulk heterojunction (BHJ) as a photosensitizer for developing a hybrid photodetector that showed a photoresponsivity of  $1.08 \times 10^4$  A  $W^{-1}$ , a detectivity of 4.28  $\times$  10<sup>13</sup> Jones, an EQE value of 2.0  $\times$ 106%, and a >45 ms photoresponse time. The high photoresponse in the hybrid heterostructured system originated from the hole transfer from the perovskite to the rGO layer, facilitated

Another common technique of improving the performance of MoS<sub>2</sub> photodetectors is via chemical doping. For example, Kang  $et~al.^{180}$  demonstrated that the field-effect mobility increased from 28.75 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> to 142.2 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and the photoresponsivity increased from 219 A W<sup>-1</sup> to 5.75 × 10<sup>3</sup> A W<sup>-1</sup> for APTES/MoS<sub>2</sub> hybrid phototransistors after aminopropyltriethoxysilane (APTES) doping of monolayer MoS<sub>2</sub>. The 24.5-fold increase in the photoresponsivity of the APTES/MoS<sub>2</sub> photodetector resulted from the enhanced photocurrent after APTES doping. The photoresponsivity of APTES/MoS<sub>2</sub> devices reached 1212.8 A W<sup>-1</sup> at a gate bias voltage of  $V_{\rm g}=0$  and a  $V_{\rm ds}$  of 5 V for a 520 nm wavelength under an incident power of 5.8 mW cm<sup>-2</sup>. Yu  $et~al.^{181}$  used mechanically exfoliated monolayer MoS<sub>2</sub> nanosheets sensitized with rhodamine 6G (R6G) organic dye to develop a photodetector with an enhanced photoresponse. The

by the suppression of the recombination of photocarriers from the perovskite/MoS<sub>2</sub> BHJ along with electron trapping in the

MoS<sub>2</sub> layers.

dye-sensitized MoS<sub>2</sub>/R6G-based photodetector showed a photoresponsivity of 1.17 A W<sup>-1</sup>, a detectivity of 1.5  $\times$  10<sup>7</sup> Jones, an EQE of 280% at 520 nm under an incident power of 1 μW and a photoresponse between wavelengths of 405 and 980 nm arising from charge transfer from the rhodamine 6G dye to monolayer MoS<sub>2</sub>. In addition to photosensitive dyes, the high-κ Al<sub>2</sub>O<sub>3</sub> dielectric has been used for enhancing the photoresponse of MoS<sub>2</sub> photodetectors. Huang et al. 182 used zinc phthalocyanine (ZnPc) organic dye on the surface of monolayer MoS2 to create a charge transfer interface. Dark and photocurrent of the dye-sensitized ZnPc-treated MoS2 photodetectors increased by 10<sup>3</sup> to 10<sup>5</sup> times after a 30 nm thick top Al<sub>2</sub>O<sub>3</sub> passivation layer was used. The photoresponsivity of 281 and 1.74 A W<sup>-1</sup> were recorded for the bare MoS2 and ZnPc-treated MoS2 devices at 532 nm under light intensity of 0.07 mW cm $^{-2}$ , respectively. The photoresponse of the Al<sub>2</sub>O<sub>3</sub>-passivated MoS<sub>2</sub>/ZnPc hybrid photodetector was significantly improved: the photoresponsivity increased from 430 A W<sup>-1</sup> to  $1.4 \times 10^4$  A W<sup>-1</sup> as the light intensity changed from 3.64  $\mathrm{mW~cm^{-2}}$  to 0.07  $\mathrm{mW~cm^{-2}}$ under a gate bias of 40 V, respectively. The photoresponse of the MoS<sub>2</sub>/ZnPc hybrid device was 100 times faster than that of a pristine MoS2 device. Wu et al. 183 demonstrated a photoresponsivity of  $2.7 \times 10^4 \, \text{A W}^{-1}$  for a MoS<sub>2</sub> photodetector using an Al<sub>2</sub>O<sub>3</sub>/ITO/SiO<sub>2</sub> substrate, which increased the light absorption of MoS<sub>2</sub> thin films. The high-κ Al<sub>2</sub>O<sub>3</sub> dielectric also yielded a current  $I_{\rm on}/I_{\rm off}$  ratio of 10<sup>9</sup> under a 2 V gate bias voltage, a mobility of 84 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and a subthreshold swing of  $104 \text{ mV dec}^{-1}$ .

Several different strategies including  $MoS_2$  plasmonic heterostructures, chemical doping of  $MoS_2$  layers, halide perovskites, 2D–0D  $MoS_2/QDs$  heterostructures, and 2D–2D  $MoS_2/VDS$  hybrid heterostructures have been employed for boosting the light absorption efficiency of  $MoS_2$  thin films, hence improving the performance of  $MoS_2$  photodetectors. The strategies assist in terms of increasing the carrier mobility and the absorption of incident sunlight by  $MoS_2$  hybrid heterostructures.

#### 3.1 MoS<sub>2</sub> plasmonic heterostructures

The plasmonic nanostructures have been used for enhancing the optical absorption of semiconductor-based photodetectors. The photoresponse of atomic layered MoS<sub>2</sub> photodetectors has been optimized by forming hybrid plasmonic heterostructures for light-harvesting. The gold nanoparticles (AuNPs)@MoS2 heterostructure-based plasmonic photodetectors having AuNPs core and ML MoS2 shell showed 10-fold increase in photoresponsivity (0.5 A W<sup>-1</sup>) compared with pristine MoS<sub>2</sub> phototransistors (0.057 AW<sup>-1</sup>). The maximum photoresponsivity of 30 A W<sup>-1</sup> was achieved for the Si-supported AuNPs@MoS<sub>2</sub> heterojunction-based gateless photodetector greater than that of Si/MoS<sub>2</sub> heterojunction (1.1 A W<sup>-1</sup>) phototransistors. Bang et al. 184 developed a monolayer (1L) MoS2 photodetector exploiting the surface plasmon of a one-dimensional (1D) silver nanowire (AgNW) network. Fig. 5(a-d) shows the schematic diagram of the 1L-MoS<sub>2</sub>/AgNW-based photodetector, dark field image of a hybrid photodetector, and photocurrent-voltage

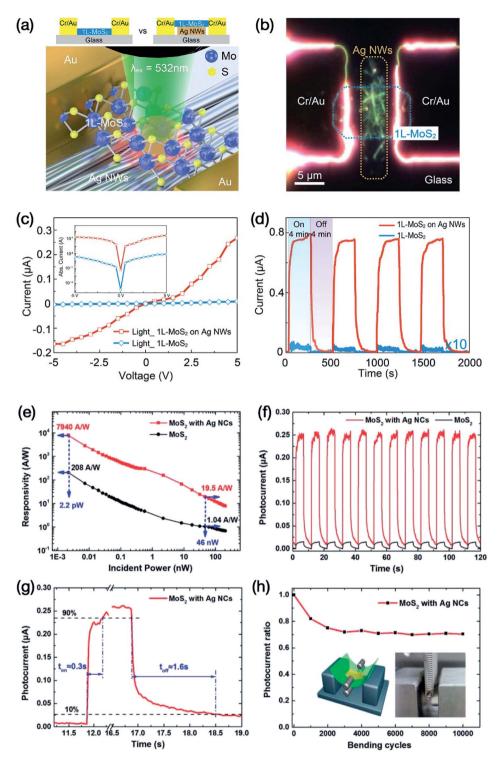


Fig. 5 (a) Schematic diagram of the  $1L-MoS_2$  and Ag nanowires (NWs) based photodetector. Upper area shows the schematic diagrams of the pristine  $1L-MoS_2$  and the  $1L-MoS_2$ /AgNWs hybrid photodetector on a glass substrate along with Cr/Au electrodes. (b) Dark field image of the  $1L-MoS_2$ /AgNWs hybrid photodetector (60% density of AgNWs). (c) A comparison of the photocurrent–voltage curves between pristine  $1L-MoS_2$  (blue line) and the  $1L-MoS_2$ /AgNWs hybrid photodetector (red line) measured at 532 nm. The inset represents a logarithmic scale of the photocurrent–voltage characteristic. (d) Time dependent photocurrent of the pristine  $1L-MoS_2$  (blue) and  $1L-MoS_2$ /AgNWs hybrid photodetectors (red) recorded with an  $I_{on}/I_{off}$  time of 4 min. Reprinted with permission from ref. 184, copyright © American Chemical Society. (e) Photoresponsivity of  $MoS_2$  and  $MoS_2$ /Ag nanocubes (NCs) hybrid-based photodetectors as a function of incident laser power. (f) A comparison of the transient photocurrent of  $MoS_2$  and  $MoS_2$ /Ag nanocubes (NCs) photodetectors under periodical  $I_{on}/I_{off}$  illumination at 1 V. (g) Photocurrent rise ( $I_{on}$ ) and decay ( $I_{off}$ ) times of  $MoS_2$ /Ag NCs hybrid-based photodetector. (h) Photocurrent of  $MoS_2$ /Ag NCs hybrid-based photodetector as a function of number of bending cycles, where the insets show schematic and photograph of a bending setup. Reprinted with permission from ref. 186, copyright @ Wiley.

curves of pristine 1L-MoS2 and the 1L-MoS2/AgNWs hybrid photodetectors as a function of applied voltage (from -5 V to +5V) and the time-dependent photocurrents. The current  $I_{\rm on}/I_{\rm off}$ ratios of  $1.39 \times 10^4$  and 62.97 were measured for the 1L MoS<sub>2</sub>/ AgNW hybrid and pristine 1L-MoS<sub>2</sub> photodetectors, respectively. The 1L MoS<sub>2</sub>/AgNW hybrid heterostructure-based device showed 560- and 250-fold increases in the PL and photocurrent, respectively, compared with the pristine 1L MoS<sub>2</sub> device. Similarly, the photoresponsivity of 59.60 A W<sup>-1</sup> and detectivity of  $4.51 \times 10^{10}$  Jones for the 1L MoS<sub>2</sub>/AgNW hybrid photodetector were 1000 times enhanced compared to those of the pristine 1L- $MoS_2$  photodetector (0.05 A W<sup>-1</sup> and 4.11  $\times$  10<sup>7</sup> Jones). The significant improvement in the optoelectronic properties of the 1L MoS<sub>2</sub>/AgNW hybrid photodetector occurred due to the surface plasmon coupling of the AgNW network. In another study, Jing et al. 185 enhanced the localized surface plasmon resonance (LSPR) by depositing Ag nanoparticles onto monolayer MoS<sub>2</sub> for developing phototransistors. AgNPs/MoS<sub>2</sub> hybrid-based phototransistors showed a 470% increase in photoresponsivity, changing from  $5.35 \times 10^3 \text{ A W}^{-1}$  to  $2.97 \times 10^3 \text{ A W}^{-1}$  $10^4$  A W<sup>-1</sup> at 610 nm for 25 nm AgNPs. The interactions between MoS<sub>2</sub> layers and light are enhanced by the integrated Au or Ag nanostructures due to the LSPR, which significantly improves the photoresponse of plasmon heterostructure-based hybrid MoS<sub>2</sub> photodetectors. Sun et al. 186 used silica layer-coated silver nanocubes (AgNCs) with optimized LSP in the gap mode for developing a flexible MoS2 photodetector. The PL spectrum of MoS<sub>2</sub>/Ag nanocubes hybrid was found to be significantly enhanced compared with MoS2 film after modifying of Ag NCs with underneath Ag thin film due to interactions between the MoS<sub>2</sub> excitons and LSP in the gap mode. Fig. 5(e-g) compare the photoresponsivity and photocurrent of MoS<sub>2</sub> and flexible MoS<sub>2</sub>/ Ag nanocubes (NCs) hybrid-based photodetectors as a function of incident laser power and time, respectively. Photocurrent rise  $(\tau_{\rm rise})$  and decay  $(\tau_{\rm decay})$  times and mechanical stability of flexible MoS<sub>2</sub>/AgNCs hybrid-based photodetector are also depicted. The photocurrents of the photodetectors fabricated using pristine MoS<sub>2</sub> film and MoS<sub>2</sub> film with underneath Ag film were almost the same (48-50 nA) at 3 V under 520 nm laser illumination with 46 nW incident power whereas the photocurrent of

flexible photodetector having MoS2 film in the gap of Ag layer

and AgNCs was considerably increased to 0.91 µA under similar

experimental conditions due to the Ag nanocubes. The AgNCs

decorated MoS2 film shows 19-fold increment in photocurrent

compared with pristine MoS2 film. The photoresponsivity of

MoS<sub>2</sub> with AgNCs based flexible photodetector increased 38

times to 7940 A W<sup>-1</sup> at 3 V under 2.2 pW incident power

compared with pristine MoS<sub>2</sub> film with decreasing incident

power intensity due to the reduced scattering and recombination of the photogenerated charge carriers. Photocurrent rise

time ( $\tau_{rise}$ ) of 0.3 s and decay time ( $\tau_{decay}$ ) of 1.6 s were estimated

for the flexible MoS<sub>2</sub>/AgNCs hybrid-based photodetector. The

flexible photodetector showed good mechanical stability after bending at a curvature of 8 mm for 10 000 times because 71%

photocurrent ratio of devices was retained. The photocurrent

initially decreased up to 3000 bending cycles, but no noticeable decrease in photocurrent ratio was observed thereafter. These

studies show that the integration of plasmonic nanostructures with MoS<sub>2</sub> atomic layers can significantly increase the photoresponsivity of MoS<sub>2</sub> based photodetectors.

#### 3.2 Chemical doping of MoS<sub>2</sub> layers

As discussed above, performance of MoS<sub>2</sub> photodetectors can be significantly increased by doping MoS<sub>2</sub> layers with APTES, <sup>180</sup> rhodamine 6G181 and ZnPc182 organic dyes, which efficiently generate charge transfer interfaces between MoS2 and chemical dopants. A few examples of boosting the performance of MoS<sub>2</sub> photodetectors via chemical doping are presented here. Heo et al. 187 used n-type doping of MoS2 flakes with triphenylphosphine (PPh<sub>3</sub>) to improve the electronic and optoelectronic properties of multilayer MoS<sub>2</sub> by utilizing charge transfer from PPh<sub>3</sub> to MoS<sub>2</sub>, in which the PPh<sub>3</sub> doping concentration ranged from 1.56  $\times$  10<sup>11</sup> to 9.75  $\times$  10<sup>12</sup> cm<sup>-2</sup>. The PPh<sub>3</sub> doping considerably increased the mobility from 12.1 to 241 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and the  $I_{\rm on}/I_{\rm off}$  current ratio from 8.72  $\times$  10<sup>4</sup> to 8.70  $\times$  10<sup>5</sup> for the MoS<sub>2</sub> transistor. The photoresponsivity of the MoS<sub>2</sub> photodetector similarly increased from  $2.77 \times 10^3$  to a maximum value of  $3.92 \times 10^5$  A W<sup>-1</sup> under an applied laser power of 5 pW. The detectivity decreased by three orders of magnitude, from  $6.82 \times 10^{13}$  Jones to  $2.36 \times 10^{10}$  Jones, as the device doping temperature was increased from 150 °C to 350 °C. The MoS<sub>2</sub> photodetector also showed long-term stability, where the photoresponsivity decreased by 1.58% after 14 days of exposure to air; additionally, the PPh<sub>3</sub> doping was reversible, allowing repetitive use of the photodetector device. For example, a MoS<sub>2</sub>/Si heterojunction-based photodetector showed no degradation in the photovoltage after storing in an air atmosphere over a period of a month.162

The chemical doping of monolayer MoS<sub>2</sub> film over a 13 cm<sup>2</sup> area for developing photodetector devices was reported by Kim et al. 161 The n-type MoS<sub>2</sub> semiconductor transitions into the ptype semiconductor after doping with Nb. Raman spectroscopy, X-ray photoelectron spectroscopy (XPS), and photoluminescence (PL) spectroscopy were used to characterize the doped MoS<sub>2</sub>. The Nb-doped MoS<sub>2</sub> showed binding energy peaks at lower values compared with MoS2. The Nb- and Mn-doped monolayer MoS2 FETs showed p-type and n-type doped MoS2 characteristics, respectively. Fig. 6 shows doped MoS<sub>2</sub> photodetectors, transfer curves (drain current versus gate voltage) and photoresponsivity of Nb-doped MoS2 photodetectors as a function of optical power and compares the photoresponsivity, EQE, and detectivity of Nb-doped MoS2 photodetectors with updoped MoS<sub>2</sub> photodetectors at different laser wavelengths. A sublinear relationship  $(R \propto P\alpha)$  was observed for Nb-doped MoS<sub>2</sub> photodetector between photoresponsivity (R) and optical power (P), which yielded an  $\alpha$  value of -0.9 using the power function fitting method. The Nb-doped MoS2 photodetector showed photoresponsivity of  $2 \times 10^5$  A W<sup>-1</sup>, which is  $10^6$  times higher compared with the photoresponsivity of  $0.52 \text{ A W}^{-1}$  for the MoS<sub>2</sub> film measured under similar conditions at a 550 nm laser wavelength. The highest photoresponsivity of  $4.83 \times 10^5 \,\mathrm{A W}^{-1}$ was recorded at 750 nm wavelength for the Nb-doped MoS2 photodetector. Likely, the EQE for Nb-doped MoS2

photodetector was found to be  $9.31 \times 10^7$ %, which was  $10^6$  times higher compared with EQE of 107% for the MoS $_2$  device at 450 nm wavelength. The Nb-doped MoS $_2$  photodetector showed detectivity of  $5.0 \times 10^{12}$  Jones, compared with the detectivity of  $3.93 \times 10^8$  Jones for the updoped MoS $_2$  photodetector at 750 nm wavelength, which resulted in  $10^5$  times higher detectivity after Nb-doping. The photocurrent values of Nb-doped MoS $_2$  devices were also increased by  $10^5$  folds due to the charge-transfer process. The Nb-doped MoS $_2$  devices also exhibited faster rise/decay times of 4.9 ms and 5.7 ms compared with 0.63 s and 1.63 s for the updoped MoS $_2$  devices at 550 nm laser wavelength, respectively. The Nb-doped MoS $_2$  photodetector devices showed stability for 30 days under ambient conditions.

The phototransistors utilizing hybrid MoS<sub>2</sub>/PbS QDs, were fabricated by Pak *et al.* <sup>188</sup> in which the PbS QDs were surface modified with n-type tetrabutylammonium iodide (TBAI) and ptype 1,2-ethanedithiol (EDT) ligands to develop p–n junctions. The MoS<sub>2</sub>/PbS-TBAI/PbS-EDT hybrid device showed a photoresponsivity of 5700  $\pm$  71.2 A W $^{-1}$  for a single-junction device and 6120  $\pm$  96.9 A W $^{-1}$  for a double-junction device at an incident laser power of 20 pW. The photocurrent rise time of 40 ms for the single-junction device was reduced to 950  $\mu s$  for the double-junction device. The efficient charge transfer occurring in the MoS<sub>2</sub>/PbS QD hybrid photodetector yielded a maximum

photoresponsivity of  $5.4 \times 10^4$  A W<sup>-1</sup> and a detectivity of  $1 \times 10^{11}$  Jones. High photoresponsivity of 2570 A W<sup>-1</sup> and detectivity of  $2.2 \times 10^{12}$  Jones at 635 nm in a few-layer MoS<sub>2</sub> photodetector have been demonstrated under zero gate voltage with the use of a poly(vinylidene fluoride-trifluoroethylene) [P(VDF-TrFE)] ferroelectric polymer gate.<sup>137</sup> This MoS<sub>2</sub>/P(VDF-TrFE) hybrid photodetector also showed photodetection over the 0.85  $\mu$ m to 1.55  $\mu$ m spectral region and excellent stability over 90 000 repeated cycles of operation.

Organic molecules and polymers have been hybridized with MoS<sub>2</sub> to develop photodetectors. Sun et al. 189 used narrow semiconducting bandgap organic polymer, diketopyrrolopyrrole-terthiophene) (PDPP3T), large bandgap monolayer MoS2 to develop UV-NIR photodetectors. The photoresponsivities of MoS<sub>2</sub>/PDPP3T based phototransistors were enhanced by one to two orders of magnitude compared with MoS2. Flexible MoS2/PDPP3T photodetectors that were fabricated on a PET substrate. The MoS2/PDPP3T hybrid showed photoresponsivities of 276, 445, and 269 mA  $W^{-1}$  and detectivity values of  $2.59 \times 10^8$ ,  $3.14 \times 10^8$ , and  $2.53 \times 10^8$ 108 Jones at 365, 660, and 850 nm, respectively. The flexible MoS<sub>2</sub>/PDPP3T photodetectors were developed on a PET substrate which exhibited photoresponse from 365 nm to 940 nm. The bending testing of flexible MoS<sub>2</sub>/PDPP3T

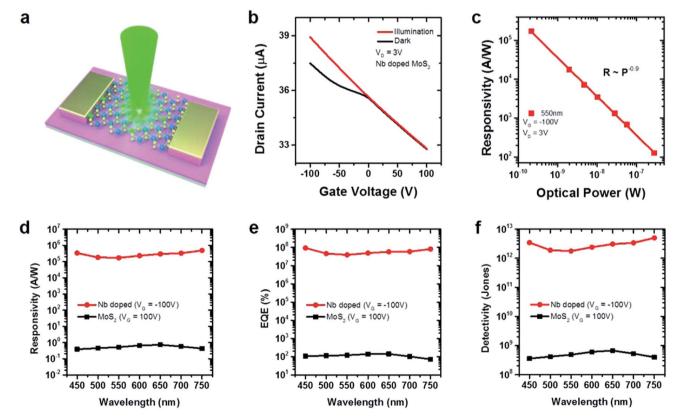


Fig. 6 (a) Schematic illustration of doped MoS<sub>2</sub> photodetectors. (b) Transfer curves of Nb-doped MoS<sub>2</sub> photodetectors at 550 nm laser wavelength under 282 nW optical power. (c) Photoresponsivity (R) of Nb-doped MoS<sub>2</sub> photodetectors as a function of optical power (P) at 550 nm laser wavelength and at  $V_{\rm d} = 3$  V and  $V_{\rm g} = -100$  V. A comparison of photoresponse characteristics of Nb-doped MoS<sub>2</sub> photodetectors with updoped MoS<sub>2</sub> photodetectors. (d) Photoresponsivity, (e) EQE, and (f) detectivity of Nb-doped MoS<sub>2</sub> photodetectors and updoped MoS<sub>2</sub> photodetectors at  $V_{\rm g} = -100$  V as a function of laser wavelength. Reprinted with permission from ref. 161, copyright © American Chemical Society.

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photodetector was conducted under 660 nm light illumination a 9 mm bending radius where some decrease in the photocurrent was noticed after 10 000 bending cycles. Likely, the environmental stability of the flexible MoS<sub>2</sub>/PDPP3T photodetector was also evaluated without any encapsulation in an air atmosphere for 35 days where slight changes were observed both in the dark and photo currents. MoS<sub>2</sub>/PDPP3T hybrid photodetector devices demonstrated both mechanical stability and durability in the air.

#### 3.3 Halide perovskite MoS<sub>2</sub> heterostructures

Organometallic halide perovskites have emerged as an important class of light harvesting materials for developing solar cells<sup>8,9,130,131</sup> because of their tunable bandgap, extended light absorption over a broad spectral range, high photoconversion efficiencies, charge-carrier mobilities, and ease of solution processing into ultrathin layers. These unique optoelectronic properties of perovskites have been utilized in improving the performance of MoS<sub>2</sub> photodetectors. Wu et al. 190 developed hybrid phototransistors using 0D cesium lead halides perovskite (CsPbI<sub>3-x</sub>Br<sub>x</sub>) QDs and 2D monolayer MoS<sub>2</sub>. The CsPbI<sub>3-x</sub>Br<sub>x</sub> QD/1L MoS<sub>2</sub> 0D-2D mixed-dimensional vdW heterostructure-based photodetectors showed a high photoresponsivity of  $7.7 \times 10^4$  A W<sup>-1</sup>, a detectivity of  $5.6 \times 10^{11}$  Jones, and an EQE value greater than 10<sup>7</sup>% at 532 nm light illumination under optical power of 1.5 µW due to the photogating effect. Also under similar illumination conditions, the photocurrent of CsPbI<sub>3-x</sub>Br<sub>x</sub> QDs/1L MoS<sub>2</sub> hybrid phototransistor was found to be increased by 15.3 times that of a pristine MoS<sub>2</sub> phototransistor, indicating the efficient separation of photogenerated carriers and the strong absorption of 0D CsPbI<sub>3-x</sub>Br<sub>x</sub> QDs.

MoS<sub>2</sub> layers combined with perovskite CsPbBr<sub>3</sub> nanosheets have been investigated for fabricating photodetectors, as reported by Song et al.191 The MoS2/CsPbBr3 hybrid-based photodetector showed a photoresponsivity of 4.4 A W<sup>-1</sup>, a detectivity of  $2.5 \times 10^{10}$  Jones, and a 302% EQE arising from photoexcited carrier separation at the interface of the perovskite CsPbBr<sub>3</sub> nanosheet and MoS<sub>2</sub> layer. The photoresponsivity of the MoS<sub>2</sub>/CsPbBr<sub>3</sub> hybrid-based photodetector increased by three orders of magnitude compared to the MoS<sub>2</sub> photodetector without the perovskite CsPbBr3. The response time of the hybrid photodetector decreased from 65.2 to 0.72 ms after adding MoS<sub>2</sub> layers. The high photon absorption by the CsPbBr<sub>3</sub> perovskite layer and the carrier transport by the MoS<sub>2</sub> layer contributed to the high performance of the photodetector devices. The 3 MoS<sub>2</sub>/CsPbBr<sub>3</sub> hybrid, CsPbBr<sub>3</sub> and MoS<sub>2</sub> photodetector devices showed current in the 0.1-1 nA range. Photocurrents of 5030, 1230, and 54 nA were measured for the MoS<sub>2</sub>/CsPbBr<sub>3</sub> hybrid, CsPbBr<sub>3</sub>, and MoS<sub>2</sub>, respectively. Light on/off ratios of 16 700, 14 300, and 150 were calculated for the MoS<sub>2</sub>/CsPbBr<sub>3</sub> hybrid, CsPbBr<sub>3</sub>, and MoS<sub>2</sub> photodetector devices, respectively. PL quenching, as well as a fast decay time, was observed for the MoS<sub>2</sub>/CsPbBr<sub>3</sub> hybrid due to the charge transfer from the perovskite CsPbBr3 nanosheet to the MoS2 atomic layers. Kang et al.192 reported perovskite/MoS2/APTES

hybrid heterostructure-based photodetector devices. The photoresponsivity of a MoS<sub>2</sub> photodetector was enhanced from 636 to 4.9  $\times$  10 $^3$  A W $^{-1}$  and detectivity from 1.53  $\times$  10 $^9$  to 8.76  $\times$ 10<sup>10</sup> Jones for a perovskite/MoS<sub>2</sub> hybrid device after applying the perovskite layer at 520 nm. The similar increment was also observed for 655 and 785 nm laser wavelengths, but for 850 nm. The photocurrent of the perovskite/MoS<sub>2</sub>/APTES hybrid photodetector was increased by 25.9 times that of the MoS<sub>2</sub> photodetector at 520 nm wavelength. The photoresponsivity and detectivity of the perovskite/MoS<sub>2</sub>/APTES hybrid photodetector device were enhanced from 816.6 to  $2.11 \times 10^4$  A W<sup>-1</sup> and from  $3.93 \times 10^9$  to  $1.38 \times 10^{10}$  Jones after APTES n-doping, respectively. The photoresponsivity of the perovskite/MoS<sub>2</sub>/APTES hybrid photodetector was increased by 94.2 times, from 2.11  $\times$  $10^4$  to  $1.94 \times 10^6$  A W<sup>-1</sup> at 520 nm as a function of incident laser power (1.57 nW to 4.63 pW), while the highest detectivity value was  $1.29 \times 10^{12}$  Jones due to the decreased scattering between photogenerated electrons. The perovskite/MoS<sub>2</sub>/APTES hybrid photodetectors showed significantly higher photoresponsivity values compared with the MoS<sub>2</sub>/APTES photodetector. 180 The performance of photodetector devices followed the sequence as: perovskite/MoS<sub>2</sub>/APTES > perovskite/MoS<sub>2</sub> > MoS<sub>2</sub>, as clearly evident from the above-mentioned results. Since perovskites are susceptible to environmental degradation, 8,130 therefore, the of perovskite/MoS<sub>2</sub>/APTES photodetectors was improved by applying encapsulating layers of octadecyltrichlorosilane (OTS) and PMMA. The stability of nonencapsulated, PMMA and OTS/PMMA encapsulated perovskite/MoS2/APTES photodetector devices in air was measured at different wavelengths: 520, 655, 785 and 850 nm. Photoresponsivity and detectivity deteriorated by 50% and 70% after 68 h for PMMA and 20.4% and 28.7% after 200 h for OTS/PMMA encapsulated devices, and 20.4-24.8% and 28.7-34.2% for perovskite/MoS<sub>2</sub>/APTES photodetectors at different wavelengths, respectively. These data showed that performance of MoS<sub>2</sub> photodetectors can be improved by applying a perovskite absorption layer and furthermore via a chemical doping process.

The flexible perovskite/MoS2 hybrid photodetectors were developed using a polyethylene terephthalate (PET) substrate. Sun et al.76 used CVD grown atomic layered MoS2 film, deposited a 20 nm Ti/50 nm Au thick electrode and then spin-coated a triple cations  $[Cs_{0.05}(MA_{0.17}FA_{0.83})_{0.95}Pb(I_{0.83}Br_{0.17})]_3$  lead mixed-halide perovskite layer to fabricate a hybrid photodetector. Fig. 7 shows the schematics and energy-band diagram of the perovskite/MoS<sub>2</sub> hybrid photodetector under illumination, photoresponse of the pristine MoS<sub>2</sub> and perovskite/MoS<sub>2</sub> hybrid photodetector devices and mechanical stability test of the flexible hybrid photodetector device up to 20 000 bending cycles. The flexible perovskite/MoS2 hybrid photodetectors showed photoresponsivity of 342 A  $W^{-1}$  at 2 V bias potential without any gate voltage at 520 nm under 2.2 pW incident power. The hybrid photodetector devices showed high stability without any encapsulation, photoresponse and decay times of 27 ms and 21 ms, respectively. The hybrid devices were fabricated on rigid SiO<sub>2</sub>/Si, glass and flexible PET substrates. The pristine MoS<sub>2</sub> photodetector device showed the photocurrent of 32 nA at 2 V

bias potential with 20 nW incident power, which increased to 84 nA after spin-coating the perovskite layer. The perovskite/MoS<sub>2</sub> hybrid device showed photocurrent of 2 pA at 1 V and 3.8 pA at 2 bias potential. At 1 V bias potential, the photocurrent of the hybrid device increased from 2 pA in the dark to 40 nA under illumination. The hybrid photodetector device having 10 µm channel exhibited the highest photoresponsivity value of  $1.7~\mathrm{A~W}^{-1}$  under 50 nW incident power. The estimated detectivity was  $1.14 \times 10^{12}$  Jones. The photocurrent of the hybrid devices increased as a function of increased incident power. The photoresponsivity of the hybrid photodetector device was dramatically increased to 342 A W<sup>-1</sup> as the incident power decreased to 2.2 pW because of the suppressed scattering between the photogenerated charge carriers, and mechanical stability test on flexible perovskite/MoS2 hybrid photodetectors was performed with 5 mm curvature up to 20 000 bending cycles. The device retained 91% photocurrent value under bending compared with the corresponding I-V curves of a device without bending. There was no noticeable decline in photocurrent ratio from 2000 to 20 000 bending cycles, indicating the strong mechanical stability of the flexible perovskite/ MoS<sub>2</sub> hybrid devices.

#### 3.4 2D-0D MoS<sub>2</sub>-quantum dots (QDs) heterostructures

As discussed above, photodetectors fabricated with hybrid MoS<sub>2</sub>/PbS QDs yield significantly high photoresponsivity.<sup>188</sup> 0D QDs have been used for improving the performance of MoS<sub>2</sub>

photodetectors. Huo et al. 193 developed photodetectors by incorporating mercury telluride (HgTe) colloidal OD film into a TiO<sub>2</sub>-encapsulated few-layer MoS<sub>2</sub> channel. In the MoS<sub>2</sub>/TiO<sub>2</sub>/ HgTe hybrid heterostructure, TiO2 is a buffer layer between the MoS<sub>2</sub> channel and the HgTe QD layer that acts as an electron accepting medium to form a p-n junction with the HgTe QDs to facilitate the transfer of photogenerated charges from the HgTe QDs to the MoS<sub>2</sub> channel. MoS<sub>2</sub>/TiO<sub>2</sub>/HgTe hybrid photodetectors showed a high photoresponsivity of 10<sup>6</sup> A W<sup>-1</sup> under an incident power of 70 fW (0.35  $\mu$ W cm<sup>-2</sup>) at a gate voltage ( $V_g$ ) of -15 V and a  $V_{\rm ds}$  of 1 V, which is seven orders of magnitude higher than that of the HgTe QD photodetector due to the low carrier mobility  $(2 \times 10^{-3} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1})$  of the HgTe QDs. The detectivity of  $MoS_2/TiO_2/HgTe$  hybrid photodetectors was 1  $\times$ 10<sup>12</sup> Jones at a 2.0 μm wavelength, which is four orders of magnitude higher than that of pure HgTe-based photodetectors (10<sup>7</sup> to 10<sup>8</sup> Jones). This study is an excellent example of extending the spectral wavelengths of a MoS2-based photodetector over 2.0 µm. In another study, Zhang et al. 194 reported 2D MoS<sub>2</sub>-0D zinc cadmium selenide (ZnCdSe)/zinc sulfide (ZnS) colloidal QD-based photodetectors, where monolayer (1L) to multilayer (ML) MoS2 thin film acts as a carrier transport channel and a core/shell ZnCdSe/ZnS QDs sensitizing thin layer functions as a light harvester. Fig. 8 compared the photoresponsivity and detectivity as a function of laser incident power for the pristine MoS<sub>2</sub> based photodetctors with hybrid MoS<sub>2</sub>-ZnCdSe/ZnS QD-based photodetectors having monolayer MoS<sub>2</sub> (1L), bilayer MoS<sub>2</sub> (2L), trilayer MoS<sub>2</sub> (3L), and multilayer MoS<sub>2</sub>

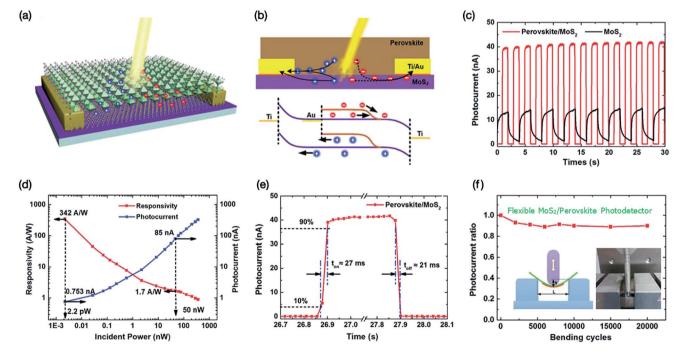


Fig. 7 (a) Schematic illustration of perovskite/ $MoS_2$  hybrid based photodetector. (b) Working mechanism and energy-band diagram of flexible perovskite/ $MoS_2$  hybrid photodetector under illumination. (c) A comparison of the transient photoresponse of the pristine  $MoS_2$  and flexible perovskite/ $MoS_2$  hybrid based photodetectors under on/off illumination. (d) Photoresponsivity and photocurrent of the flexible perovskite/ $MoS_2$  hybrid photodetector devices as a function of laser incident power. (e) Photoresponse rise and decay time of the flexible perovskite/ $MoS_2$  hybrid based photodetector. (f) Mechanical stability test of the flexible perovskite/ $MoS_2$  hybrid photodetector device up to 20 000 bending cycles. Reprinted with permission from ref. 76, copyright @ Elsevier.

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(ML). There is a very significant increase in photocurrent, photoresponsivity, and detectivity after adding ZnCdSe/ZnS QD sensitizing layer. The photocurrent of hybrid MoS2-ZnCdSe/ZnS QD-based photodetectors increased by 1000 folds compared with pristine MoS<sub>2</sub> photodetectors. The response time of the MoS2-ZnCdSe/ZnS QD-based photodetector was reduced to 0.3 s from 15 s for MoS<sub>2</sub> layers, making the hybrid device 50 times faster. The schematic of the MoS2-ZnCdSe/ZnS QD interface and their energy diagram depict the transfer of electrons from ZnCdSe/ZnS QDs to MoS2 layers via a tunneling process and the transfer of excitons from ZnCdSe/ZnS QDs to the MoS<sub>2</sub> layer via nonradiative energy transfer (NRET) processes after a heterojunction formation. In the NERT process, the MoS2 layer acts as an acceptor, whereas the ZnCdSe/ZnS QDs thin layer acts as a donor. The photoresponsivity of the hybrid MoS2-ZnCdSe/ZnS QD-based photodetectors increased by three orders of magnitude to  $3.7 \times 10^4$  A W<sup>-1</sup> compared to pristine MoS<sub>2</sub> layers of 10 A W<sup>-1</sup>. Likely, the detectivity of the MoS2-ZnCdSe/ZnS QD-based photodetector increased to  $1.0 \times 10^{12}$  Jones, and the gain increased by five orders of magnitude to  $1.08 \times 10^5$  after adding a layer of QDs due to the increased absorption and efficient transfer of energy from the photoexcited ZnCdSe/ZnS QDs layer to MoS2 layers. The better performance of the 2D-0D hybrid photodetector is associated with high carrier mobility in the MoS<sub>2</sub> layer and the creation of effective photon absorption/exciton in the ZnCdSe/ ZnS QDs layer. The MoS<sub>2</sub> layers efficiently quench the

fluorescence of the ZnCdSe/ZnS QDs in the 2D-0D hybrid nanostructures exhibiting ultrasensitivity and high gain.

#### 3.5 2D-2D MoS<sub>2</sub>-2D van der Waals heterostructures (vdWHs)

MoS2-based photodetectors have been designed and developed using different electrode materials and van der Waals heterostructures (vdWHs) to improve their optoelectronic properties. The performance of MoS<sub>2</sub>-based photodetectors can be increased using rGO layers. 178,179 Fig. 9(a-c) shows a schematic of the multilayer MoS<sub>2</sub> photodetector developed with Mo bottom contacts (100 nm) on thermally oxidized SiO<sub>2</sub>/Si substrates (270 nm) and the photoresponsivity and EQE of the ML MoS<sub>2</sub> photodetector measured over the 400-1100 nm spectral region, as reported by Saenz et al. 195 The photodetector exhibited ultrahigh photoresponsivity of  $1.4 \times 10^4 \text{ A W}^{-1}$  and detectivity of  $2.3 \times 10^{11}$  Jones at a 700 nm wavelength with a 14.5 pW laser power for the multilayer MoS<sub>2</sub> device fabricated using 100 nm thick Mo bottom electrodes, with a broadband photoresponse from the UV to IR regime. The photoresponsivity increased from 8 imes 10 $^3$  A W $^{-1}$  at 400 nm to 1.4 imes 10 $^4$  A W $^{-1}$  at 1100 nm at a bias voltage of 20 V, and the EQE varied from 3.6 imes $10^4$  to  $1.4 \times 10^4$  within the 400 nm to 1100 nm wavelength range. Photoresponsivities of  $1 \times 10^3$  A W<sup>-1</sup> and 42 A W<sup>-1</sup> were recorded at incident powers of 70 pW and 15.85 nW, respectively, at a bias voltage of 5 V and 300 K. The decrease in the photoresponsivity resulted from the loss of photocarriers due to

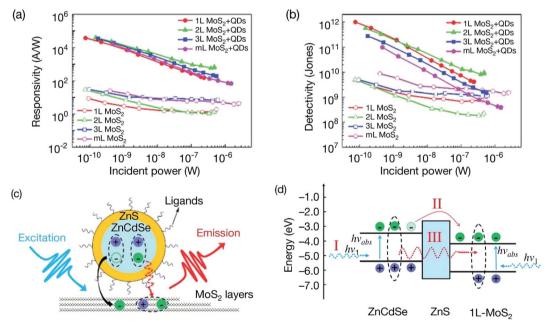


Fig. 8 (a and b) A comparison of photoresponsivity and detectivity of pristine MoS<sub>2</sub> based photodetctors with hybrid MoS<sub>2</sub>-ZnCdSe/ZnS QDbased photodetectors having different MoS<sub>2</sub> layers; monolayer MoS<sub>2</sub> (1L), bilayer MoS<sub>2</sub> (2L), trilayer MoS<sub>2</sub> (3L), and multilayer MoS<sub>2</sub> (ML) as a function of laser incident power. Both responsivity and detectivity increased significantly after adding QD sensitizing layer. (c) Schematic of the MoS<sub>2</sub>-ZnCdSe/ZnS QD interface showing the transfer of electrons from ZnCdSe/ZnS QDs to MoS<sub>2</sub> layers via a tunneling process (represented by black arrow) and the transfer of excitons from ZnCdSe/ZnS QDs to MoS<sub>2</sub> layer via nonradiative energy transfer (NRET) processes (represented by red dashed arrow) under an illumination. (d) Energy diagram of the  $1L MoS_2-ZnCdSe/ZnS QD$  interface after a heterojunction formation where three photoelectrical processes are involved; (I) photon excitation in  $1L-MoS_2$  and ZnCdSe/ZnSQDs; (II) transfer of electrons from the ZnCdSe/ZnSQDs; (II) transfer of electrons from the ZnCdSe/ZnSQDs; ZnS QDs to 1L-MoS<sub>2</sub> via a tunneling process and (III) exciton transfer from the ZnCdSe/ZnS QDs to 1L-MoS<sub>2</sub> via NRET processes. Reprinted with permission from ref. 194, copyright @ American Chemical Society.

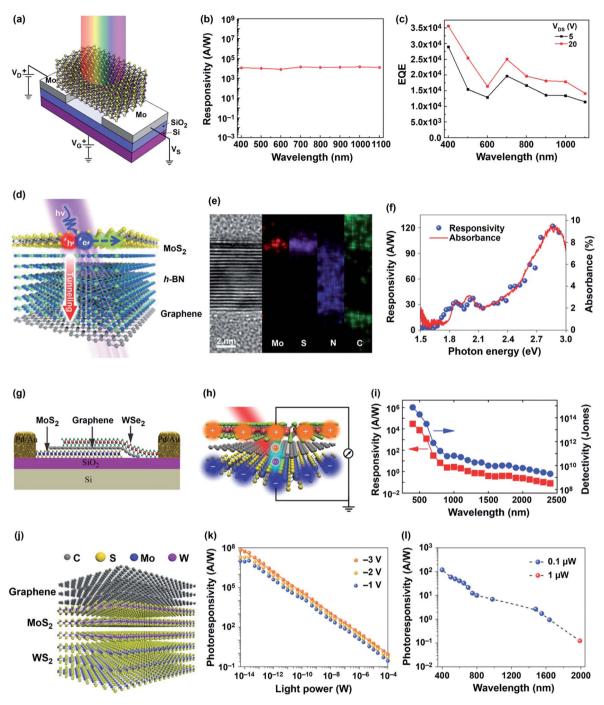


Fig. 9 (a) Schematic of the multilayer MoS $_2$  photodetector fabricated using 100 nm thick Mo bottom contacts on 270 nm thick thermally oxidized SiO $_2$ /Si substrates. (b) Photoresponsivity and (c) external quantum efficiency (EQE) of the ML MoS $_2$  photodetector as a function of wavelength over the 400–1100 nm spectral region. Reprinted with permission from ref. 195, copyright © 2018 Springer Nature Limited. (d) Schematic of the MoS $_2$ /h-BN/graphene vdWH photodetector using the MoS $_2$  layer as a photon absorber, the h-BN layer as a selective hole tunneling layer and the graphene layer as a bottom electrode. The generation of an electron–hole pair upon light illumination and occurrence of selective hole carrier tunneling through the h-BN layer. (e) Cross-sectional STEM image and energy dispersive X-ray spectroscopy (EDS) elemental mapping of the MoS $_2$ /h-BN/graphene vdWHs. (f) Photoresponsivity and absorbance of the MoS $_2$ /h-BN/graphene photodetector as a function of photon energy. Reprinted with permission from ref. 196, copyright © American Chemical Society. (g) Side view of MoS $_2$ /graphene/WSe $_2$  vdWHs. (h) Schematic drawing of atomically layered MoS $_2$ /graphene/WSe $_2$  vdWHs for broadband photodetection. (i) Photoresponsivity and detectivity ( $D^*$ ) of the MoS $_2$ /graphene/WSe $_2$ -based broadband photodetector in the 400 nm to 2400 nm wavelength range. Reprinted with permission from ref. 198, copyright © American Chemical Society. (j) Schematic of the graphene/MoS $_2$ /WS $_2$  vdWH-based optical-fiber compatible photodetector. (k) Photoresponsivity of the graphene/MoS $_2$ /WS $_2$ -based broadband optical-fiber compatible photodetector as a function of laser illumination power at different bias voltages. (l) Photoresponsivity of the graphene/MoS $_2$ /WS $_2$ -based broadband optical-fiber compatible photodetector as a function of wavelength in the 400 nm to 2000 nm spectral range. Reprinted with permission from ref. 199, copyright © Wiley.

recombination effects. Vu et al. 196 used MoS2/h-BN/graphene vdWHs to develop a photodetector. Fig. 9(d-f) depicts a schematic of the MoS<sub>2</sub>/h-BN/graphene photodetector, its crosssectional STEM image, its energy dispersive X-ray spectroscopy (EDS) elemental mapping and its photoresponsivity and absorbance as a function of photon energy. An h-BN insulating layer was inserted between the MoS<sub>2</sub> photoabsorber and the graphene electrode. In these vdWHs, the dark carriers are suppressed at the graphene/h-BN barrier (2.7 eV), whereas the tunneling of photocarriers is facilitated at the MoS<sub>2</sub>/h-BN junction (1.2 eV). Varying the thickness of the h-BN insulating layer from 0-25 nm played an important role in the tunneling of the dark carriers and photocarriers; a 7 nm thick h-BN barrier layer was most effective in blocking the conduction of dark carriers and facilitating the tunneling of photocarriers through the low-hole MoS<sub>2</sub>/h-BN junction. The photodetector fabricated from MoS<sub>2</sub>/h-BN/graphene vdWHs with a 7 nm thick h-BN layer exhibited a photoresponsivity of 180 A W<sup>-1</sup> with a maximum photocurrent/dark current ( $I_{\rm photo}/I_{\rm dark}$ ) ratio of 10<sup>5</sup> and a detectivity of 2.6  $\times$  10<sup>13</sup> Jones. The detectivity of the vdWH-based photodetector was 1000 higher compared with the values of  $2.5 \times 10^{10}$  Jones for the lateral MoS<sub>2</sub> p-n junction<sup>170</sup> and 5 × 10<sup>10</sup> Jones for monolayer MoS<sub>2</sub>-based photodetectors. 197 Furthermore, the rise/fall times of 0.23 s/0.25 s for the vdWHbased photodetector were 1000 times faster than those of the monolayer MoS2-based photodetector.171

Similarly, atomically thin layered MoS<sub>2</sub>/graphene/WSe<sub>2</sub> (p-gn) vdWHs were developed by Long et al. 198 In this vdWH, graphene was sandwiched within the p-n junction to broaden the absorption spectral range and photodetection sensitivity. Fig. 9(g-i) shows a side view of MoS<sub>2</sub>/graphene/WSe<sub>2</sub> vdWHs, a schematic for the broadband photodetection and the wavelength-dependent photoresponsivity and detectivity (D) of the MoS<sub>2</sub>/graphene/WSe<sub>2</sub>-based broadband photodetector over the 400 nm to 2400 nm wavelength range. Both the photoresponsivity and detectivity decreased with increasing excitation laser wavelength. The maximum photoresponsivity and detectivity values of the p-g-n heterostructure-based photodetector were on the order of 10<sup>4</sup> A W<sup>-1</sup> and 10<sup>15</sup> Jones in the visible range and decreased to a few mA W<sup>-1</sup> and 10<sup>9</sup> Jones at the 2400 nm wavelength, respectively. A photoresponsivity of  $4250 \,\mathrm{AW}^{-1}$ , a detectivity of  $2.2 \times 10^{12} \,\mathrm{Jones}$  and an EQE value of  $1.0 \times 10^6$ % were measured at 532 nm with a 0.2 nW laser power intensity for the p-g-n heterostructure-based photodetector, while the photoresponsivity dropped to  $306 \text{ mA W}^{-1}$  in the near-IR region, 940 nm with a 17 nW laser power. The photocurrent mapping conducted at 830 nm with a 20.5 μW laser power indicated that the overlapping regions of the MoS<sub>2</sub>, graphene and WSe2 atomic layers are responsible for the strong photoresponse instead of the electrode regions. The MoS<sub>2</sub>/graphene/ WSe<sub>2</sub> heterostructure-based broadband photodetector also showed a fast photoresponse with a 53.6 µs rise time and a 30.3 μs fall time, and can be used from the visible to near-IR spectral range at room temperature.

Fig. 9(j-l) illustrates a schematic of the graphene/MoS<sub>2</sub>/WS<sub>2</sub> vdWH-based optical-fiber compatible photodetector fabricated by Xiong *et al.*<sup>199</sup> The photoresponsivity of this optical-fiber

tuned photodetector was recorded as a function of applied laser power at different bias voltages and in the 400 nm to 2000 nm spectral range. The photoresponsivity increased with increasing bias voltage at a fixed incident light power of 1 pW. The fiber-based photodetector was impacted by the trap state of MoS<sub>2</sub> and WS<sub>2</sub>. The optical fiber-based photodetector exhibited a photoresponsivity of 17.1 A W<sup>-1</sup> at 1550 nm, and an optimum photoresponsivity of  $6.6 \times 10^7$  A W<sup>-1</sup> was measured at 400 nm under an incident light power of 6.35 nW cm $^{-2}$  (5 fW) at a -3 V bias voltage. The EQE value of graphene/MoS2/WS2 vdWH reached  $2.06 \times 10^8$  at a 5 fW incident power input (400 nm) and 13.71 at 1550 nm, orders of magnitude higher compared with multilayer graphene and MoS2/WS2 heterostructure. The photoconductive photobolometric mechanism involved in graphene/MoS<sub>2</sub>/WS<sub>2</sub> vdWH vielded the photoresponse times of 7 ms and 160 ms at the illumination power of 200 µW and 5 mW, respectively, quite different than those of graphene (photobolometric) and MoS<sub>2</sub>/WS<sub>2</sub> heterostructure (photoconductive) resulting from different photogeneration mechanisms. The photoresponsivity was measured as a function of the wavelength by maintaining the incident light power at 100 nW for the 400 nm to 1640 nm range and 1.0  $\mu$ W for the 2.0  $\mu$ m wavelength. The photodetection limit of graphene/MoS<sub>2</sub>/WS<sub>2</sub> vdWH was between 400 nm (5 fW) and 1550 nm (20 nW), compared with 0.1 mW at 1550 nm for graphene and 0.2 nW at 400 nm for MoS<sub>2</sub>/WS<sub>2</sub> heterostructure. The photodetector exhibited a decrease in photoresponsivity as the wavelength was increased from 400 nm to 2.0 µm but retained a high photoresponsivity. This result demonstrates the broadband photodetection of the graphene/MoS<sub>2</sub>/WS<sub>2</sub> vdWH-based photodetector from the visible to IR ranges.

The MoS<sub>2</sub>-based vdWHs are also interesting for developing highly sensitive photodetectors. Liu et al.200 developed photodetectors using vertically stacked p-Sb<sub>2</sub>Te<sub>3</sub>/n-MoS<sub>2</sub> vdWHs, which showed a photoresponsivity of 330 A  $W^{-1}$ , a fast response time of <500 µs and a power conversion efficiency of 4.5%. Yang et al.201 fabricated few-layer SnSe/MoS2 vdWHs with a current  $I_{\rm on}/I_{\rm off}$  ratio of 1  $\times$  10<sup>5</sup>. The type-II SnSe/MoS<sub>2</sub> heterostructure FET showed a fast response time of <10 ms, a photoresponsivity  $(R_{\lambda})$  of 100 A W<sup>-1</sup>, and an EQE of 23.3  $\times$  10<sup>3</sup>% under 532 nm light illumination. The gallium telluride (GaTe)-MoS<sub>2</sub> p-n vdW heterojunction FET showed a fast response time of <10 ms, a photoresponsivity of 1.365 AW<sup>-1</sup>, and an EQE of 266% under 633 nm light illumination,167 much higher compared with the photoresponsivity of 0.03 A W<sup>-1</sup> for a flexible GaTe photodetector measured at a wavelength of 473 nm under an incident laser power of 80.5 mW cm<sup>-2</sup>.202 The electronic and optoelectronic properties of MoS<sub>2</sub> have been improved by fabricating vdWH-based FETs with other 2D materials.36,203 The vertically stacked vdWHs of SnS<sub>2</sub>/MoS<sub>2</sub> monolayers showed improved mobility of 27.6 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>,  $I_{\text{on}}/I_{\text{off}}$  ratio of 10<sup>6</sup>, and photoresponsivity of 1.36 A W<sup>-1</sup>.<sup>204</sup> 2D layered vdW semiconductor MoTe<sub>2</sub> has been used with MoS<sub>2</sub> to develop vdW heterojunction p-n diodes for extending the range of photodetection in the NIR region. Ding et al.166 fabricated vertically stacked 2H-MoTe<sub>2</sub>/ MoS<sub>2</sub> bilayer heterostructures using CVD technique for broadband photodetectors ranging from 200 nm (UV) to 1100 nm

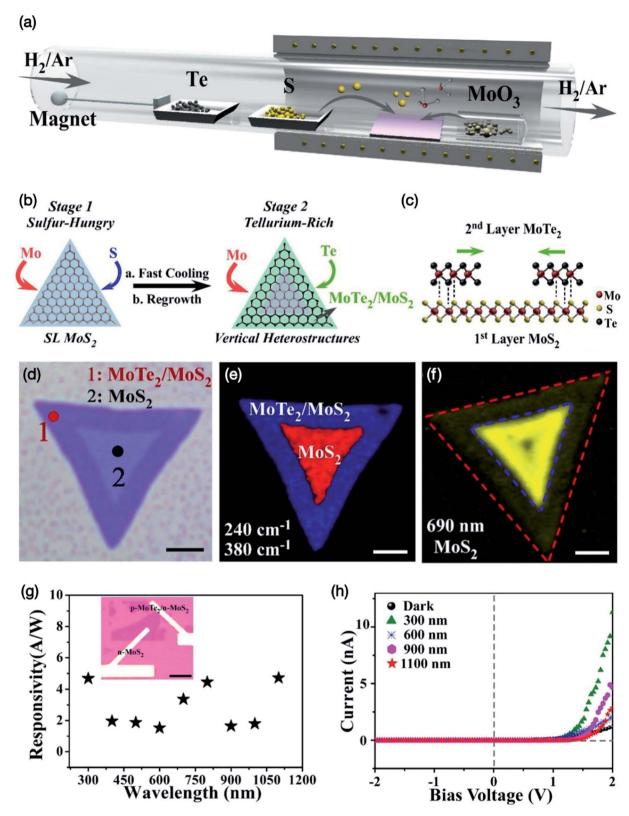


Fig. 10 (a) Schematic diagram of experimental set-up showing magnet-assisted CVD growth method for preparing  $MoTe_2/MoS_2$  heterostructure. (b) Vertically stacking approach of  $MoTe_2/MoS_2$  bilayer heterostructures. (c) Schematic side view of the  $MoTe_2/MoS_2$  bilayer heterostructure where Mo atoms are represented in red, S atoms in yellow, Te atoms in black. (d) Optical image of the  $MoTe_2/MoS_2$  flake. (e) Raman intensity mapping at 240 cm<sup>-1</sup> shown in blue and 380 cm<sup>-1</sup> in red. (f) PL intensity mapping at 690 nm wavelength where the red dash lines defect the  $MoTe_2/MoS_2$  heterojunction and the blue dash lines indicates the interface of regions with the inner core and outside ring. (g) Photoresponsivity of  $MoTe_2/MoS_2$  photodetectors as a function of wavelength between 300 nm to 1100 nm region. (h) I-V current characteristics of the  $MoTe_2/MoS_2$  photodetectors at different applied bias voltage. Reprinted with permission from ref. 166, copyright © Elsevier.

(NIR) regions. Fig. 10 shows the magnet-assisted CVD growth method, stacking approach of MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructures, optical image of the MoTe2/MoS2 flake, Raman intensity and PL mapping, photoresponsivity and I-V current of the MoTe<sub>2</sub>/MoS<sub>2</sub> heterostructure-based photodetectors. MoTe<sub>2</sub> was observed to grow along the edges of MoS<sub>2</sub> seeds. During the first stage, the sulfur-hungry environment assisted in growing the initial MoS<sub>2</sub> seeds. In the second stage, MoTe<sub>2</sub> was seen to grow over the first MoS2 monolayer from the edge nucleation and thereafter epitaxial growth of MoTe2 occurred from the center area on the MoS2 surface to create a vertically stacked MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructure. Atomic force microscopy (AFM) evidenced from the height image of a triangular MoTe<sub>2</sub>/ MoS<sub>2</sub> bilayer heterostructure that center and outside regions have a thickness of 0.8 nm and 1.6 nm, respectively. The center area is the MoS<sub>2</sub> monolayer whereas the outside area is a vertically stacked MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructure. The core-ring structure of vertically stacked MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructures also was confirmed by the Raman mapping of MoTe<sub>2</sub> at 240 cm<sup>-1</sup> and MoS<sub>2</sub> mapping at 380 cm<sup>-1</sup> and 375 cm<sup>-1</sup>. PL spectra showed emission peaks at 640 nm and 690 nm for the MoS<sub>2</sub> flake where the peak at 690 nm indicates a significant quenching for the MoS2. A band alignment occurred when the MoS<sub>2</sub> monolayer was vertically stacked with the MoTe<sub>2</sub> monolayer due to the interlayer coupling interactions. The vertically stacked MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructures also showed higher image contrast than that of the MoS2 monolayer with high-angle annular dark field (HAADF) STEM. The photoresponsivity and external quantum efficiency (EQE) of 4.71 A  $W^{-1}$  and 532% at 1100 nm and 4.67 A  $W^{-1}$  and 1935% at 300 nm under the light power density of 4.209 mW cm<sup>-2</sup> were measured for the MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructure-based photodetectors, respectively, which was up to two orders of magnitude higher compared with an exfoliated MoTe<sub>2</sub> heterostructure-based photodetector. Epitaxial growth of MoTe<sub>2</sub> monolayer on the top and along the edges of MoS2 monolayer having a 2H-stacking mode dramatically enhanced the contact and interfacial interactions of the MoTe2/MoS2 bilayer heterostructures, which yielded a better performance of photodetectors from UV to infrared regions. Ahn et al.205a fabricated selfpowered visible-invisible multiband photodetectors using MoTe<sub>2</sub>/MoS<sub>2</sub> multilayer-based semivertical heterojunction p-n diodes, which showed an ideality factor of less than 1.5 and current  $I_{\rm on}/I_{\rm off}$  ratio of more than 10<sup>4</sup>. The MoTe<sub>2</sub>/MoS<sub>2</sub> photodiodes showed photodetection from 405 nm (violet) to 1310 nm (NIR) wavelength region and a linear dynamic range (LDR) of 130 dB between  $10^{-5}$  to 1 W cm<sup>-2</sup> applied laser power intensity in the photovoltaic mode. The MoTe<sub>2</sub>/MoS<sub>2</sub> photodetectors showed photoresponsivity of 0.62 A W<sup>-1</sup> and 0.86 A W<sup>-1</sup> at 532 nm laser illumination, and LDR of 132 dB and 84 dB in the photoconduction mode (V = -2 V), respectively. The values of detectivity ranged from 10<sup>8</sup> to 10<sup>10</sup> Jones within 405-1310 nm wavelength range. A prototype self-powered visible-invisible multiband image sensor was also constructed with MoTe<sub>2</sub>/MoS<sub>2</sub> photodiodes in the photovoltaic mode operation. Wang et al. 205b developed p-MoTe<sub>2</sub>/n-MoS<sub>2</sub> based van der Waals heterojunctions for photodetectors. The multilayer MoTe<sub>2</sub>/MoS<sub>2</sub>

vdWH-based FETs showed a photocurrent that increased by several orders of magnitude with increasing laser power density, a photoresponsivity of 0.15 A W<sup>-1</sup> and an EQE value of 39.4% at a 473 nm laser wavelength, a photocurrent  $I_{\rm on}/I_{\rm off}$  ratio of 780 and a field-effect mobility of 1.9 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>, much larger compared with pure MoTe<sub>2</sub>-based FETs. The photoelectric response of vertically stacked MoTe<sub>2</sub>/MoS<sub>2</sub> bilayer heterostructure-based photodetectors<sup>166</sup> was much higher compared with these MoTe<sub>2</sub>/MoS<sub>2</sub> FET-based photodetectors. The PdSe<sub>2</sub>/MoS<sub>2</sub> 168 vdWH-based photodetectors exhibiting a very broad spectral range from 450 nm (visible) to 10.6 µm (LWIR) have been reported. The photoresponsivity of PdSe<sub>2</sub>/ MoS<sub>2</sub> vdWH-based devices reached 22.86 A W<sup>-1</sup> at 450 nm, 11.15 A W<sup>-1</sup> at 637 nm, 4.24 A W<sup>-1</sup> at 940 nm and 28.83 A W<sup>-1</sup> at 4.012  $\mu$ m at the  $V_{\rm ds}$  of 1 V. The photoresponsivity of heterostructure photodetectors at 4.012 µm was higher than those of 2.7 µm, 3.1 µm, and 10.6 µm wavelengths. The detectivity was more than  $6.88 \times 10^9$  Jones over the full spectral range and reached a maximum value of  $6.09 \times 10^{10}$  Jones at  $4.012~\mu m$ . The low NEP value of 0.13 pW Hz<sup>-1/2</sup> was measured for the heterostructure device in the full spectral region. The photoresponse for heterostructure devices was much faster having rise/fall times of 65.3  $\mu$ s/62.4  $\mu$ s at 637 nm illumination.

A significant improvement in mobility was also observed for NbS2/MoS2 vdWH-based Schottky-effect FETs, which yielded a mobility of 800 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> at room temperature with graphene source/drain (S/D) contacts, compared with the low mobility values of 15–170 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> for pure MoS<sub>2</sub> FETs with Au contacts, depending on the annealing conditions.206 In contrast, lower photoresponsivities were recorded for GaSe/ MoS<sub>2</sub> vertical heterostructure-based FETs at wavelengths from  $300 \text{ nm to } 670 \text{ nm under } 6.412 \text{ mW cm}^{-2} \text{ to } 2.169 \text{ mW cm}^{-2}$ optical power, as were a low mobility of 0.026 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and a low  $I_{\rm on}/I_{\rm off}$  current ratio of  $10^3$ , compared with pure MoS<sub>2</sub> FETs due to the increased scattering of charge transport carriers at the interface of the vdW heterojunctions. 207a Atomic layer vdW heterostructure-based photodiodes were fabricated using n-type MoS<sub>2</sub> on top of p-type GaSe crystals, which showed photoresponsivity of  $\sim$ 3 A W<sup>-1</sup> at 532 nm when symmetric FL graphene contacts were used. 207b However, the asymmetric GaSe/FL graphene and MoS2/Au contacts based vdW photodiodes resulted in a low NEP value of 10<sup>-14</sup> W Hz<sup>-1/2</sup> because of the reduced dark current and a large LDR of ≈70 dB.

## 3.6 Interface coupling effect in dual-gated MoS<sub>2</sub> phototransistors

Different strategies have been used to improve photoresponse of photodetectors. Deng  $et~al.^{208}$  demonstrated that the interface coupling effect (ICE) enhanced photoresponse in fully-depleted silicon-on-insulator (FD-SOI) metal-oxide-semiconductor field-effect transistors (MOSFETs). The thinner Si film-based photodetectors exhibited higher photoresponsivity due to a stronger ICE. CMOS-compatible SOI photodetectors achieved a high photoresponsivity of  $3.3 \times 10^4$  A W $^{-1}$ . This ICE strategy was also employed for improving the performance of MoS $_2$ -based phototransistors. Liao  $et~al.^{209}$  first reported interface coupling effect

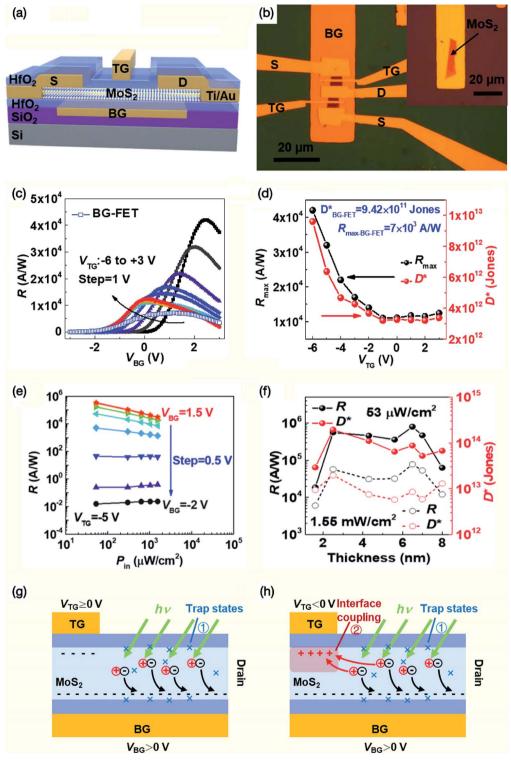


Fig. 11 (a) 3D schematic of a dual-gated (DG) MoS<sub>2</sub> phototransistor on a Si/SiO<sub>2</sub> substrate showing location of top-gate (TG), bottom-gate (BG), source (S), drain (D) and HfO<sub>2</sub> layer as a BG dielectric. (b) Optical microscopic image of a DG MoS<sub>2</sub> phototransistor. Inset is an optical microscopic image of the ML MoS<sub>2</sub> flake. (c) Photoresponsivity (R) of DG MoS<sub>2</sub> phototransistor as a function of back-gate voltage ( $V_{\rm HG}$ ) with illumination power density ( $P_{\rm in}$ ) of 1.55 mW cm<sup>-2</sup> at 550 nm wavelength. Blueline + square symbol represent photoresponsivity of MoS<sub>2</sub> BG-FET. (d) The maximum photoresponsivity ( $R_{\rm max}$ ) and detectivity ( $D^*$ ) as a function of applied  $V_{\rm TG}$ . (e)  $P_{\rm in}$  dependence of photoresponsivity the DG MoS<sub>2</sub> phototransistor with varying  $V_{\rm BG}$  at  $V_{\rm TG} = -5$  V. (f) The MoS<sub>2</sub> thickness (1.6 to 8 nm) dependence of R and  $D^*$  under the illumination power density of 53  $\mu$ W cm<sup>-2</sup> (solid sphere) and 1.55 mW cm<sup>-2</sup> (open circle). Schematic illustrating generated electron-hole pairs in the DG MoS<sub>2</sub> phototransistor with a positive  $V_{\rm TG}$  bias (g) and a negative (h)  $V_{\rm TG}$  bias in connection with interface coupling effect (ICE). Reprinted with permission from ref. 209, copyright © Wiley.

E) phenomenon in dual-gated (DG) MoS<sub>2</sub> phototransistors. current, which ultimately improves the photoresponse of

(ICE) phenomenon in dual-gated (DG) MoS<sub>2</sub> phototransistors. Both negative top-gate (TG) voltage ( $V_{TG}$ ) as well as the positive back-gate (BG) voltage  $(V_{BG})$  is simultaneously applied to the MoS<sub>2</sub> channel in order to facilitate the trapping of photogenerated holes in the depleted region beneath top-gate. In fabricating DG MoS<sub>2</sub> phototransistors, two metal gates were placed on the top and bottom of a MoS<sub>2</sub> layer. Fig. 11 shows a 3D schematic and optical microscopic image of a DG MoS<sub>2</sub> phototransistor, photoresponsivity (R) of DG MoS2 phototransistor as a function of  $V_{BG}$  under different  $V_{TG}$  with illumination power density  $(P_{in})$  of 1.55 mW cm<sup>-2</sup> at 550 nm wavelength,  $R_{max}$  and detectivity ( $D^*$ ) as a function of applied  $V_{TG}$ ,  $P_{in}$  dependent Rwith different  $V_{BG}$ ,  $MoS_2$  thickness dependent R and  $D^*$  values and schematic illustration of ICE in the DG MoS2 phototransistor with positive and negative  $V_{TG}$  biases. The DG MoS<sub>2</sub> photodetector, having varied thickness between 2.5 nm to 6.5 nm, showed the highest photoresponsivity of  $7.7 \times 10^5$  A  $W^{-1}$  and detectivity of 1.9  $\times$  10<sup>14</sup> Jones under illumination power density  $(P_{\rm in})$  of 53  $\mu \rm W~cm^{-2}$  at 550 nm under  $V_{\rm TG} = 5.0~\rm V$ and  $V_{\rm BG} = 2.0$  V. The response and recovery time of the DG MoS<sub>2</sub> photodetector decreased from 11.9 s to 8.3 s and 76.2 s to 46.4 s as the  $V_{\rm TG}$  decreased from -4 V to -6 V, respectively. The maximum photoresponsivity and detectivity of BG-MoS2 FETs were found to be  $7 \times 10^3$  A W<sup>-1</sup> and  $9.6 \times 10^{12}$  Jones, respectively. DG MoS2 photodetectors showed photoresponsivities in 10<sup>4</sup> to 10<sup>5</sup> A W<sup>-1</sup> range independent of the MoS<sub>2</sub> thickness; however, photoresponsivity decreased as the thickness of the MoS<sub>2</sub> channel was less than 2.5 nm or more than 6.5 nm. DG MoS<sub>2</sub> photodetectors having 2.5 and 6.5 nm thickness exhibit a strong ICE under applied negative  $V_{TG}$  and positive  $V_{BG}$ . The photoresponse speed of the DG MoS<sub>2</sub> phototransistors can be adjusted with ICE. This study showed that the interface coupling effect in the DG MoS<sub>2</sub> phototransistors improves the photoelectric performance of photodetectors.

Flexible photodetectors for wearable applications have been developed from a wide variety of nanomaterials, and their performance is controlled by many conditions, including the material synthesis, atomic layer processing, hybrid heterostructures, device fabrication, measurement wavelengths and incident laser power. $^{64,87,208-214}$  The performance of MoS<sub>2</sub>-based photodetectors, such as the detectivity, photoconductive gain, response time and broadband responsivity depends on several factors, including the number of active layers, processing, nature of doping materials, vdW interactions, barrier and junction heterostructures, transport, photocarrier generation and spectral range.215 Additionally, ferroelectric polymers, such as poly(vinylidene fluoride) (PVDF), poly(vinylidene fluoridetrifluoroethylene) [P(VDF-TrFE)] copolymer vinylidene fluoride-trifluoroethylene-chlorofloroethylene) [P(VDF-TrFE-CFE)] terpolymer are unique organic polymers that have been used in flexible electronics because they offer high piezoelectricity, pyroelectricity and ferroelectricity, tremendous mechanical strength and flexibility to integrate into devices such as transducers, sensors, actuators, nonvolatile ferroelectric random-access memory (NV-FeRAM) and ferroelectric FETs.216 Additionally, in the case of MoS2 photodetectors, these ferroelectric polymers help suppress the dark current, which ultimately improves the photoresponse of photodetectors.<sup>137</sup> MoS<sub>2</sub>-based flexible photodetectors are discussed in the next section.

# 4. MoS<sub>2</sub> based flexible photodetectors for wearable technology

Similar to graphene, applications of flexible atomic layered TMDs have been explored for wearable technologies, from electronics to optoelectronics.36 Flexible photodetectors are expected to be important elements of wearable optoelectronic technology in fields from biomedical imaging to surveillance and high-speed broadband optical communication. Flexible photodetectors have been developed using a variety of nanomaterials, from traditional semiconductors, such as Si, Ge, Se, GaP, InP, CdS and ZnSe, 42-49 to newly emerging perovskites, 75,76 as a very wide variety of hybrid heterostructures involving polymers, metal oxides, CNTs, graphene, transition metal trichalcogenides, etc.77-89 Similarly, flexible MoS2 atomic layers and MoS2-based hybrid heterostructures have been explored for fabricating photodetectors for the next generation of wearable technologies. The progress made in developing flexible MoS<sub>2</sub> photodetectors is summarized in this section.

Flexible polymeric substrates based on poly(ethylene terephthalate) (PET), Kapton/polyimide/(PI), poly(methylmethacrylate) (PMMA), poly(ethylene naphthalate) (PEN), poly(dimethylsiloxane) (PDMS) and poly(4-vinylphenol) (PVP) have been generally used for developing wearable electronic and optoelectronic devices due to their inherent mechanical strength and flexibility. 23,25,36 In addition, textile fibers and papers have also been considered for developing flexible devices. Zhang et al.217 reported substratedependent performance of MoS2 photodetectors owing a dualphotogating effect where rigid silicon carbon (SiC) and flexible Kapton (polyimide) films were used as substrates for developing MoS<sub>2</sub> photodetectors. Both SiC and Kapton have strong light absorption, therefore, the dual-photogating effect induced at the interface of the MoS<sub>2</sub>/SiC or MoS<sub>2</sub>/Kapton assists in enhancing the photoresponse of MoS<sub>2</sub>-based photodetectors. Fig. 12 shows the schematic illustrations of MoS2 photodetectors fabricated on updoped SiC and Kapton substrates, their energy level diagrams and the variation of photoresponsivity (R) and on/off ratio ( $I_{photo}$ ) Idark) of rigid MoS2/SiC and MoS2/SiO2/Si photodetectors as well as flexible MoS<sub>2</sub>/Kapton and MoS<sub>2</sub>/PET photodetectors as a function of optical power intensity in the UV and visible wavelengths. The bandgap of 2.7 and 3.2 eV and the electron affinity of 4.2 and 1.8 eV for MoS<sub>2</sub> and SiC are depicted, respectively. The energy level mismatch at the MoS<sub>2</sub>/SiC interface yields to a strong built-in electric field  $(E_{in})$  which assists in separating the photoexcited carriers in MoS2. The enhanced photoresponse was noticed for the MoS<sub>2</sub>/SiC photodetectors more than those of MoS<sub>2</sub>/SiO<sub>2</sub>/Si photodetectors. The energy band diagram in a flexible MoS<sub>2</sub>/Kapton photodetector shows the valence band of MoS₂ as −6.0 eV and conduction band as -4.2 eV and the HOMO level at -5.0 eV and LUMO level at -2.1 eV, versus vacuum. The highest photoresponsivity of  $\sim 10^4$  A W<sup>-1</sup> for MoS<sub>2</sub>/SiC photodetector and the

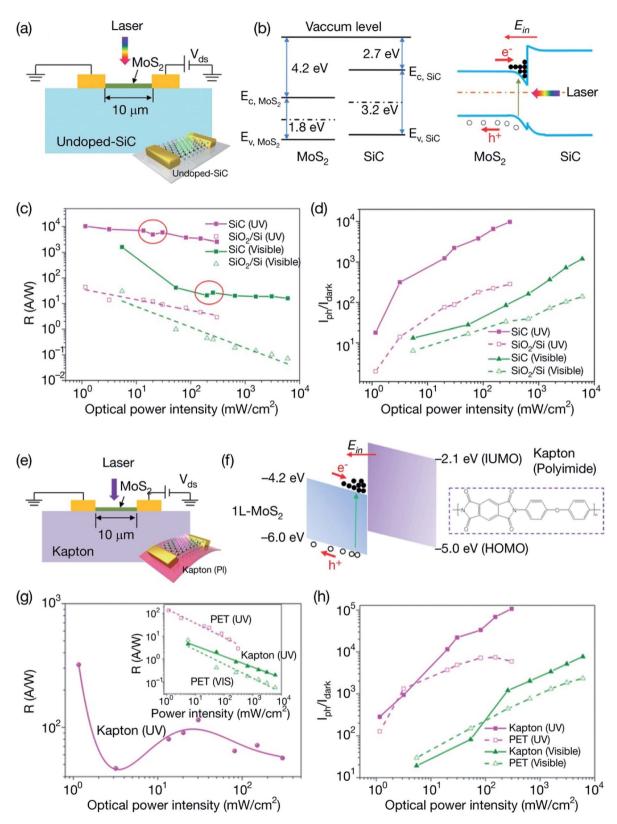


Fig. 12 (a) Schematic illustration of  $MoS_2$  photodetector on a SiC substrate. (b) Energy level diagrams of the  $MoS_2$  and SiC showing electron affinity and bandgap of  $MoS_2$  and SiC.  $MoS_2/SiC$  interface showing a band structure. (c) Variation of photoresponsivity (R) and (d) on/off ratio ( $I_{photo}/I_{dark}$ ) of rigid  $MoS_2/SiC$  and  $MoS_2/SiC_2/Si$  photodetectors as a function of optical power intensity in the UV and visible wavelengths. (e) Schematic illustration of  $MoS_2$  photodetector on a flexible Kapton substrate. (f) Energy band diagram of a flexible  $MoS_2/Kapton$  photodetector. (g) Variation of photoresponsivity (R) and (h) on/off ratio ( $I_{photo}/I_{dark}$ ) of flexible  $MoS_2/Kapton$  and  $MoS_2/PET$  photodetectors as a function of optical power intensity in the UV and visible regions. Reprinted with permission from ref. 217, copyright © Royal Society of Chemistry.

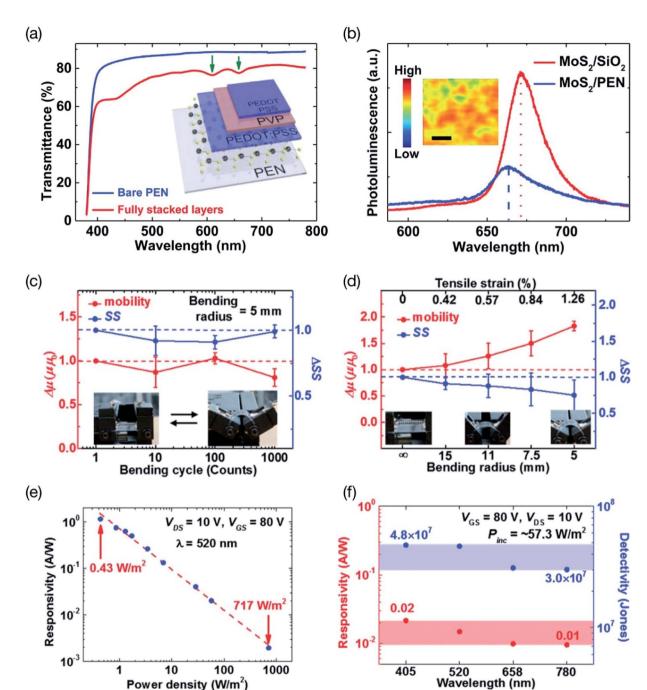


Fig. 13 (a) Transmittance spectra of the flexible bare PEN substrate, denoted by the blue line, and fully stacked PEDOT:PSS/PVP/PEDOT:PSS/  $MoS_2$ /PEN layers, denoted by the red line. The inset is a schematic of the phototransistors with stacked layers. (b) PL spectra of CVD-grown monolayer  $MoS_2$ /SiO<sub>2</sub>/Si and  $MoS_2$ /PEN. The inset is PL intensity mapping at 670 nm (1.85 eV). (c) The variation in mobility and SS values as a function of the number of bending cycles for a 5 mm bending radius, and (d) mobility and SS values at different bending radii of 5, 7.5, 11, 15 mm, and  $\infty$ . (e) Variation of photoresponsivity  $MoS_2$  phototransistors as a function of power density at 520 nm laser wavelength. (f) Photoresponsivity and photodetectivity of transparent  $MoS_2$  phototransistors at different laser wavelengths. Reprinted with permission from ref. 219, copyright © American Chemical Society.

fastest current  $I_{\rm on}/I_{\rm off}$  ratio of  $\sim 10^5$  for MoS<sub>2</sub>/Kapton photodetector were measured at 325 nm laser illumination due to the dual-photogating effect generated at the MoS<sub>2</sub>/substrate interface. SiC and Kapton substrates improve the photoresponse of MoS<sub>2</sub> photodetectors due to the light absorption.

Transparent poly(4-vinylphenol) (PVP) as the encapsulation layer, as well as a gate dielectric was used by Ma *et al.*<sup>218</sup> for

developing flexible  $MoS_2$  phototransistors on a polyarylate substrate. PVP thin film having  $\geq 80\%$  transmittance between 400 nm to 900 nm was used. The PVP encapsulation not only increased the mobility but also improved the current  $I_{\rm on}/I_{\rm off}$  ratio and subthreshold slope. The photoresponsivity (2 A W<sup>-1</sup>), as well as the detectivity (3.1  $\times$  10<sup>12</sup> Jones) of  $MoS_2$  phototransistors, was increased by two orders of magnitude over the

visible to IR range due to the doping effect of hydroxyl groups in PVP. For a comparison, the transparent PVP polymer improved the photoresponsivity of  $MoS_2$ -based flexible phototransistor devices by ten fold over that of PMMA encapsulated devices. The photodetectors developed from monolayer and bilayer  $MoS_2$  encapsulated with a  $HfO_2$  layer showed photoresponsivity in the wide range of 10– $10^4$  A W<sup>-1</sup> and a response time from 10 ms to 10 s. These studies show the role of encapsulation in increasing the photoresponse of  $MoS_2$ -based photodetectors.

Transparent and flexible MoS2 phototransistor arrays using all-organic components with inkjet-printing technology were developed by Kim et al.219 The CVD-grown monolayer MoS2 channel layers were transferred onto a flexible PEN substrate. The all-organic components, including poly(3,4ethylenedioxythiophene)polystyrenesulfonate (PEDOT:PSS)based source/drain electrodes, PVP as a gate dielectric layer, and PEDOT:PSS as a top-gate electrode, were consecutively inkjet printed on the monolayer MoS<sub>2</sub>/PEN substrate. The formation of CVD-grown monolayer MoS2 was confirmed by Raman spectroscopy, XPS, scanning transmission electron microscopy (STEM) coupled with energy dispersive X-ray spectroscopy (EDS), PL spectroscopy, and optical transmittance spectroscopy as demonstrated in Fig. 13(a and b). The optical transmittance of the inkjet-printed MoS<sub>2</sub> phototransistors was 76%, compared with 87% for the PEN substrate in the same visible wavelength range. The performance of printed MoS2 phototransistors was not degraded under 1000 repeated bending cycles, as shown by the mobility and SS values for a fixed 5 mm bending radius, which corresponds to 1.26% uniaxial tensile strain along the MoS<sub>2</sub> channel length, demonstrating good mechanical stability as shown in Fig. 13(c and d). The mobility and SS values of MoS<sub>2</sub> phototransistors measured at bending radii of 15, 11, 7.5, and 5 mm increased as the bending radius decreased. Fig. 13(e and f) shows the photoresponsivity and photodetectivity of transparent MoS<sub>2</sub> phototransistors as a function of wavelength over the 405-780 nm region at a fixed laser power density of 57.3 W m<sup>-2</sup>, a  $V_{\rm gs}$ of 80 V, and a  $V_{\rm ds}$  of 10 V. The photoresistivity, detectivity and EQE of MoS<sub>2</sub> phototransistors showed wavelength dependence, varying between 0.01 and 0.02 A W $^{-1}$ , 3.0 and 4.8  $\times$  10 $^{7}$  Jones, and 1.5 and 6.6%, respectively.

Flexible photodetectors obtained by depositing MoS<sub>2</sub> layers on a PI substrate were developed by Lim et al. 220 The MoS<sub>2</sub> layers were characterized in terms of their uniformity, stoichiometry and structural homogeneity by Raman, AFM, and XPS techniques. The frequency difference of 23.4  ${\rm \,cm^{-1}}$  between the  ${\rm E_{2g}}^{1}$ and A<sub>1g</sub> Raman vibration modes of the MoS<sub>2</sub> layers indicated few-layer MoS2 thin films. TEM showed the formation of fivelayer MoS<sub>2</sub> films and an interlayer spacing of 6 Å. The optical transmittance was 90.8% at 550 nm for the  $MoS_2$  films deposited on a glass substrate. MoS2 FETs showed a mobility of 14 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and an on-off current ratio of  $5 \times 10^2$ . The MoS<sub>2</sub> photodetector arrays were also fabricated on a 4-inch SiO<sub>2</sub>/Si wafer. Fig. 14 shows a photograph of the MoS<sub>2</sub> layer on a flexible PI film, XPS spectra, time-dependent photocurrents before and after bending up to 10<sup>5</sup> bending cycles, and the change in the photocurrent of MoS2-based flexible photodetectors as a function of the bending cycle at 20 V. The visible-light photodetectors exhibited a response time of 13 s and a recovery time of 30 s.  $MoS_2$  photodetectors were formed on a flexible PI substrate, and the photocurrent decreased by 5.6% after  $10^5$  bending cycles at a bending radius of 5 mm.

Enhancement of the photocurrent and sensitivity has been observed for flexible p-CuO/n-MoS2 heterojunction-based photodetectors.221 The dark current of CuO/MoS2 heterojunction increased from 0.039 nA to 0.12 nA as the tensile strain was increased from 0% to 0.65%, whereas the photocurrent increased to 108 nA under 0.65% tensile strain with 1656 mW cm<sup>-2</sup> light intensity, which is 2770-fold increase in the photocurrent over that of the dark current. The photocurrent of the p-CuO/n-MoS<sub>2</sub> heterojunction increased 27 times under 0.65% tensile strain compared with that of the strain-free heterojunction at 532 nm, and the sensitivity reached  $3.27 \times 10^8$ Jones. The photoresponse of a flexible CuO/n-MoS2 heterojunction based photodetector was increased by the piezophototronic effect. Zhang et al. 222 fabricated a MoS2 phototransistor on a transparent and flexible biodegradable paper substrate using a gel electrolyte gate dielectric. The gel electrolyte thin layer was coated on top of mechanically exfoliated MoS2 flakes as the gate dielectric. The optical transmittance of the MoS<sub>2</sub> phototransistor at 550 nm was 82%, compared with 85% for the bare nanopaper, due to the added passivation layer and gel electrolyte gate dielectric. The MoS2 phototransistor exhibited a photoresponsivity of 1.5 kA W<sup>-1</sup> at an illumination power of 10 nW. The MoS2 phototransistor showed high flexibility and optical transparency with great photoresponsivity.

The solution-processed few-layer MoS2 thin films on several flexible substrates, including PI, Al, and Cu foils, cotton thread, and cellulose, carbon, and ceramic paper were developed by Sahatiya et al. 223 The growth of layers and morphologies of the MoS<sub>2</sub> nanosheets varied depending on the substrate. The photodetectors fabricated from these MoS2 nanosheets showed that the defects introduced during growth control the photocurrent response. Sahatiya et al. 224 also fabricated a broadband flexible photodetector using 1D V<sub>2</sub>O<sub>5</sub> NWs and 2D MoS<sub>2</sub> flakes covering the UV (365 nm) to NIR (780 nm) region, wherein V<sub>2</sub>O<sub>5</sub> NWs absorb in the UV-visible, and MoS2 absorbs in the visible-NIR regions. The V<sub>2</sub>O<sub>5</sub>/MoS<sub>2</sub> hybrid device showed a responsivity of 41.5 mA W<sup>-1</sup> in the UV, 65.1 mA W<sup>-1</sup> in the visible, and 29.4 mA W<sup>-1</sup> in the NIR. The same research team<sup>225</sup> also developed a flexible photodetector using MoS2/C QD hybrid films. The wide UV-vis-NIR absorbance range originated from the UV absorbance of the C QDs and the visible-NIR region absorbance of MoS2. The MoS2/C QD sensor showed photoresponsivities of 2.62, 8.4, and 18.12 mA  $W^{-1}$  in the NIR, UV, and visible regions, respectively. The MoS<sub>2</sub>/C QD sensor showed almost no change in photoresponse up to 500 bending cycles. These flexible MoS<sub>2</sub>/C QD broadband photodetectors can be used for wearable electronics for surveillance purposes.

## 4.1 MoS<sub>2</sub>/graphene hybrid heterostructures for flexible photodetectors

The indirect bandgap restricts the photodetection ability of multilayer MoS<sub>2</sub>. Hybrids of MoS<sub>2</sub> atomic layers with gapless

Photocurrent (nA)

Review

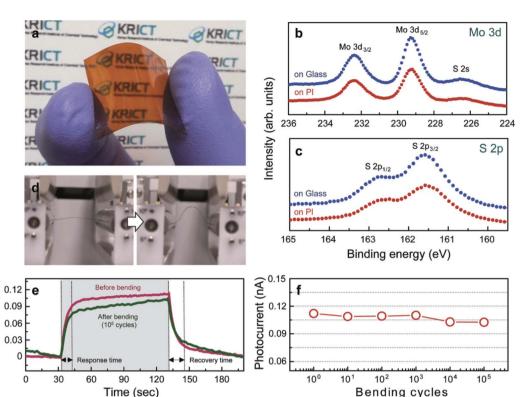


Fig. 14 (a) Photograph of the MoS<sub>2</sub> layer on a flexible PI film. (b) XPS spectra showing the Mo 3d core level and (c) S 2p core level spectra of MoS<sub>2</sub> layers on glass and PI substrates. (d) Bending of a flexible MoS<sub>2</sub> layer deposited on a PI substrate at a 5 mm bending radius. (e) Time-dependent photocurrents of MoS<sub>2</sub>-based flexible photodetectors measured at an incident power of 12.5 mW cm<sup>-2</sup> and V = 20 V, before and after bending up to  $10^5$  bending cycles. (f) The variation in the photocurrent of the MoS<sub>2</sub> photodetector as a function of the bending cycle. Reprinted with permission from ref. 220, copyright © 2016 Wiley-VCH.

graphene have been used to improve the optoelectronic properties by utilizing the high carrier mobility, ultrafast response and broadband absorption of graphene and the generation of electron-hole pairs by MoS2. Ross et al.126 obtained a high carrier mobility (1 × 10<sup>4</sup> cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>) in a graphene/MoS<sub>2</sub> hybrid structure by placing monolayer graphene on a multilayer MoS<sub>2</sub> nanosheet on a Si/SiO<sub>2</sub> substrate. The graphene/MoS<sub>2</sub> hybrid-based photodetector showed high photoresponsivities of  $1 \times 10^{10} \, \text{A W}^{-1}$  at 130 K under an LED power of 1 fW  $\mu \text{m}^{-2}$  and of  $5 \times 10^8$  A W<sup>-1</sup> at room temperature under an LED power of 6.4 fW µm<sup>-2</sup> and gate-tunable photoconductivity with a high photodetection capability. Zhang et al.226 used CVD-grown monolayer MoS2 to develop a graphene/MoS2 hybrid structurebased phototransistor that showed a photoresponsivity of 1.2  $\times$  10<sup>7</sup> A W<sup>-1</sup> at 650 nm under a light power of 0.01 W m<sup>-2</sup> and a high photogain of  $10^8$ . A photoresponsivity of  $3.34 \times 10^3$  A  $W^{-1}$  and a detectivity of  $1.004 \times 10^{12}$  Jones have been observed for graphene/MoS2 hybrid structure-based FETs.227 The phototransistor fabricated from multilayer MoS2 using graphene source/drain electrodes showed a high photoresponsivity of 1  $\times$ 10<sup>4</sup> A W<sup>-1</sup> in the wavelength range of 470-600 nm.<sup>228</sup>

Chen et al.<sup>229</sup> developed n-n-type vdWHs using multilayer MoS<sub>2</sub> coated with a layer of nitrogen-doped graphene QDs (N-GQDs) to complement each other with their strong characteristics to improve the carrier mobility. In this hybrid structure,

MoS<sub>2</sub> was used to generate photoexcited holes, while the GQDs working as a gain material contributed to the recirculation of photoexcited carriers at the heterojunction interface. Additional photocarriers were also created by the reabsorption of light emitted from the GQDs by MoS2. Fig. 15 shows a schematic of MoS<sub>2</sub>/GQD heterostructure-based the phototransistor, a comparison of the drain current (Id) versus source-drain voltage (V<sub>ds</sub>) curves of pristine MoS<sub>2</sub> and MoS<sub>2</sub>/GQD hybrid phototransistor devices in the dark and under light illumination, and the photoresponse speed and incident light powerdependent photoresponsivity of MoS2/GQD vdWH-based phototransistors. In the case of the MoS<sub>2</sub> phototransistor, the drain current increased to 10.15 μA at a 405 nm wavelength under an incident laser power of 30.1 µW, with a source-drain voltage  $(V_{ds})$  of 1.68 V; this drain current was 1000 times larger compared with the 11 nA current recorded in the dark state. The MoS<sub>2</sub> phototransistor showed a sensitivity up to 5 nW and rise/ fall times longer than 50 s. The MoS2 phototransistor showed the highest photocurrent of 16.2 µA at 50 nW and photoresponsivity of 800 A W<sup>-1</sup> at 70 V. The MoS<sub>2</sub>/GQD hybrid phototransistor showed a significant change in the drain current  $(I_{\rm d})$  versus source-drain voltage  $(V_{\rm ds})$  curves, a higher drain current and a faster photoresponse speed compared with the pristine MoS<sub>2</sub> phototransistor. The photocurrent of the MoS<sub>2</sub>/ GQD hybrid phototransistor reached 0.55 mA at a gate bias of

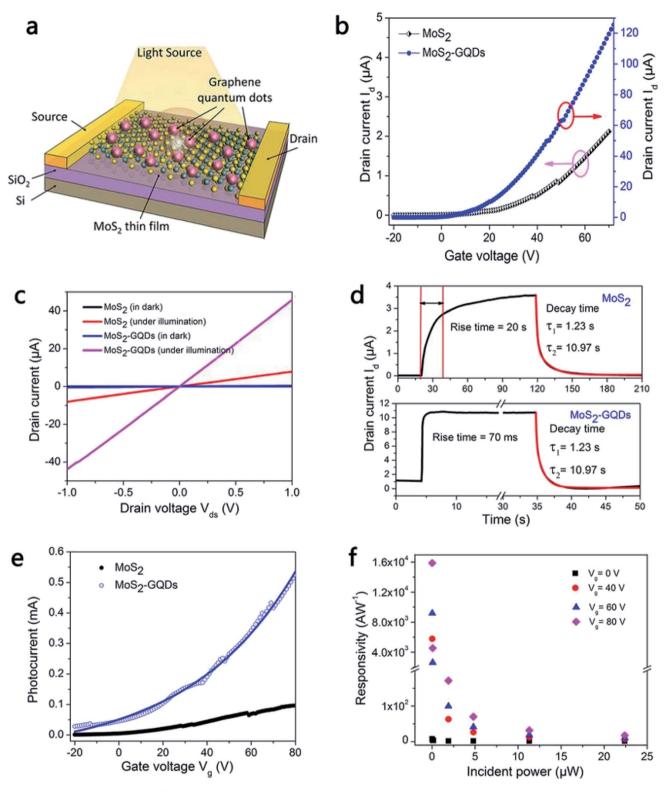


Fig. 15 (a) Schematic of the  $MoS_2/GQD$  heterostructure-based phototransistor. (b) Current vs. voltage curves of  $MoS_2$  and  $MoS_2/GQD$  phototransistor devices. Here,  $I_d$  is the drain current, and  $V_{ds}$  is the source-drain voltage = 1 V. (c) Drain current versus source-drain voltage curves in the dark and under light illumination for  $MoS_2$  and  $MoS_2/GQD$  phototransistors, measured at a 405 nm wavelength under an incident light power of 17  $\mu$ W. (d) Photoresponse times of  $MoS_2$  (top) and  $MoS_2/GQD$  (bottom) phototransistors. (e) Photocurrent versus back gate voltage curves for  $MoS_2$  and  $MoS_2/GQD$  phototransistors, measured under an incident light power of 30.1  $\mu$ W. (f) Incident light power-dependent photoresponsivity of  $MoS_2/GQD$  phototransistors. Reprinted with permission from ref. 229, copyright © Springer Nature Publishing.

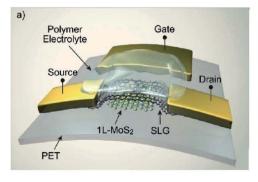
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80 V. The MoS<sub>2</sub>/GQD heterostructure-based photodetector showed a photoresponsivity of  $1.6 \times 10^4$  A W<sup>-1</sup> at 80 V under an incident power of 50 nW and a photoconductive gain of 2.4  $\times$ 10<sup>7</sup> electrons per photon. The high performance of MoS<sub>2</sub>/GQD heterostructure-based photodetectors occurs due to their increased light absorption and the effective generation of electron-hole pairs between the GQDs and MoS<sub>2</sub>.

Large-area MoS2 films on monolayer graphene were developed by Chen et al.230 by adding hydrogen gas during the CVD growth process, which resulted in centimeter-long monolayer MoS<sub>2</sub> continuous films on graphene. Hydrogen addition prevented the degradation of monolayer graphene by decreasing the oxidation. The MoS<sub>2</sub>/graphene-based photodetector showed a photoresponsivity as high as 2.4 A W<sup>-1</sup> under 532 nm illumination and a 135 µW power density. Flexible photodetectors, consisting of an rGO fiber and MoS2 nanosheet hybrid composite, showed significant enhancement of the photocurrent. 231a The Zn-doped MoS2/rGO hybrid fiber-based flexible photodetectors showed a photoresponsivity of 5.73 A W<sup>-1</sup> at laser power density of 125.2 W m<sup>-2</sup> using a bias voltage of 2 V. The same research group also reported one-step synthesis for preparing Zn-doped MoS<sub>2</sub> photodetector using Zn(II)-tetrakis(4hydroxyphenyl)-porphyrin [Zn(II)THPP] as a dopant loaded seeding promoter.231b The Zn-doped MoS2 thin films were transferred onto a PET substrate to fabricated flexible photodetectors. The electrical resistance of the flexible photodetector increased 13% after 10 000 bending cycles at a bending radius of 3 cm while resistance increased 10% at a bending radius of 1 cm, demonstrating good mechanical stability of the flexible photodetectors. The photocurrent of Zn-doped MoS<sub>2</sub> photodetectors was found to increase from 0.05 µA to 2.62 µA as the applied voltage was raised from 1 V to 40 V at a power density of 125.2 W m<sup>-2</sup> and a similar trend was observed for the photoresponsivity. The photocurrent and photoresponsivity of the Zndoped MoS<sub>2</sub> photodetectors can be controlled by adjusting the Zn doping concentration. Asad et al.232 used MoS2 nanoparticle (MoS<sub>2</sub> NP)-decorated graphene nanoribbons (GNRs) to develop flexible phototransistors. In the GNR-MoS<sub>2</sub>NP hybrid, the GNRs function as carrier transport channels, whereas the MoS2 NPs offer high gain absorption. The MoS<sub>2</sub> NPs also generate electron-hole pairs, which are separated at the GNR and MoS2 NP

interface and result in electron transfer from the MoS2 NPs to the GNRs. The flexible GNR-MoS<sub>2</sub> hybrid photodetector showed a photoresponsivity of 66 A W<sup>-1</sup>, a fast rise time of 5 ms and a decay time of 30 ms under 385 nm illumination and a 2.1  $\mu$ W power density. The photoresponsivity of the GNR-MoS<sub>2</sub> hybrid photodetector was  $1.3 \times 10^5$  times larger than that of the pristine graphene photodetector and 104 times larger than that of the pristine MoS<sub>2</sub> phototransistor. The hybrid photodetector also showed high stability for a 6 mm bending radius. De Fazio et al.233 developed visible-light flexible photodetectors using CVD-grown single-layer graphene (SLG) and single-layer (1L) MoS<sub>2</sub> on flexible PET substrates. Fig. 16 is a schematic of a flexible SLG/1L MoS<sub>2</sub> photodetector on a flexible PET substrate and a photograph of the photodetector showing the optical transparency and flexibility. The polymer electrolyte-gated flexible SLG/1L MoS2 photodetector showed an external photoresponsivity of 45.5 A W<sup>-1</sup> and an internal photoresponsivity of 570 A W<sup>-1</sup> at 642 nm, a photoconductive gain of  $4 \times 10^5$ , and >82% optical transparency. The flexible photodetectors showed mechanical durability upon bending at a 1.4 cm bending radius. The photoconductive gain increased by nearly one order of magnitude from 0.1 to 1.0 V, and the photoresponsivity reached 45.5 A  $W^{-1}$  at a  $V_{ds}$  of 1 V. Therefore, the photoconductive gain of the SLG/1L MoS2-based heterostructure photodetector being four orders of magnitude larger than that of the 1L MoS<sub>2</sub> photodetector developed without any SLG showed that the SLG/1L MoS2 heterostructure is important for high photoresponsivity.

Photodetector devices using a MoS<sub>2</sub>/graphene hybrid pattern formed by the soft-lithographic patterning technique were reported by Kang et al.234 The cross-stacked MoS2/graphene patterns were transferred onto a flexible PET substrate for fabricating flexible photodetectors. Fig. 17 shows a schematic of the formation of cross-stacked MoS2/graphene patterned nanostructures. The various fabrication steps involve the CVD growth of MoS2 nanosheets on a 5,10,15,20-tetrakis(4-hydroxyphenyl)-21H,23H-porphyrin (p-THPP) promoter layer, transfer and patterning of the MoS2 nanosheets using a PDMS mold, CVD growth of a graphene layer on Cu foil, transfer of the graphene layer onto a 300 nm thick SiO<sub>2</sub> substrate, and transfer of the graphene layer onto the top of the MoS<sub>2</sub> patterns by using



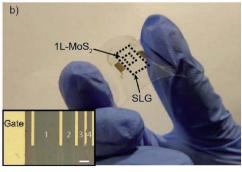


Fig. 16 (a) Schematic of the single-layer graphene (SLG)/1L MoS<sub>2</sub> photodetector on a flexible PET substrate. (b) Photograph of the flexible photodetector showing optical transparency. The inset is an optical image of 4 photodetectors with different channel lengths. Reprinted with permission from ref. 233, copyright © 2016 American Chemical Society.

a dimethyl sulfoxide (DMSO)-coated PDMS mold—the same process that was eventually employed for the transfer and patterning of the  $MoS_2$  film. The SEM images confirmed the cross-stacked  $MoS_2$ /graphene line patterns with a width of 7  $\mu$ m. The Raman peak difference between the  $E_{2g}^{-1}$  and  $A_{1g}$  vibration modes of  $MoS_2$  was estimated to be 20 cm<sup>-1</sup>, which indicated the formation of monolayer  $MoS_2$  patterns.

The photoresponsivities for cross-stacked MoS2/graphene hybrid photodetectors containing monolayer, bilayer, and trilayer MoS<sub>2</sub> films increased linearly as a function of the bias voltage from (10 to 50) V. The trilayer MoS<sub>2</sub> film-based hybrid photodetector showed the highest photoresponsivity compared with the monolayer and bilayer MoS<sub>2</sub> films, a value of 5 A W<sup>-1</sup> at a bias voltage of 2 V. Fig. 18 shows optical microscope images of crossstacked patterns of MoS<sub>2</sub>/graphene based on MoS<sub>2</sub> patterns formed by the soft-lithographic patterning technique, photographs of MoS<sub>2</sub>/graphene hybrid patterns on a flexible PET substrate before and after the bending test, and the photoresponsivity of flexible MoS<sub>2</sub>/graphene hybrid photodetectors as a function of the number of bending cycles at a bending radius of 9 mm and a 1.0 V bias. The mechanical stability of cross-stacked patterns of graphene/MoS2 photodetector devices fabricated on flexible PET substrates was evaluated under various bending cycles. The photocurrent of the MoS<sub>2</sub>/graphene hybrid photodetector with MoS<sub>2</sub> patterns 10 µm in width was measured between 1 and 10 000 bending cycles. The photocurrent of the device decreased from 4.3 to 3.7 A as a function of the number of bending cycles. The smallest reduction in the photoresponsivity with increasing number of bending cycles was observed for the  $10~\mu m$  wide  $MoS_2$  patterns due to the lower compressive stress. Graphene has also been used in developing flexible photodetectors with atomic layered materials. Graphene/tin monosulfide (SnS) hybrid structure-based photodetectors further substantiated that a high photoresponsivity of  $1.7\times10^4~A~W^{-1}$  under an optical light intensity of  $1.2~mW~m^{-2}$  can be achieved in flexible graphene/SnSe/graphene-based photodetectors and demonstrated no change in photoresponse after 25 bending cycles, indicating high mechanical strength of the devices.  $^{65}$ 

Polymer electrolytes have been used for developing flexible  $MoS_2$  photodetectors. Sun *et al.*<sup>235</sup> fabricated four phototransistor arrays with 100, 200, 500, and 1000  $\mu$ m channel lengths in one flexible photodetector device based on a vertically stacked  $MoS_2/g$  graphene thin film deposited on a PET substrate. A polymer electrolyte consisting of PEO: LiClO<sub>4</sub> in an 8:1 ratio was used to fabricate a flexible side-gated photodetector. The flexible photodetector based on the  $MoS_2/g$ raphene film showed an external responsivity of 3.5 A W<sup>-1</sup> at -1 V ( $V_{gs}$ ) under a 60  $\mu$ W incident power. The  $MoS_2/g$ raphene thin film had a transmittance of 10.5% at 520 nm, and the internal photoresponsivity of the photodetector reached 33.3 A W<sup>-1</sup>. The photocurrent of the  $MoS_2/g$ raphene film can be adjusted in the 0 to 300  $\mu$ A range.

## 4.2 MoS<sub>2</sub>/carbon nanotube hybrid heterostructures for flexible photodetectors

CNTs show large optical absorption compared with traditional semiconductors; therefore, photodetection can be further

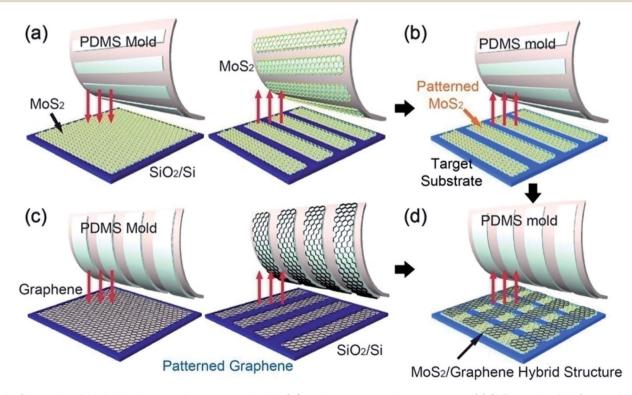


Fig. 17 Schematic of the fabrication steps for cross-stacked  $MoS_2$ /graphene patterned nanostructures. (a) CVD growth of  $MoS_2$  nanosheets on a  $SiO_2$  substrate (left), and pattern fabrication on the  $MoS_2$  layer within a target area (right). (b) Transfer of  $MoS_2$  patterns on the PDMS mold onto a target substrate. (c) CVD growth of a graphene layer. (d) Transfer of graphene patterns on the PDMS mold to the top of  $MoS_2$  patterns on the target substrate. Reprinted with permission from ref. 234, copyright © Elsevier.

improved by using CNTs in hybrid heterostructures. 236,237 CNTbased hybrid broadband photodetectors have been fabricated with a variety of functional materials, including Si, GaAs, fullerenes, graphene, ZnO, PbS, and perovskites. 238-249 A negative photoresponsivity on the order of 10<sup>8</sup> A W<sup>-1</sup> has been reported in fullerene-sensitized aligned CNTs at room temperature.<sup>250</sup> Highly flexible photodetectors based on CNTs have been demonstrated for wearable technologies.<sup>251-254</sup> The outstanding electronic and optical properties have been utilized by integrating CNTs with MoS<sub>2</sub> atomic layers to develop flexible CNT/MoS<sub>2</sub> hybrid broadband photodetectors.

Photodetectors have been developed using few-layer MoS<sub>2</sub>/ SWCNT hybrids, 255 which showed high photoresponsivities of 100 to 1000 A  $W^{-1}$  at a 0.1 V bias voltage in the 500-700 nm visible range. Specifically, the MoS<sub>2</sub>/SWCNT hybrid structure exhibited a photoresponsivity of 300 A W<sup>-1</sup> at 532 nm under a  $V_{\rm o}$ of 0 V. Large-area MoS2, WS2, and MoSe2 device arrays were fabricated by Li et al.256 MoS2 channels and MoS2/CNT hybrid electrodes were simultaneously deposited on a CNT-patterned substrate by the CVD method. MoS2-MoS2/CNT devices showed ohmic contacts between MoS2 channels and MoS2/CNT hybrid electrodes and exhibited better mechanical stability as well as photoresponsivity than gold-contacted devices,

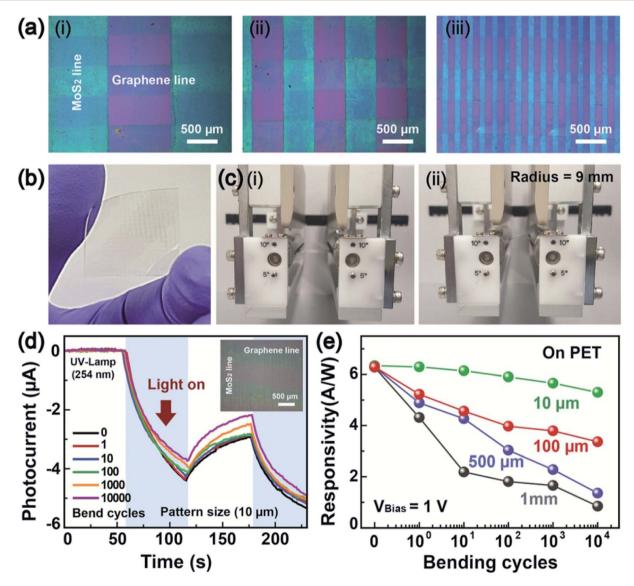


Fig. 18 (a) Optical microscope images of cross-stacked patterns of  $MoS_2$ /graphene based on  $MoS_2$  patterns with widths of (i) 1 mm, (ii) 500  $\mu$ m, and (iii) 100 μm, where the graphene patterns have a fixed width of 500 μm. (b) Photographic image of cross-linked MoS<sub>2</sub>/graphene hybrid patterns on a flexible PET substrate developed by the soft-lithographic patterning technique. (c) Photographs of MoS<sub>2</sub>/graphene hybrid patterns on a flexible PET substrate (i) before and (ii) after the photodetector device bending test. (d) Photocurrent as a function of time for a flexible MoS<sub>2</sub>/ graphene hybrid photodetector under  $1-10\,000$  bending cycles. The inset shows an optical image of cross-stacked patterned MoS<sub>2</sub> (width =  $10\,000$  $\mu$ m) and graphene (width = 500  $\mu$ m). (e) Photoresponsivity of flexible MoS<sub>2</sub>/graphene hybrid photodetectors as a function of bending cycle (1– 10 000), where the photodetectors have 1 mm, 500 µm, 100 µm, and 10 µm pattern sizes for the MoS<sub>2</sub> layers. The bending test was conducted at a bending radius of 9 mm and a 1.0 V bias voltage. Reprinted with permission from ref. 234, copyright © Elsevier.

indicating the suitability of the  $MoS_2-MoS_2/CNT$  hybrid for flexible electronic devices. Highly flexible pixel arrays based on  $MoS_2-MoS_2/CNT$  hybrid photodetectors were developed. Fig. 19 shows the flexible  $MoS_2-MoS_2/CNT$  hybrid film-based photodetector pixel array, photocurrent response at zero gate voltage, and image patterns recorded using the  $MoS_2-MoS_2/CNT$  photodetector pixel array. The flexible  $MoS_2-MoS_2/CNT$  photodetector arrays were deposited on a 3  $\mu$ m thick flexible SU-8 substrate. The  $MoS_2-MoS_2/CNT$  device showed a current below  $10^{-11}$  A at a bias voltage of 0.5 V. The  $MoS_2-MoS_2/CNT$  devices showed a detectivity of  $2.4 \times 10^{10}$  cm  $Hz^{-1/2}$  W<sup>-1</sup>. The 160 photodetector pixels formed with  $MoS_2-MoS_2/CNT$  devices were arranged in 16 columns  $\times$  10 rows. Both L- and T-shaped image patterns were recorded by the pixel array.

## 4.3 MoS<sub>2</sub>/2D TMD hybrid heterostructures for flexible photodetectors

MoS<sub>2</sub>-based vdWHs have been extensively studied for developing photodetectors, as discussed in the previous section. <sup>195–206</sup> The electronic and optoelectronic properties of MoS<sub>2</sub>-based FETs and photodetectors have been dramatically improved by integrating atomic layered MoS<sub>2</sub> with other vdW structures, such as 2D graphene, h-BN and TMDs. Huo *et al.*<sup>257</sup> developed a phototransistor from multilayer MoS<sub>2</sub>/WS<sub>2</sub> vdWHs that

exhibited an on/off switching ratio >10<sup>5</sup>, an electron mobility of 65 cm $^2$  V $^{-1}$  s $^{-1}$ , and a photoresponsivity of 1.42 A W $^{-1}$ , enhanced properties compared with multilayer MoS2 or WS2 transistors. Xue et al. 164 used vertical heterojunction arrays of few-layer MoS<sub>2</sub>/WS<sub>2</sub> to develop flexible photodetectors. HRTEM and AFM images indicated three layers of MoS<sub>2</sub> (~2.1 nm) and five layers of WS<sub>2</sub> ( $\sim$ 3.9 nm) in the heterostructure layered films. MoS<sub>2</sub>/WS<sub>2</sub> heterojunction-based FETs were fabricated on a rigid SiO<sub>2</sub>/Si substrate. Flexible MoS<sub>2</sub>/WS<sub>2</sub> heterojunction photodetector arrays were also fabricated on a PDMS substrate. Fig. 20 shows a schematic of the MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunctionbased phototransistor, current-voltage plot, time-dependent photocurrent of the MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction at different incident powers during laser switching on/off, photographic image of the flexible MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction photodetector arrays on a PDMS substrate and time-dependent photocurrent of the flexible MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction photodetector device on the PDMS substrate at different incident laser powers. The MoS<sub>2</sub>/WS<sub>2</sub>-based photodetector showed a photoresponsivity of 2.3  ${
m A~W}^{-1}$  at a 450 nm wavelength.

In another study, Lin *et al.*<sup>258</sup> fabricated flexible vdW photodiodes on flexible PET substrates using monolayer n- $MoS_2$ /few-layer p-WSe<sub>2</sub> heterojunctions. The photoresponsivity of the  $MoS_2$ /WSe<sub>2</sub> photodiode increased by 86% at -0.62% compressive strain in the  $MoS_2$  armchair direction due to

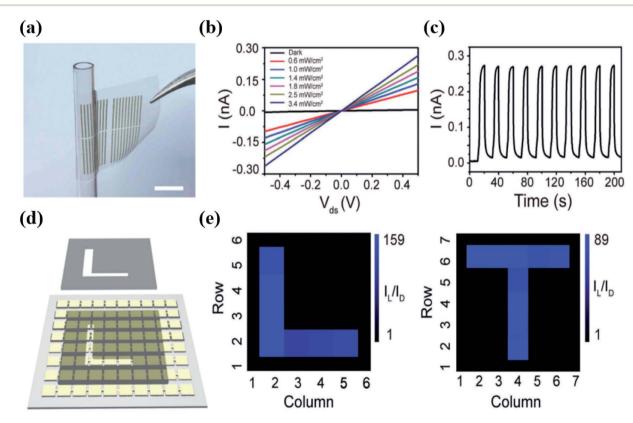


Fig. 19 Flexible  $MoS_2-MoS_2/CNT$  hybrid photodetectors. (a) Flexible  $MoS_2-MoS_2/CNT$  hybrid film-based electronic device array attached to the surface of a glass tube. (b)  $I-V_{ds}$  curves of the  $MoS_2-MoS_2/CNT$  hybrid device at 442 nm under different intensities of light illumination. (c) Photocurrent response of the  $MoS_2-MoS_2/CNT$  device as a function of time. (d) Schematic representation of a photodetector pixel array of  $MoS_2-MoS_2/CNT$  hybrid photodetectors. (e) L- and T-shaped image patterns (row vs. column) recorded using the  $MoS_2-MoS_2/CNT$  photodetector pixel array. Reprinted with permission from ref. 256, copyright © Wiley-VCH.

realignment of the energy band at the MoS<sub>2</sub>/WSe<sub>2</sub> interface caused by the strain-induced piezoelectricity. The MoS<sub>2</sub>/WSe<sub>2</sub> photodiode showed a photoresponsivity of 3.4 mA  $W^{-1}$ . The PL peak intensity of CVD-grown monolayer MoS2 increased by three orders of magnitude after 15 min of TFSI chemical treatment. This study demonstrated that strain-tunable 2D TMDbased vdWHs could be used for developing optoelectronic devices. The photoresponse of flexible MoS<sub>2</sub>/WSe<sub>2</sub> vdWH-based photodiodes was enhanced by the piezophototronic effect. Alloys of TMDs have been explored for developing flexible photodetectors. In another study, Wu et al. 264 also demonstrated improved photoresponse of flexible monolayer MoS2 due to the piezophototronic effect for strain-gated photodetectors. The polarization charges induced by the applied strain can change the separation of photogenerated carriers and their transport at the interface between MoS2 and metal allowing tuning of pho-

toresponse. The strain-induced flexible monolayer MoS<sub>2</sub>

photodetector showed high photoresponsivity of  $2.3 \times 10^4$  A

W<sup>-1</sup>, which is 26 times larger photoresponsivity compared with

monolayer MoS<sub>2</sub> phototransistors<sup>172</sup> due to the piezophototronic effect. The current  $(I_{ds})$  monolayer MoS<sub>2</sub> increased by 2.5 times, from 90 nA in dark to 220 nA under 4.297 mW cm<sup>-2</sup> optical power intensity at a drain voltage of -2 V. The photocurrent was 40 nA at 3.4 μW cm<sup>-2</sup> power intensity under strain of -0.38%, which increased to 207 nA at 4.29 mW cm<sup>-2</sup> power intensity under increased strain of -0.45%. Zheng et al.259 developed Mo<sub>0.5</sub>W<sub>0.5</sub>Se<sub>2</sub> alloy-based photodetectors on a SiO<sub>2</sub>/Si rigid substrate and a PI flexible substrate for photodetection over a broadband spectrum ranging from the UV to NIR region (370 nm to 808 nm). The  $Mo_{0.5}W_{0.5}Se_2$  photodetectors on the SiO<sub>2</sub>/Si substrate exhibited a photoresponsivity of 77.1 A W<sup>-1</sup> and a detectivity of  $1.1 \times 10^{12}$  Jones with a rapid response speed of 8.3 ms, whereas the photodetector on the flexible PI substrate showed a photoresponsivity of 63.5 A W<sup>-1</sup> and a detectivity of  $3.56 \times 10^{12}$  Jones. The Mo<sub>0.5</sub>W<sub>0.5</sub>Se<sub>2</sub> photodetectors showed no noticeable degradation in performance over 100 bending cycles, showing their suitability for flexible optoelectronic devices.

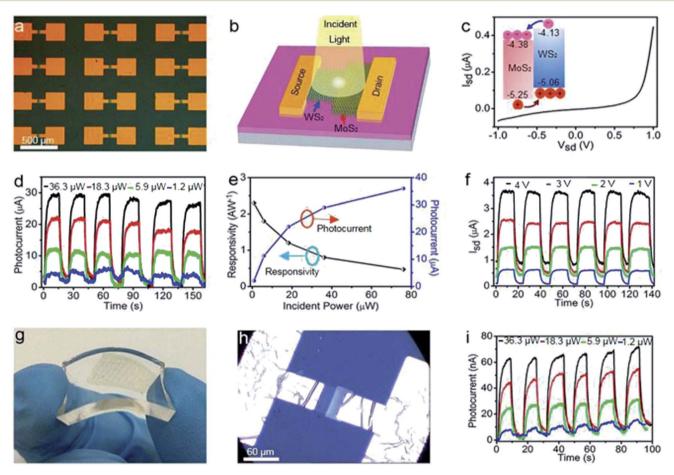


Fig. 20 (a) Vertical heterojunction arrays fabricated from few-layer  $MoS_2/WS_2$  on a  $SiO_2/Si$  substrate. (b) Schematic illustration of the  $MoS_2/WS_2$ vertical heterojunction-based phototransistor. (c) Current-voltage plot of a MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction-based phototransistor without illumination. The inset indicates the band alignment for few-layer MoS2 and WS2. (d) Time-dependent photocurrent of the MoS2/WS2 vertical heterojunction at different incident powers. (e) Photocurrent and photoresponsivity as a function of incident light power at a 405 nm wavelength. (f) Time dependence of the photocurrent based on the MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction photodetector during switching on/off of the laser with varying source-drain voltage ( $V_{sd}$ ) from 1 to 4 V. (g) Photographic image of the flexible MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction photodetector array on a PDMS substrate. (h) Optical microscope image of a single flexible MoS<sub>2</sub>/WS<sub>2</sub> vertical heterojunction photodetector device on a PDMS substrate. (i) Time-dependent photocurrent of the flexible  $MoS_2/WS_2$  vertical heterojunction photodetector device on the PDMS substrate at different incident laser powers. Reprinted with permission from ref. 164, copyright © 2017 American Chemical Society.

4.4 MoS<sub>2</sub>/ZnO hybrid heterostructures for flexible

**RSC Advances** 

## photodetectors

Ultrahigh photoresponsivity has been observed in ZnO-based hybrid heterostructures, and flexible broadband photodetectors have been fabricated using ZnO nanostructures (NWs, nanorods, QDs, nanoparticles) combined with other functional nanomaterials, including graphene, CNTs, carbon nanodots, Au, Cu, ZnS, CdO, SnO<sub>2</sub>, and Zn<sub>2</sub>SnO<sub>4</sub>, for wearable technologies. 52-54,260-271 Hybrid heterostructures of ZnO with MoS<sub>2</sub> have similarly been used to develop photodetectors. The electronic and optoelectronic properties of MoS2 atomic layers have been improved by ZnO doping. A photoresponsivity of  $3.18 \times 10^3$  A  $W^{-1}$  and a detectivity of 5.94  $\times$  10<sup>12</sup> Jones have been observed for the ZnO-doped MoS2 photodetector at a wavelength of 520 nm due to the suppression of the recombination rate of photocarriers induced by ZnO doping.<sup>272</sup> Nazir et al.<sup>273</sup> used ZnO QD-decorated multilayer MoS2 nanosheets to develop ZnO QD/ MoS<sub>2</sub> heterostructure-based photodetectors. The field-effect mobility of ML MoS<sub>2</sub> increased from 5.75 to 25.09 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> after decorating ML MoS<sub>2</sub> with ZnO QDs due to the charge transfer from the deposited ZnO QD thin layer to the surface of the pristine ML MoS2 nanosheet. The ML MoS2 photodetector showed a photoresponsivity of 1913 A W<sup>-1</sup> at a  $V_{BG}$  of 30 V and a  $V_{\rm ds}$  of 1 V at 220 nm under an incident laser power of 11 mW cm<sup>-2</sup>, which increased to 2267 A W<sup>-1</sup> under similar conditions after decorating the ML with a ZnO QD thin layer. The flexible MoS<sub>2</sub>/ZnO/PEN photodetectors showed an I<sub>on</sub>/I<sub>off</sub> current ratio of 104, compared with 103 for the pure ZnO/PEN photodetector. 274 The highest photocurrent was obtained for the device with a 5 wt% MoS<sub>2</sub> layer. The I<sub>on</sub>/I<sub>off</sub> current ratio increased from 8840 to 17 800 for 0 to 5 wt% MoS<sub>2</sub> in the MoS<sub>2</sub>/ZnO hybrid structure along with the highest photocurrent and photoresponsivity values for the photodetectors. Pak et al. 275 reported a photoresponsivity of 14.9 mA  $W^{-1}$  at 1100 nm for the  $\alpha$ -IGZO photodetector capped by a MoS2 layer, which was five times higher compared with the pure α-IGZO photodetector with no MoS<sub>2</sub> layer. Yang et al.<sup>276</sup> used few-layer MoS<sub>2</sub> (bandgap of 1.7 eV) with amorphous indium-gallium-zinc oxide (InGaZnO: α-IGZO) (bandgap of 3.0 eV) to develop a hybrid heterostructurebased phototransistor. The MoS<sub>2</sub>/α-IGZO hybrid formation imparted enhanced visible light absorption and a high carrier mobility. The band alignment at the heterostructure junction facilitated the transfer of electrons generated by visible light within the upper few-layer MoS<sub>2</sub> to the underlying  $\alpha$ -IGZO layer. The photocurrent of the MoS<sub>2</sub>/α-IGZO heterostructure-based phototransistors was four orders of magnitude higher than that of the MoS<sub>2</sub> phototransistor at an incident laser power of 1.0  $\mu$ W; the photoresponsivity was 1.7 A W<sup>-1</sup> at a wavelength of 520 nm, and the extrapolated photoresponsivity exceeded 10<sup>3</sup> A  $W^{-1}$  under an incident laser power of 1.0 pW. The MoS<sub>2</sub>/ $\alpha$ -IGZO phototransistors showed an  $I_{\text{on}}/I_{\text{off}}$  current ratio of 10<sup>5</sup> and photoresponse times of 2.6 s and 1.7 s.

The morphology of nanomaterials also plays an important role in controlling the electrical properties. Lee et al.277 reported different ZnO morphological nanostructures, such as NWs, nanostars (NSs), and nanoflowers (NFs), which were

hydrothermally grown on graphene monolayer and MoS2 multilayer films by adjusting the pH of the solution, and used these ZnO hybrid nanostructures to fabricate photodetectors. ZnO-based NWs, NSs, and NFs were obtained at pH values of 6.53, 8.18, and 9.18, respectively, and characterized by fieldemission (FE)-SEM, resonant Raman spectroscopy, and XPS methods. The photodetectors fabricated from ZnO NWs/ graphene, ZnO NSs/graphene, and ZnO NFs/graphene showed high photoresponsivity values of 145, 302, and 350 A W<sup>-1</sup>, respectively. However, the photodetectors fabricated from ZnO NW/MoS<sub>2</sub>, ZnO NS/MoS<sub>2</sub>, and ZnO NF/MoS<sub>2</sub> hybrids showed very low photoresponsivities of  $7.91 \times 10^{-6}$ ,  $1.02 \times 10^{-4}$ , and  $8.99 \times 10^{-4} \text{ A W}^{-1}$ , respectively. The EQE of photodetectors developed from ZnO NWs, NSs, and NFs in combination with graphene were  $5.14 \times 10^4$ ,  $1.07 \times 10^5$ , and  $1.24 \times 10^5$ %, compared with  $2.81 \times 10^{-3}$ ,  $3.63 \times 10^{-2}$ , and  $3.19 \times 10^{-1}$ % for ZnO NWs, NSs, and NFs with MoS2, respectively. Fig. 21 shows a photograph of the ZnO NF/MoS<sub>2</sub> photodetector fabricated on a flexible PI substrate, time-dependent photocurrents of hybrid photodetectors developed from ZnO NWs, ZnO NSs, and ZnO NFs along with graphene and MoS2, and the variation in the photocurrent of the ZnO NF/graphene hybrid and ZnO NF/MoS<sub>2</sub> hybrid as a function of the bending cycle. The photocurrents of the ZnO NW, NS, and NF hybrids with graphene decrease, whereas the photocurrents of the ZnO NW, NS, and NF hybrids with MoS<sub>2</sub> increase under UV illumination at 256 nm owing to the difference in the electronic structures of graphene and MoS<sub>2</sub>. The photocurrent of the ZnO hybrid photodetectors shows an increasing trend of ZnO NWs < NSs < NFs, regardless of whether graphene or MoS<sub>2</sub> is used, because of the increased oxygen vacancies induced by adjusting the pH. The response and decay times were 10 and 67 s for the ZnO NF/graphene hybrid and 61 and 90 s for the ZnO NF/MoS<sub>2</sub> hybrid-based photodetector devices, respectively. The photocurrent decreased by 74% for the ZnO NF/graphene hybrid and by 76% for the ZnO NF/MoS2 hybrid-based devices from the initial values after 10 000 bending cycles at a bending radius of 6 mm.

Flexible photodetectors have been developed using MoS<sub>2</sub> and graphitic carbon nitride (g-C<sub>3</sub>N<sub>4</sub>) hybrid thin films on a paper substrate, as reported by Velusamy et al.278 The dark current of MoS2 decreased as the amount of g-C3N4 increased in the hybrid films because of the resistivity of g-C<sub>3</sub>N<sub>4</sub>, although the photocurrent was significantly improved due to the photocarriers generated under light illumination. The photocurrent of the MoS<sub>2</sub>/g-C<sub>3</sub>N<sub>4</sub> hybrid increased linearly as a function of increasing laser power density, yielding  $I_{\rm on}/I_{\rm off}$  current ratios of  $4 \times 10^3$  and  $1 \times 10^4$ , photoresponsivities of 700 mA W<sup>-1</sup> and 4 A  $W^{-1}$ , and detectivities of 8  $\times$  10<sup>10</sup> Jones and 4  $\times$  10<sup>11</sup> Jones at 532 nm and 365 nm wavelengths under laser power densities of  $0.225 \text{ W cm}^{-2} \text{ and } 0.5 \text{ W cm}^{-2} \text{ for MoS}_2/\text{g-C}_3\text{N}_4 (5:5) \text{ hybrid}$ thin film, respectively. The photodetectors showed stability, retaining 90% of their initial photocurrent after a time period of 3000 s. The  $MoS_2/g-C_3N_4$  (5:5) hybrid film-based photodetectors showed no significant decrease in the photocurrent after bending the thin films to radii of 10, 7, 5, 4, 3, and 2 mm; and no deformation up to 400 bending cycles at a 4 mm bending radius under the measurement conditions described above. Yu et al. 279



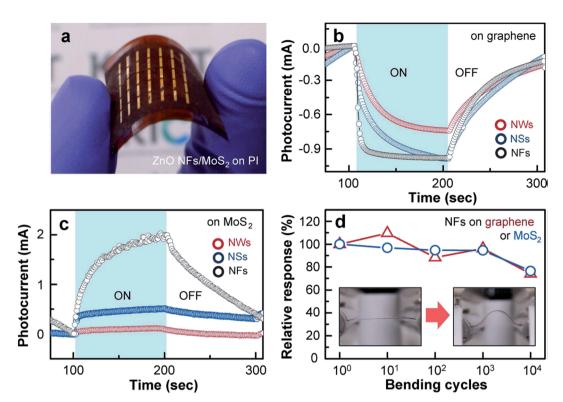


Fig. 21 (a) Photograph of the ZnO NF/MoS<sub>2</sub> photodetector fabricated on a flexible PI substrate. (b) Time-dependent photocurrents for ZnO NW/ graphene, ZnO NS/graphene, and ZnO NF/graphene hybrids measured at 1 V. (c) Time-dependent photocurrents for ZnO NW/MoS<sub>2</sub>, ZnO NS/ MoS<sub>2</sub>, and ZnO NF/MoS<sub>2</sub> hybrids measured at 1 V. (d) The change in the photocurrent of the ZnO NF/graphene hybrid (red) and ZnO NF/MoS<sub>2</sub> hybrid (blue) as a function of the bending cycle. Insets show the bending process of photodetectors at a bending radius of 6 mm. Reprinted with permission from ref. 277, copyright © 2017 American Chemical Society.

developed flexible photodetectors by transferring MoS<sub>2</sub> layers onto interdigital electrodes patterned on a PET substrate which showed a photoresponsivity of 20 mA W<sup>-1</sup>, with response rise/ fall times of 12 s and 19 s. Seo et al.280 developed inkjet printed flexible photodetector devices using MoS2 nanosheets and graphene electrodes. MoS<sub>2</sub>/graphene photodetectors were fabricated on a rigid glass substrate applying thermal annealing and a flexible polyimide (PI) substrate using photonic annealing. Thermally annealed MoS<sub>2</sub>/graphene photodetectors showed photoresponsivity of 1 mA  $W^{-1}$  and detectivity of 4.37  $\times$ 10<sup>7</sup> Jones at 515.6 nm, which increased many folds for the photonically annealed photodetectors because more charge carriers were generated by the photothermal effect associated with lower thermal conductivity and larger heat capacity of polyimide thin film substrate than that of a rigid glass substrate. The photonically annealed flexible MoS<sub>2</sub>/graphene photodetectors also showed retained mechanical stability over 500 bending cycles at 8.1 mm radius of curvature.

#### 4.5 Surface functionalized MoS<sub>2</sub> layers for flexible photodetectors

The electrical, optical, mechanical, thermal, chemical, and biological properties of MoS2 atomic layers can be altered by covalent surface functionalization. Different organic functional groups can be covalently attached to the MoS2 atomic layers by exploiting vacancies mainly on surface atoms and consequently

their physical and chemical properties can be tuned.<sup>281-284</sup> Tang et al. 285 reported that the bandgap of 1T-phase MoS<sub>2</sub> monolayer can be tuned between zero to 1.0 eV depending upon the chemical bonding of CH3, CF3, OCH3, NH2 and H functional groups. Ding et al.286 demonstrated covalent functionalization of 2H-phase MoS2 monolayers can be achieved and tuned by thiol (SH) group functionalization and controlling the vacancies of sulfur atoms on the basal planes. The covalent functionalization by thiol groups can modulate both photoluminescence and catalytic behavior of functionalized MoS2 monolayers. The applications of PEGylated MoS2 atomic layers and carboxyl (-COOH) functionalized MoS2 nanosheets have been reported in cancer therapy287 and surface plasmon resonance (SPR) immunosensors.288 Various studies have shown that the covalent surface functionalization can be used for controlling the phase stability, surface characteristics, chemical reactivity, mechanical, and electrical properties of MoS2.289-292

Flexible MoS<sub>2</sub> photodetectors have been fabricated using surface-functionalized monolayer MoS2. Pak et al.293 developed flexible photodetectors based on CVD-grown monolayer MoS2 surface-functionalized with electron accepting (p-doping) octadecyltrichlorosilane (ODTS, -CH3 groups) or electron donating (ndoping) (3-aminopropyl)triethoxysilane (APTES, -NH2 groups) organic molecules. The PL spectrum of ODTS-MoS2 layer was found to increase in the intensity and blue-shifted by 11 meV whereas the PL intensity of APTES-MoS2 layer decreased and red-

shifted by 15 meV, compared with the pristine MoS<sub>2</sub> layer due to the different process of exciton recombination. Fig. 22 shows the schematics of a flexible MoS2 based photodetector, ODTS functionalized monolayer MoS2, and mechanical stability test and then compares the incident power dependent photoresponsivity and detectivity of the pristine MoS<sub>2</sub> with APTES-MoS<sub>2</sub> and ODTS-MoS<sub>2</sub> photodetector devices. The lower dark and photo current values of 475 pA and 202 nA for ODTS-MoS<sub>2</sub> device and higher values 1.2 μA and 4.6 µA for APTES-MoS2 device were associated with their charge carrier concentrations, respectively. The photoresponsivity of the ODTS-MoS<sub>2</sub> device increased from 2.5 A W<sup>-1</sup> to 37.5 A W<sup>-1</sup> and from 25.2 A W<sup>-1</sup> to 1500 A W<sup>-1</sup> for the APTES-MoS<sub>2</sub> device at the lowest incident power. The functionalized MoS2 channel assisted in transporting more excitons that yielded higher photoresponsivity for the APTES-MoS<sub>2</sub> device. The ODTS-MoS<sub>2</sub> photodetector showed highest detectivity of 10<sup>11</sup> Jones under the lowest incident power, which may be associated with the dropping of the dark level due to the electrons withdrawal from the channel. The photoresponse decay time of flexible APTES-MoS2 photodetector was decreased to 0.7 s compared with 1.45 s for the pristine 1L-MoS<sub>2</sub> photodetector. The mechanical stability of the flexible ODTS-MoS<sub>2</sub>/PET device was studied as a function of bending radius and bending cycles. At 2 mm bending radius, less than 10% degradation in photocurrent occurred while 20% degradation was noticed at bending radius of 4 mm up to 1000 bending cycles. This study demonstrated that a flexible MoS2 photodetector can be fabricated with surface-functionalization of a MoS2 monolayer. Kang et al. 180 also observed the similar phenomenon for the MoS<sub>2</sub>

photodetector devices n-doped by APTES organic molecules where photoresponsivity was improved from 219 A W $^{-1}$  to 5.75  $\times$  10 $^3$  A W $^{-1}$  for the APTES–MoS $_2$  devices.

Several other studies have been reported on MoS<sub>2</sub> hybrid based flexible photodetectors. In-plane lateral graphene/MoS<sub>2</sub> heterostructure showed photoresponsivity of  $1.1 \times 10^5 \, \text{AW}^{-1}$ , detectivity of 1.4  $\times$  10<sup>14</sup> Jones and  $I_{\rm on}/I_{\rm off}$  current ratio of 10<sup>6</sup> due to the strong absorption and increased separation of the photoexcited charge carriers and the charge transportation.294 MoS<sub>2</sub> phototransistors have been prepared on flexible polyarylate substrate where poly(4-vinylphenol) (PVP) was used both as a gate dielectric and an encapsulating layer material.295 The encapsulation with PVP improved the field-effect mobility  $(\mu_{\rm FE})$  and the current  $I_{\rm on}/I_{\rm off}$  ratio, which resulted in two orders of magnitude enhancement in photoresponsivity as well as in detectivity from visible to infrared wavelength. The hydroxyl functional groups in PVP improved the performance of MoS<sub>2</sub> phototransistors due to the n-doping effect and decreased the recombination of photoexcited carriers. Kang et al.296 developed MoS<sub>2</sub>-ZnO hybrid based flexible photodetectors using MoS<sub>2</sub> nanosheets with atomic layer deposition (ALD) deposited ZnO nanopatches. The photocurrent was found to increase with an increasing number of ALD cycles where the highest photocurrent was measured for the MoS2 nanosheets having 40 cycles ZnO nanopatches. The sulfur vacancies in defected MoS2 structure disappeared with increasing ZnO cycles and the recombination of photoexcited carriers decreased. The photocurrent of pristine MoS2 and flexible

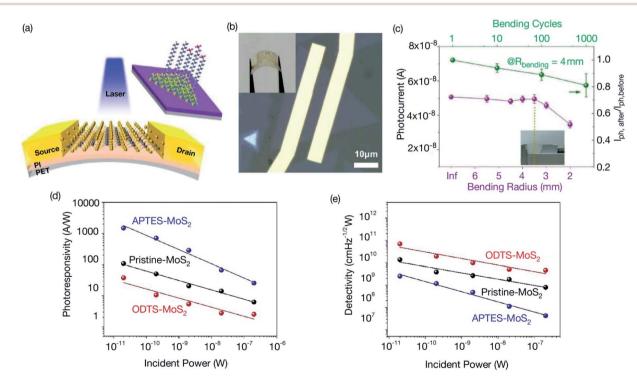


Fig. 22 (a) Schematics of a flexible  $MoS_2$  based photodetector on a PET substrate and the surface-functionalized monolayer  $MoS_2$  with ODTS (-CH<sub>3</sub> groups). (b) Schematics and optical image of flexible  $MoS_2$  photodetector device developed using e-beam lithography. (c) Mechanical stability of flexible  $MoS_2$  devices in terms of their photocurrent at different bending radius as a function of bending cycles. A comparison of the photoresponsivity (d) and detectivity (e) of the pristine  $MoS_2$  with APTES- $MoS_2$  and ODTS- $MoS_2$  photodetector devices as a function of incident power intensity. Reprinted with permission from ref. 293, copyright @ The Royal Society of Chemistry.

Table 1 The figure of merit of different  $MoS_2$  based photodetectors. The performance of photodetectors is compared in terms of their photoresponsivity, detectivity and response/recovery time ( $\tau_{rise}/\tau_{decay}$ ) along with their measurement wavelength and incident laser power (Jones = cm Hz<sup>1/2</sup> W<sup>-1</sup>)<sup>a</sup>

IoS <sub>2</sub> photodetector	Conditions (wavelength, incident power)	Photoresponsivity (A W <sup>-1</sup> )	Detectivity (Jones)	Response time $(\tau_{\rm rise}/\tau_{ m decay})$	Ref.
) Pristine MoS <sub>2</sub> based					
hotodetectors					
L MoS <sub>2</sub>	$(\lambda = 561 \text{ nm}, 150 \text{ pW})$	880	$2 \times 10^9$	4 s/9 s	171
L MoS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 35 \text{ pW})$	$1.1 \times 10^5$	2 × 10	232 s	306
L WOS2			_		
34.0	$(\lambda = 1070 \text{ nm}, 150 \text{ nW})$	5.2	_	216.5 s	308
$_{1}$ MoS $_{2}$	$(\lambda = 532 \text{ nm})$	0.57		70 μs/110 μs	307
$L MoS_2$	$(\lambda = 633 \text{ nm}, 10 \text{ nW})$	0.12	10 <sup>10</sup> to 10 <sup>11</sup>	_	308
$MoS_2$	$(\lambda = 520 \text{ nm})$	$6.3 \times 10^{-5}$	$4.2 \times 10^{8}$	20 ms	304
$MoS_2$	$(\lambda = 850 \text{ nm})$	1.80	$5.0 \times 10^{8}$	0.3 s/0.36 s	139
l/MoS <sub>2</sub> /Cr–Au	$(\lambda = 500 \text{ nm})$	5.07	$3 \times 10^{10}$	100 ms/200 ms	197
$2L \text{ MoS}_2/\text{HfO}_2$	$(\lambda = 635 \text{ nm}, 3.75 \text{ pW})$	$1 \times 10^4$	$7.7 \times 10^{11}$	10 ms	136
$MoS_2/Al_2O_3$	$(\lambda = 635 \text{ nm})$	406	$3.8 \times 10^{11}$	55 ms	136
MoS <sub>2</sub> /SiC	$(\lambda = 325 \text{ nm})$	$1.02\times10^4$	$6.4 \times 10^{11}$	_	217
	$(\lambda = 532 \text{ nm})$	$1.6 \times 10^{3}$	$1.0\times10^{11}$	_	217
MoS <sub>2</sub> /SiC/Si	$(\lambda = 325 \text{ nm})$	44	$1.4\times10^{10}$	_	217
	$(\lambda = 532 \text{ nm})$	30	$9.5 \times 10^{9}$	_	217
MoS <sub>2</sub> (CVD)	$(\lambda = 532 \text{ nm})$ $(\lambda = 532 \text{ nm}, 0.377 \text{ mW cm}^{-2})$	7160	$6.62 \times 10^{10}$	97 ms/291 ms	351
$S_2$ layers (PLD)	$(\lambda = 365 \text{ nm})$	$3.0 \times 10^4$	$1.81 \times 10^{14}$	32 ms	369
	,		$2.38 \times 10^{13}$		
/6L MoS <sub>2</sub> (serial multi-heterojunction)	$(\lambda = 520 \text{ nm}, 1 \text{ nW})$	$9.26 \times 10^4$		20 ms/25 ms	348
	$(\lambda = 520 \text{ nm, 5 pW})$	$2.67 \times 10^6$	_	5 ms/5 ms	
	$(\lambda = 785 \text{ nm}, 1 \text{ nW})$	$1.86 \times 10^{4}$	_	15 ms/20 ms	
	$(\lambda = 850 \text{ nm}, 1 \text{ nW})$	$1.08 \times 10^{4}$	_	10 ms/15 ms	
	$(\lambda = 1064 \text{ nm}, 1 \text{ nW})$	$1.07 \times 10^{3}$	_	5 ms/10 ms	
	$(\lambda = 1064 \text{ nm}, 5 \text{ pW})$	$1.65 \times 10^{4}$	_	1.5 ms/2.5 ms	
/6L MoS <sub>2</sub> (parallel multi-heterojunction)	$(\lambda = 520 \text{ nm}, 1 \text{ nW})$	$8.74 \times 10^{3}$	_	465 ms/315 ms	348
oS <sub>2</sub> microspheres	$(\lambda = 405 \text{ nm}, 1.77 \text{ mW cm}^{-2})$	0.96	$2.9\times10^{10}$	_	384
i) MoS <sub>2</sub> based flexible					
hotodetectors					
	() 225)	2.10 102	4.5 4011		017
oS <sub>2</sub> /Kapton (flexible)	$(\lambda = 325 \text{ nm})$	$3.19 \times 10^{2}$	$4.5 \times 10^{11}$	_	217
MoS <sub>2</sub> /PET (flexible)	$(\lambda = 532 \text{ nm})$	5.0	$6.4 \times 10^{9}$	_	217
	$(\lambda = 325 \text{ nm})$	$1.36 \times 10^{2}$	$2.0 \times 10^{11}$	_	217
	$(\lambda = 532 \text{ nm})$	9.0	$9.7 \times 10^{9}$	_	217
MoS <sub>2</sub> /graphene/PET (flexible)	$(\lambda = 632.8 \text{ nm}, 0.645 \mu\text{W})$	10		1.5 s	309
C <sub>3</sub> N <sub>4</sub> /MoS <sub>2</sub> (flexible)	$(\lambda = 365 \text{ nm}, 0.5 \text{ W cm}^{-2})$	4.0	$4\times10^{11}$	60 ms/95 ms	278
oS <sub>2</sub> /graphene/polyimide (flexible) hotonic annealing at 2.8 kV for 1.36 ms)	$(\lambda = 515.6 \text{ nm}, 0.6 \text{ mA W}^{-1})$	$50~\mathrm{mA~W}^{-1}$	$3.18 \times 10^{9}$	5 ms	280
,	() 205 nm)	210	$4.5\times10^{11}$		202
oS <sub>2</sub> /Kapton (flexible)	$(\lambda = 325 \text{ nm})$	319		<del></del>	303
G (prom (G . U.L.)	$(\lambda = 532 \text{ nm})$	5.0	$6.4 \times 10^9$		2.5-
oS <sub>2</sub> /PET (flexible)	$(\lambda = 325 \text{ nm})$	136	$2.0 \times 10^{11}$	_	303
	$(\lambda = 532 \text{ nm})$	9.0	$9.7 \times 10^{9}$		
oS <sub>2</sub> /SiO <sub>2</sub> /Si	$(\lambda = 325 \text{ nm})$	44	$1.4 \times 10^{10}$	_	303
	$(\lambda = 532 \text{ nm})$	30	$9.5 \times 10^{9}$		
oS <sub>2</sub> /SiC	$(\lambda = 325 \text{ nm})$	$1.02\times10^4$	$6.4\times10^{11}$	_	303
	$(\lambda = 532 \text{ nm})$	$1.6 \times 10^{3}$	$1.0\times10^{11}$		
nO NFs/MoS <sub>2</sub> (flexible)	$(\lambda = 350 \text{ nm}, 1.2 \text{ mW cm}^{-2})$	$8.99 \times 10^{-4}$	_	61 s/90 s	277
ii) MoS <sub>2</sub> /2D van der Waals					
eterostructure-based photodetectors					
MoS <sub>2</sub> /1L graphene	$(\lambda = 532 \text{ nm}, 0.01 \text{ W m}^{-2})$	$1.2\times10^7$	_	2.5 s	226
oS <sub>2</sub> /graphene nanoribbon	$(\lambda = 385, 2.1 \mu\text{W})$	1.2 × 10 66	_		232
-0.		_	$-$ 9. $\times$ 10 <sup>15</sup>	5 ms/30 ms	
raphene/MoS <sub>2</sub> /graphene	$(\lambda = 633 \text{ nm}, 1 \mu\text{W cm}^{-2})$	$1.14 \times 10^5$		25.7 s/41.4 s	300
ı/MoS <sub>2</sub> /Au	$(\lambda = 633 \text{ nm}, 1 \mu \text{W cm}^{-2})$	$4.8 \times 10^{3}$	$2.7 \times 10^{14}$	7.1 s/31.8 s	300
	$(\lambda = 432 \text{ nm})$	$2.2  imes 10^5$	$3.5 \times 10^{13}$	1.7 ms/2.8 ms	301 <i>a</i>
	() 460 0 1172)	2.10	$5\times10^{11}$	18 ms	310
MoS <sub>2</sub> /rGO NPs	$(\lambda = 460 \text{ nm}, 8 \text{ mW cm}^{-2})$				100
MoS <sub>2</sub> /rGO NPs	$(\lambda = 400 \text{ nm}, 8 \text{ mw cm}^{-2})$ $(\lambda = 400 \text{ nm}, 6.35 \text{ nW cm}^{-2})$	$6.6 \times 10^{7}$	_	7 ms/21.86 ms	199
MoS <sub>2</sub> /rGO NPs L graphene–MoS <sub>2</sub> –WS <sub>2</sub> /fiber		$6.6 \times 10^{7}$ $180$	$-$ 2.6 $\times$ 10 <sup>13</sup>	7 ms/21.86 ms 0.23 s/0.25 s	199 196
L MoS <sub>2</sub> /rGO NPs L graphene–MoS <sub>2</sub> –WS <sub>2</sub> /fiber oS <sub>2</sub> /h-BN/graphene	$(\lambda = 400 \text{ nm}, 6.35 \text{ nW cm}^{-2})$ $(\lambda = 532 \text{ nm})$	180	$2.6\times10^{13}$		
raphene/MoS <sub>2</sub> /graphene L MoS <sub>2</sub> /rGO NPs L graphene–MoS <sub>2</sub> –WS <sub>2</sub> /fiber loS <sub>2</sub> /h-BN/graphene L 2H-SnSe <sub>2</sub> /1L 2H-MoS <sub>2</sub> L ML MoS <sub>2</sub>	$(\lambda = 400 \text{ nm}, 6.35 \text{ nW cm}^{-2})$			0.23 s/0.25 s	196

MoS <sub>2</sub> photodetector	Conditions (wavelength, incident power)	Photoresponsivity (A W <sup>-1</sup> )	Detectivity (Jones)	Response time $( au_{ m rise}/ au_{ m decay})$	Ref.
ML PdSe <sub>2</sub> /MoS <sub>2</sub>	$(λ = 10.6 \mu m, 435.9 \text{ nW})$ $(λ = 4.012 \mu m)$	42.1 28.83	$8.21 \times 10^9$ $6.09 \times 10^{10}$	74.5 ms/93.1 ms	168 168
FL MoS <sub>2</sub> /FL SnSe	$(\lambda = 532, 0.65 \text{ nW})$	100	_	4 ms/6 ms	201
MoS <sub>2</sub> /WS <sub>2</sub>	$(\lambda = 638 \text{ nm})$	1.36	_	—	204
ML MoS <sub>2</sub> /MoTe <sub>2</sub>	$(\lambda = 532 \text{ nm}, 100 \text{ mW cm}^{-2})$	0.62	$10^{10}$	0.01 ms	205a
ML MoS <sub>2</sub> /MoTe <sub>2</sub>	$(\lambda = 473 \text{ nm}, 46.8 \text{ mW cm}^{-2})$	0.15	_	68 ms/68 ms	205b
MoS <sub>2</sub> /MoTe <sub>2</sub>	$(\lambda = 1200 \text{ nm})$	0.046	_	60 μs/25 μs	205 <i>c</i>
ML MoS <sub>2</sub> /MoTe <sub>2</sub>	$(\lambda = 473 \text{ nm})$	0.064	$\textbf{1.6}\times\textbf{10}^{10}$	385 ms/453 ms	205d
1L MoS <sub>2</sub> /GaSe	$(\lambda = 300 \text{ nm}, 6.41 \text{ mW cm}^{-2})$	0.063	_	80 ms/20 ms	167 and 20
FL MoS <sub>2</sub> /FL black phosphorus	$(\lambda = 532 \text{ nm}, 1 \text{ nW})$	22.3	$3.1\times10^{11}$	—	170
TE MOS2/TE black phosphorus	$(\lambda = 1550 \text{ nm}, 1 \text{ nW})$	0.1534	$2.13 \times 10^{9}$	15 μs/70 μs	17.0
MoS <sub>2</sub> /FL black phosphorus	$(\lambda = 520 \text{ nm})$	5000	$1.6 \times 10^{10}$	0.02 s	332
FL WSe <sub>2</sub> /FL BP/FL MoS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 13.5 \text{ nW})$	6.32	$1.25 \times 10^{11}$	_	333
12 (1002/12 21/12 11002	$(\lambda = 1550 \text{ nm}, 13.5 \text{ nW})$	1.12	$2.21 \times 10^{10}$	_	333
MAPbI <sub>3</sub> /FL BP/FL MoS <sub>2</sub>	$(\lambda = 457 \text{ nm}, 0.02 \text{ mW cm}^{-2})$	11	$1.3 \times 10^{12}$	0.15 ms/0.24 ms	341
MoS <sub>2</sub> /graphene/WSe <sub>2</sub>	$(\lambda = 532 \text{ nm}, 0.02 \text{ nW})$	4250	$2.2 \times 10^{12}$	53.6 μs/30.3 μs	198
GaTe/MoS <sub>2</sub>	$(\lambda = 633 \text{ nm}, 0.2 \text{ nW})$ ( $\lambda = 633 \text{ nm}, 100 \text{ mW cm}^{-2}$ )	1.365	_	10 ms	167
GaSe/MoS <sub>2</sub>	$(\lambda = 330 \text{ nm})$ ( $\lambda = 300 \text{ nm}$ )	0.06	_	80 ms/20 ms	207a
FL graphene/GaSe/MoS <sub>2</sub>	$(\lambda = 530 \text{ nm})$ $(\lambda = 532 \text{ nm})$	3.0	$10^{10}$	50 ms	207 <i>b</i>
FL GaTe/FL MoS <sub>2</sub>	$(\lambda = 332 \text{ mH})$ $(\lambda = 473 \text{ nm}, 0.04 \text{ mW})$	21.83	$8.4 \times 10^{13}$	7 ms	334
1L MoS <sub>2</sub> /ML MoSe <sub>2</sub>	$(\lambda = 473 \text{ mHz}, 0.04 \text{ mW})$ $(\lambda = 610 \text{ nm}, 0.29 \text{ mW cm}^{-2})$	1.3	$2.6 \times 10^{11}$	0.6 s/0.5 s	335
BL MoS <sub>2</sub> /BLWS <sub>2</sub> (CVD)	$(\lambda = 457 \text{ nm}, 0.29 \text{ mW cm}^{-2})$	$6.7 \times 10^3$	$3.09 \times 10^{13}$		
BL MOS <sub>2</sub> /BLWS <sub>2</sub> (CVD)	$(\lambda = 437 \text{ nm}, 3.57 \mu\text{W cm}^{-2})$ $(\lambda = 532 \text{ nm}, 3.57 \mu\text{W cm}^{-2})$	$3.0 \times 10^{3}$	$1.24 \times 10^{13}$	<del>_</del>	344 344
EL C In Co. /11 MoC	$(\lambda = 532 \text{ nm}, 3.37 \text{ µW cm}^{-2})$		$5 \times 10^{11}$	4 ms/7 ms	
FLβ-In <sub>2</sub> Se <sub>3</sub> /1L MoS <sub>2</sub>		$23.7$ $7 \times 10^{-5}$	5 × 10	4 ms// ms 1.1 s/2.7 s	354
WS <sub>2</sub> /MoS <sub>2</sub> vdWHs WS <sub>2</sub> /MoS <sub>2</sub> vdWHs nanoscroll	(405 nm, 3.25 mW mm <sup>-2</sup> ) (405 nm)	0.647	_	0.7 s/2/4 s	382 382
Perovskite/MoS <sub>2</sub> -rGO ML 1T-MoS <sub>2</sub> /CH <sub>3</sub> NH <sub>3</sub> PbI <sub>3</sub> ML 2H-MoS <sub>2</sub> /CH <sub>3</sub> NH <sub>3</sub> PbI <sub>3</sub> 2H-MoS <sub>2</sub> /1T@2H-MoS <sub>2</sub> 1L 2H-MoS <sub>2</sub> 1L MoS <sub>2</sub> /CsPbI <sub>3-x</sub> Br <sub>x</sub> QDs 1L MoS <sub>2</sub> /CsPbBr <sub>3</sub> MoS <sub>2</sub> /CsPbBr <sub>3</sub> QDs 1L MoS <sub>2</sub> /CsPbBr <sub>3</sub> NCs 1L MoS <sub>2</sub> /CsPbBr <sub>3</sub> NCs	(λ = 660  nm) (λ = 500  nm, 0.14  mW) (λ = 500  nm, 0.14  mW) $(λ = 532 \text{ nm}, 2.35 \text{ mW cm}^{-2})$ $(λ = 532 \text{ nm}, 2.35 \text{ mW cm}^{-2})$ (λ = 532  nm, 1.5  μW) $(λ = 442 \text{ nm}, 20 \text{ μW cm}^{-2})$ $(λ = 405 \text{ nm}, 12.8 \text{ μW cm}^{-2})$ $(λ = 405 \text{ nm}, 0.6 \text{ mW cm}^{-2})$ (λ = 532  nm)	$1.08 \times 10^{4}$ $3.3 \times 10^{5}$ $142$ $1917$ $56$ $7.7 \times 10^{4}$ $4.4$ $4.68 \times 10^{4}$ $24.34$ $6.4 \times 10^{2}$	$4.28 \times 10^{13}$ $7 \times 10^{11}$ $2.6 \times 10^{11}$ $7.55 \times 10^{11}$ $1.3 \times 10^{11}$ $1.5.6 \times 10^{11}$ $1.5.6 \times 10^{11}$ $1.5.6 \times 10^{11}$ $1.5.8 \times 10^{11}$ $1.5.8 \times 10^{11}$ $1.5.9 \times 10^{12}$ $1.5.9 \times 10^{12}$ $1.5.9 \times 10^{11}$	45 ms 0.45 s/0.75 s 25 ms/50 ms — 0.59 s/0.32 s 0.72 ms/1.01 ms 7.5 ms/8 ms 5.5 μs/24 μs	179 325 <i>c</i> 325 <i>d</i> 325 <i>d</i> 190 191 <i>a</i> 191 <i>b</i> 191 <i>c</i>
ML MoS <sub>2</sub> /CsFbbi <sub>3</sub> NCs ML MoS <sub>2</sub> /CH <sub>3</sub> NH <sub>3</sub> Pbi <sub>3</sub> /APTES	$(\lambda = 532 \text{ nm})$ $(\lambda = 520 \text{ nm}, 4.63 \text{ pW})$	$2.12\times10^4$	$1.38 \times 10^{10}$	6.17 s/4.5 s	191 <i>a</i> 192
ML MoS <sub>2</sub> /APTES	$(\lambda = 520 \text{ nm})$ ( $\lambda = 520 \text{ nm}$ )	$2.38 \times 10^{3}$	$4.23 \times 10^{9}$	—	192
ML MoS <sub>2</sub>	$(\lambda = 520 \text{ nm})$ $(\lambda = 520 \text{ nm})$	$8.16 \times 10^{2}$	$3.93 \times 10^{9}$	10.7 s/6.2 s	192
FL MoS <sub>2</sub> /MA <sub>3</sub> Bi <sub>2</sub> Br <sub>9</sub>	$(\lambda = 520 \text{ nm})$ $(\lambda = 530 \text{ nm}, 18 \text{ µW cm}^{-2})$	112	$3.8 \times 10^{12}$	0.3 ms/0.3 ms	326
MoS <sub>2</sub> /CH <sub>3</sub> NH <sub>3</sub> PbI <sub>3</sub> (vertical)		68.11	5.0 × 10 —	205 ms/206 ms	327
MoS <sub>2</sub> /CH <sub>3</sub> NH <sub>3</sub> PbI <sub>3</sub> (vertical)	<u> </u>	28	_	356 ms/204 ms	327
(PEA) <sub>2</sub> SnI <sub>4</sub> /FL MoS <sub>2</sub> /graphene	$(\lambda = 451 \text{ nm}, 36 \text{ pW})$	1100	$8.09 \times 10^{9}$	34 ms/38 ms	328
(PEA) <sub>2</sub> PI <sub>4</sub> /ML MoS <sub>2</sub>	$(\lambda = 431 \text{ nm}, 30 \text{ pW})$ ( $\lambda = 637 \text{ nm}, 0.1 \text{ nW})$	16.8	$1.06 \times 10^{13}$	6 ms/4 ms	322b
(v) MoS <sub>2</sub> /inorganic semiconductor heterostructure-based photodetectors					
ML MoS <sub>2</sub> /Si	$(\lambda = 808 \text{ nm}, 1 \text{ mW cm}^{-2})$	300	$10^{13}$	$4~\mu s/42~\mu s$	162
ML MoS <sub>2</sub> /Si	$(\lambda = 780 \text{ nm}, 45 \mu\text{W cm}^{-2})$	23.1	$1.63 \times 10^{12}$	21.6 μs/65.5 μs	311
ML MoS <sub>2</sub> /Si	$(\lambda = 580 \text{ nm}, 5 \text{ mW cm}^{-2})$	8.75	$1.4\times10^{12}$	10 μs/19 μs	312 <i>a</i>
MoS <sub>2</sub> /Si (porous)	$(\lambda = 550 \text{ nm})$	9	$8 \times 10^{12}$	9 μs/7 μs	312 <i>b</i>
= 4 /	$(\lambda = 650 \text{ nm}, 90 \text{ mW cm}^{-2})$	11.9	$2.1  imes 10^{10}$	30.5 μs/71.6 μs	313
V-ML MoS <sub>2</sub> /Si				•	
<del>-</del>		908.2	$1.88 \times 10^{13}$	56 ns/825 ns	303
V-FL MoS <sub>2</sub> /Si	$(\lambda = 808 \text{ nm}, 1.6 \text{ mW cm}^{-2})$	908.2 76.1	$1.88 \times 10^{13}$ $1.6 \times 10^{12}$	56 ns/825 ns 48.9 s	305 175
V-FL MoS <sub>2</sub> /Si V-ML MoS <sub>2</sub> /Si	$(\lambda = 808 \text{ nm}, 1.6 \text{ mW cm}^{-2})$ $(\lambda = 660 \text{ nm}, 12 \text{ nW})$	76.1	$1.6\times10^{12}$	48.9 s	175
V-ML MoS <sub>2</sub> /Si V-FL MoS <sub>2</sub> /Si V-ML MoS <sub>2</sub> /Si V-FL MoS <sub>2</sub> /Si FL MoS <sub>2</sub> /Si FET	$(\lambda = 808 \text{ nm}, 1.6 \text{ mW cm}^{-2})$				

Table 1 (Contd.)

MoS <sub>2</sub> photodetector	Conditions (wavelength, incident power)	Photoresponsivity (A W <sup>-1</sup> )	Detectivity (Jones)	Response time $(\tau_{\rm rise}/\tau_{\rm decay})$	Ref.
ii/MoS <sub>2</sub>	$(\lambda = 660 \text{ nm})$	1.1	_	0.38 s/0.1 s	138
i-(Au@MoS <sub>2</sub> )	$(\lambda = 800 \text{ nm})$	30	_	0.02 s	138
au@MoS <sub>2</sub> core–shell	$(\lambda = 660 \text{ nm}, 50 \mu\text{W})$	0.5	_	3.2 s/0.28 s	138
ML MoS <sub>2</sub> /GaN	$(\lambda = 405 \text{ nm}, 2 \text{ mW})$	17.2	$1.8\times10^{12}$	0.1 s/9 s	317 <i>a</i>
//L MoS <sub>2</sub> /GaN	$(\lambda = 365 \text{ nm}, 4.351 \mu\text{W})$	11.3	$1.34\times10^{10}$	21.1 s/19.7 s	317 <i>b</i>
ll <sub>2</sub> O <sub>3</sub> /MoS <sub>2</sub> /GaN	$(\lambda = 365 \text{ nm}, 3.141 \mu\text{W})$	24.62	$7.2 \times 10^{9}$	12.8 s/26.4 s	317 <i>b</i>
MoS <sub>2</sub> /GaAs (CVD)	$(\lambda = 635 \text{ nm})$	0.321	$3.5 \times 10^{13}$	17 μs/31 μs	318
iQDs/MoS <sub>2</sub> /h-BN/GaAs	$(\lambda = 635 \text{ nm})$	0.419	$1.9 \times 10^{14}$		318
L MoS <sub>2</sub> /CdSe	$(\lambda = 405 \text{ nm}, 8.52 \mu\text{W cm}^{-2})$	$2.5 \times 10^{5}$	$1.24 \times 10^{14}$	60 ms/60 ms	323
MoS <sub>2</sub> /ZnCdSe/ZnS QDs	$(\lambda = 450 \text{ nm}, 400 \text{ nW})$	$3.7 \times 10^4$	$1 \times 10^{12}$	0.3 s/1.2 s	194
L MoS <sub>2</sub> /TiO <sub>2</sub> /HgTe QDs	$(\lambda = 635 \text{ nm}, 100 \text{ nW})$ ( $\lambda = 635 \text{ nm}, 0.35  \mu\text{W cm}^{-2}$ )	$5 \times 10^5$	$6.4 \times 10^{12}$	—	193
E Mosy, Hoghigie QBs	$(\lambda = 330 \text{ nm}, 638 \text{ pW cm}^{-2})$	$2 \times 10^4$	$3 \times 10^{11}$	4 ms	130
//L MoS <sub>2</sub> /TiO <sub>2</sub> /PbS QDs	$(\lambda = 635 \text{ nm}, 35 \text{ mW cm}^{-2})$	$10^5$	$5 \times 10^{12}$	12 ms	319
MoS <sub>2</sub> /PbS	$(\lambda = 800 \text{ nm}, 10 \text{ nW cm}^{-2})$	$4.5 \times 10^{4}$	$3 \times 10^{13}$ $3 \times 10^{13}$	7.8 ms	321
L MoS <sub>2</sub> /PbS QDs	$(\lambda = 635 \text{ nm}, 0.13 \text{ mW})$	$6.0 \times 10^{5}$	$7 \times 10^{14}$	0.35 s	322
L MoS <sub>2</sub> /PbS QDs	$(\lambda = 850 \text{ nm})$	$5.4 \times 10^4$	$1 \times 10^{11}$	950 μs/1 ms	188
MoS <sub>2</sub> -ZnO/PET	$(254 \text{ nm}, 2.65 \text{ W m}^{-2})$	2.7	1 × 10	13.96 s/55.33 s	296
0-MoS <sub>2</sub> /n-ZnO	(365 nm, 5.7 mW cm <sup>-2</sup> )	24.36		0.9 s/1.04 s	360
n-MoS <sub>2</sub> /n-ZnO	(532 nm)	0.35		1.3 s/2.2 s	360
L $MoS_2/TiO_2$ nanoflowers	$(\lambda = 370 \text{ nm})$	35.9	$-$ 1.98 $\times$ 10 <sup>13</sup>	33.7 ms/28.3 ms	320
L MOS <sub>2</sub> /11O <sub>2</sub> Halloflowers	$(\lambda = 570 \text{ nm})$ $(\lambda = 570 \text{ nm})$	18.5	$1.98 \times 10^{1.09} \times 10^{13}$	- 1115/20.3 1115 -	320
I Moc /T;	,	8.6	$5.7 \times 10^{12}$		
L MoS <sub>2</sub> /Ti	$(\lambda = 570 \text{ nm})$ $(\lambda = 570 \text{ nm})$		$3.49 \times 10^{12}$	741 ms/128 ms	320 320
L MoS <sub>2</sub> /SiO <sub>2</sub>	,	6.2	$3.49 \times 10$ $3.325 \times 10^{11}$	642 ms/214 ms	
V-MoS <sub>2</sub> /TiO <sub>2</sub>	$(\lambda = 532 \text{ nm}, 856 \text{ nW})$	133	$3.3 \times 10^{8}$ $3.3 \times 10^{8}$	27.8 ms/48 ms	346 <i>b</i>
MoS <sub>2</sub> /CuO nanowires (strain) -ITO/MoS <sub>2</sub> /Cu <sub>2</sub> O/Au	$(\lambda = 600 \text{ nm}, 55 \mu\text{W})$ $(\lambda = 500 \text{ nm}, 0.26 \text{ W m}^{-2})$	$157.6$ $5.77 \times 10^4$	$3.3 \times 10$ $3.2 \times 10^{14}$	34.6 ms/51.9 ms 70 ms	331 302
vi) Chemically doped	(				
MoS <sub>2</sub> photodetectors	(2 )				
L MoS <sub>2</sub> /methylene blue doping	$(\lambda = 610 \text{ nm})$	9.09	$2.2 \times 10^{11}$	27.1 s/39.2 s	140
L MoS <sub>2</sub> /R6G doping	$(\lambda = 520 \text{ nm}, 1 \mu\text{W})$	1.17	$1.5 \times 10^{7}$	$5.1 \mu\text{s}/2.3 \text{s}$	181
ML MoS <sub>2</sub> /PPh <sub>3</sub> doping	$(\lambda = 520 \text{ nm}, 5 \text{ pW})$	$3.92 \times 10^{5}$	$2.36 \times 10^{10}$	13.2 ms/17.2 ms	187
L MoS <sub>2</sub> /HAuCl <sub>4</sub> doping	$(\lambda = 532 \text{ nm}, 0.15 \text{ mW cm}^{-2})$	99.9	$9.4 \times 10^{12}$	16.6 s/5.2 s	337
L MoS <sub>2</sub> /pentacene	$(\lambda = 655 \text{ nm}, 28.18 \text{ mW cm}^{-2})$	0.31	$1.55 \times 10^{13}$	_	330
L MoS <sub>2</sub> /ZnPc/Al <sub>2</sub> O <sub>3</sub>	$(\lambda = 532 \text{ nm}, 0.07 \text{ mW cm}^{-2})$	$1.4 \times 10^{4}$	$3 \times 10^{11}$	_	182
	$(\lambda = 532 \text{ nm}, 3.64 \text{ mW cm}^{-2})$	$4.3 \times 10^{2}$	_	<del>-</del>	
L MoS <sub>2</sub> /ZnPc	$(\lambda = 532 \text{ nm}, 3.64 \text{ mW cm}^{-2})$	7.84		100 ms/10 ms	182
L MoS <sub>2</sub> /P(VDF-TrFE)	$(\lambda = 635 \text{ nm}, 1 \text{ nW})$	$2.579 \times 10^{3}$	$2.2\times10^{12}$	1.8 ms/2 ms	137
MoS <sub>2</sub> /P(VDF-TrFE-CFE)	$(\lambda = 450 \text{ nm}, 20 \text{ nW})$	346.24	_	_	324
$MoS_2/P(VDF-TrFE)$	$(\lambda = 637 \text{ nm}, 1 \text{ nW})$	$3.26 \times 10^{3}$	$9.0 \times 10^{14}$	480 μs/320 μs	340
MoS <sub>2</sub> /polyaniline (PANI)	$(\lambda = 785 \text{ nm}, 1.4 \text{ mW mm}^{-2})$	25	_		338
$MoS_2$ - $MoO_x$	$(\lambda = 405 \text{ nm}, 1 \text{ mW cm}^{-2})$	1.09	$2.08 \times 10^{11}$	9.8 s/12.6 s	339
MoS <sub>2</sub> /UCNPs	$(\lambda = 325 \text{ nm}, 50 \text{ W m}^{-2})$	192	$1.61 \times 10^{14}$	_	364
	$(\lambda = 532 \text{ nm}, 50 \text{ W m}^{-2})$	81	$6.80 \times 10^{13}$	16 s/18 s	364
	$(\lambda = 980 \text{ nm}, 50 \text{ W m}^{-2})$	1254	$1.05 \times 10^{15}$	11 s/17 s	364
	$(\lambda = 1064 \text{ nm}, 50 \text{ W m}^{-2})$	127.5	$1.05\times10^{14}$	_	364
MoS <sub>2</sub> /Mo <sub>2</sub> C (multiple grating)	$(\lambda = 665 \text{ nm})$	$3.7 \times 10^{3}$	_	0.13 s/0.95 s	387
${ m b_2O_3/MoS_2}$	$(\lambda = 532 \text{ nm}, 0.057 \text{ W cm}^{-2})$	$4.5 \times 10^4$	$1.0\times10^{15}$	63 ms/71 ms	372
BaTiO <sub>3</sub> /MoS <sub>2</sub>	(365 nm, 1.0 mW cm <sup>-2</sup> )	120	$1.1\times10^{11}$	0.7  s/2 s	375
MoSSe	(660 nm, 1.75 mW mm <sup>-2</sup> )	$1.75 \times 10^{-3}$	_	4.7 ms	385
$MoS_{1.15}Se_{0.85}$	(532 nm)	2.06	_	18 ms/35 ms	386
	(650 nm)		$10^{12}$		435

<sup>&</sup>lt;sup>a</sup> 1L: single-layer, BL: bi-layer, FL: few-layer, ML: multilayer, V: vertically oriented, PET: poly(ethylene terephthalate), PPh<sub>3</sub>: triphenylphosphine, QDs: quantum dots, SiNWA: Si nanowire array, P(VDF-TrFE): poly(vinylidene fluoride-trifluoroethylene) [P(VDF-TrFE)] ferroelectric polymer, P(VDF-TrFE-CFE): poly(vinylidene fluoride-trifluoroethylene), APTES: (3-aminopropyl)triethoxysilane, ZnPc: zinc phthalocyanine, Jones = cm  $Hz^{1/2}$  W<sup>-1</sup>, polymer stabilizer ethyl cellulose (EC), 2D Ruddlesden-Popper perovskites: ( $C_6H_5C_2H_4NH_3 = PEA)_2SnI_4$ , PANI: polyaniline,  $Mo_2C$ : molybdenum carbide.

 ${
m MoS_2-ZnO/PET}$  hybrid photodetectors showed no significant degradation after bending at 3 mm radius; up to 10 000 cycles were examined.

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0D PbS QDs were deposited onto few layered 2H-MoS2 to develop flexible photodetectors on a PET substrate.<sup>297</sup> The 0D/ 2D PbS/MoS<sub>2</sub> hybrid photodetectors showed the photoresponsivity of 0.398 to 0.543 A  $W^{-1}$  and the detectivity of 2  $\times$  $10^{12}$  to  $2.68 \times 10^{12}$  Jones between 480 to 1200 nm at a 2 V bias. The 2H-MoS<sub>2</sub> based stretchable photodetectors were fabricated on polydimethylsiloxane (PDMS) substrates.298 The photoresponsivity of 2.52  $\mu A W^{-1}$  and response times of 122 ms/120 ms were recorded at 515.6 nm. The stretchable photodetectors retained the photoconductivity up to 5.72% tensile strain and over 1000 stretching cycles. MoS2 was deposited on a flexible cellulose ester paper and the inkjet-printed PEDOT:PSS electrodes were used to develop MoS<sub>2</sub> paper based photodetectors, which showed internal quantum efficiency of 0.063%, photoresponsivity of 0.134 mA W<sup>-1</sup> and photoresponse response/ recovery times of 17.5 s/15.3 s at 405 nm.299

# 5. Analysis and factors affecting the figure of merit of MoS<sub>2</sub> photodetectors

All these studies show that MoS2 atomic layers can be used to develop high-performance photodetectors. The analysis and factors affecting the parameters such as photoresponsivity, specific detectivity, NEP, photogain, EQE, LDR, and response time of the MoS<sub>2</sub> photodetectors have been further discussed in this section. Table 1 summarizes the research data collected on the figure-of-merit of a wide variety of MoS2 based photodetectors in terms of their key parameters such as photoresponsivity, detectivity and response/recovery time ( $\tau_{rise}/\tau_{decay}$ ) of photodetectors and their performance measured at various laser wavelengths under different incident laser powers/intensities.  $^{138,171,175,179,190-199,217,226,300-435}$  The MoS<sub>2</sub> based photodetectors have been analyzed taking into account the factors affecting their performance. MoS<sub>2</sub> based photodetectors have also been discussed and categorized as (i) pristine MoS<sub>2</sub> based photodetectors, (ii) flexible MoS<sub>2</sub> photodetectors, (iii) MoS<sub>2</sub>/2D van der Waals heterostructure-based photodetectors, (iv) MoS<sub>2</sub>/perovskite heterostructure-based photodetectors, (v) MoS<sub>2</sub>/inorganic semiconductor heterostructure-based photodetectors, (vi) chemically doped MoS2 photodetectors, and (vii) self-powered MoS<sub>2</sub> photodetectors.

The influence of different types of substrate materials on the performance of MoS<sub>2</sub> photodetectors has been extensively studied. 164,178,184,217-220,222,223,234,256,259,278,298,311-313 MoS<sub>2</sub>@TiO<sub>2</sub> photodetectors core-shell heterojunction-based were prepared by Paul et al.320 where 1L MoS2 was used as the shell and TiO<sub>2</sub> nanoflowers as the core. The 83 and 30 times increase in PL intensity was observed from the 1L MoS2 shell/ TiO<sub>2</sub> nanoflowers p-n heterojunction more than that of 1L MoS<sub>2</sub>/Ti and 1L MoS<sub>2</sub>/sapphire substrates, respectively. The 1L MoS<sub>2</sub>@TiO<sub>2</sub> heterojunction-based photodetectors showed photoresponsivity of 35.9 A  $W^{-1}$  and detectivity of 1.98  $\times$   $10^{13}\,$ Jones in the UV region and 18.5 A W<sup>-1</sup> and  $1.09 \times 10^{13}$  Jones in

the visible region. 1L  $MoS_2$ @ $TiO_2$  heterojunction also exhibited an order of magnitude faster photoresponse compared to the 1L  $MoS_2$ @Ti and 1L  $MoS_2$ @ $SiO_2$  devices due to the fast photoexcited carrier transport at the p-n heterojunction associated with the substantial built-in electric field. In another study,  $MoS_2$  nanosheets were placed on top of a CuO nanowire by wet transfer printing method.  $^{331}$   $MoS_2$ /CuO heterojunction-based photodetectors showed the photoresponsivity 157.6 A  $W^{-1}$ , rectification ratio of 6000, and low dark current of 38 fA at -2 V.

## 5.1 0D/2D quantum dots/MoS<sub>2</sub> hybrid heterostructures

The performance of MoS<sub>2</sub> photodetectors can be significantly enhanced by developing hybrid heterostructures as discussed in the earlier sections. Kufer et al. 322a showed significantly increased light absorption and carrier mobility in the 2D-0D MoS<sub>2</sub>/PbS QDs hybrid phototransistors. The photoresponsivity of pristine bilayer MoS2 with MoS2/PbS hybrid were compared as a function of wavelength between 600 nm to 1200 nm. The bilayer MoS2 absorbs up to 700 nm whereas the MoS2/PbS hybrid extends the absorption up to 1200 nm with an excitation peak at 980 nm. Bilayer MoS2 phototransistors showed fieldeffect mobility of 10–20 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and current  $I_{on}/I_{off}$  ratios of 10<sup>5</sup> to 10<sup>6</sup> which is further increased after PbS QDs doping. The photoresponsivity of pristine bilayer MoS<sub>2</sub> is 5 A W<sup>-1</sup> at 1.8 eV, which is dramatically enhanced to 10<sup>5</sup> to 10<sup>6</sup> A W<sup>-1</sup> for the MoS<sub>2</sub>/PbS hybrid phototransistor due to the PbS DQs. The multilayer MoS2/PbS hybrid photodetector showed photoresponsivity up to  $10^6 \,\mathrm{A}\,\mathrm{W}^{-1}$  at the lowest laser power intensity. The photoresponsivity of the hybrid photodetector varies by six orders of magnitude as a function of applied laser power intensity, which decreased as the laser intensity increases. The photoresponse of hybrid photodetector to light can be tailored by adjusting the size of PbS QDs. The photoresponsivity of the hybrid photodetector (6  $\times$  10<sup>5</sup> A W<sup>-1</sup>) was found to be three orders of magnitude higher than that of PbS QDs  $(4.3 \times 10^2 \text{ A})$  $W^{-1}$ ). The NEP were found to be 2  $\times$  10<sup>-15</sup> W Hz<sup>-1/2</sup> for the bilayer MoS<sub>2</sub> and  $7 \times 10^{-16}$  W Hz<sup>-1/2</sup> for few-layer MoS<sub>2</sub>/PbS hybrids at 1 Hz frequency, yielding corresponding detectivity of  $2 \times 10^{11}$  Jones and  $5 \times 10^{11}$  Jones, respectively. The MoS<sub>2</sub>/PbS hybrid photodetector reached detectivity as high as  $7 \times 10^{14}$ Jones at applied negative back-gate bias  $V_g$  of -100 V. The study showed that MoS<sub>2</sub>/PbS hybrid photodetector can achieve several orders of magnitude higher photoresponsivity than those of individual bilayer MoS2 and PbS QD-based photodetectors. In another study, Pak et al. 322b fabricated hybrid photodetectors by decorating n-type MoS<sub>2</sub> with p-type manganese oxide QDs (MnO QDs), which showed suppressed dark current (5 nA) and an enhancement of photocurrent (52 nA) compared to a pristine  $MoS_2$  photodetector (10 nA and 32 nA) at under 100 mW cm<sup>-2</sup> incident light intensity. MoS<sub>2</sub>/MnO QDs hybrid photodetectors showed the photoresponsivity of 20 A W $^{-1}$  and detectivity of 5  $\times$ 1011 Jones at 260 nm light illumination where increased detection was noticed in DUV range below 300 nm. The absorption of MnO QDs on MoS2 surface suppressed dark current and increased photogeneration of charge carriers.

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Ferroelectric polymers have been used with MoS<sub>2</sub> to improve the performance of photodetectors. Wang et al. 340 developed an ultrabroad band photodetector integrating unique pyroelectric properties of organic ferroelectric copolymer P(VDF-TrFE) with MoS<sub>2</sub>, which operated from 375 nm (ultraviolet) to 10 μm (LWIR) spectral range. The photocurrent of MoS<sub>2</sub> was improved in the 2.76  $\mu m$  to 10  $\mu m$  spectral range due to the pyroelectricity of P(VDF-TrFE). The photoresponsivity of 140 mA W $^{-1}$ ,  $I_{on}/I_{off}$ current ratio of 10<sup>3</sup> and a response time of 5.5 ms was achieved for the MoS<sub>2</sub>/P(VDF-TrFE) hybrid photodetector. Though the highest photoresponsivity of  $3.26 \times 10^3$  and detectivity of  $9.0 \times 10^3$ 10<sup>14</sup> Jones were observed at 637 nm illumination at the drain bias of 5 V, the ferroelectric polarization field of P(VDF-TrFE) significantly improved the photoconductivity of MoS2 and curtailed the dark current as well as the noise. The single-pixel imaging was also recorded by the photodetector. In a recent study, Li et al. 337 showed that the photoresponsivity and detectivity of n-doped monolayer MoS2 photodetector increased by 14.6 and 4.8 times compared with pristine MoS<sub>2</sub> photodetector, after in situ chemical doping with gold chloride hydrate (HAuCl<sub>4</sub>·xH<sub>2</sub>O). The in situ n-doped MoS<sub>2</sub> based photodetector exhibited the photoresponsivity of 99.9 A W<sup>-1</sup> and detectivity of  $9.4 \times 10^{12}$  Jones under  $V_{\rm ds} = 0.1$  V and  $V_{\rm g} = 0$  V, much higher compared with pristine MoS2 photodetectors. The enhanced photoresponse originated from n-type chlorine doping of CVDgrown MoS<sub>2</sub> film which decreased the trapping of photoexcited electrons. Both photoresponsivity and detectivity of doped and pristine MoS<sub>2</sub> photodetectors were found to decrease with increasing incident laser power intensity. The chlorine n-type doping of MoS2 photodetector increased the photoresponse due to improved photogating effect. The n-doped MoS<sub>2</sub> photodetector exhibited EQE over 100% which was found to increase as a function of decreasing wavelength, confirming photoconversion efficiency under shorter light illuminating wavelengths because of the higher excitation energy. Furthermore, these n-doped MoS<sub>2</sub> photodetectors also showed long-term stability as demonstrated by retaining 94% of the initial photocurrent after up to nine months.

Perovskites, van der Waals and plasmonic materials have been used with MoS<sub>2</sub> to improve the performance of photodetectors. Wang et al.341a reported perovskite/black phosphorus/ MoS<sub>2</sub> photogate photodiode, which utilizes black phosphorus/ MoS<sub>2</sub> photodiodes with perovskite in order to induce high photoresponsivity and a fast photoresponse. This device architecture is constructed based on the fast photovoltaic operation together with the high-gain photogating effect. Under reverse bias condition, the 2D photogate photodiode showed photoresponsivity of 11 A W<sup>-1</sup>, detectivity of 1.3  $\times$  10<sup>12</sup> Jones, fast response times of 150/240  $\mu s$ , and a low dark current of 3 imes10<sup>-11</sup> A in reverse bias. The photogate photodiode device yielded detectivity of 3 × 10<sup>11</sup> Jones, external quantum efficiency (EQE) of 80% and  $I_{\rm on}/I_{\rm off}$  current ratio of 3  $\times$  10<sup>7</sup> in a zero bias (self-powered mode) indicating their potential in fabricating photodetectors and photovoltaic devices. The black arsenic phosphorus (b-AsP) which is a p-type semiconductor was used with MoS<sub>2</sub> n-type semiconductor to develop vdW p-n heterojunction-based MIR photodetectors.341b

photoresponsivity of AsP/MoS2 photodetectors varied from 216.1 mA W<sup>-1</sup> to 115.4 mA W<sup>-1</sup> as the laser wavelength was increased from 2.36  $\mu m$  to 4.29  $\mu m$  and the value of EQE decreased from 11.36% to 3.33%, respectively. The NEP of vdW p-n junction was less than 0.24 pW  $Hz^{-1/2}$ , while that of FET device below 4.35 pW Hz<sup>-1/2</sup> for 8.05 μm MIR wavelength at room temperature. The detectivity of the AsP/MoS2 vdW p-n junction remained higher than  $4.9 \times 10^9$  Jones over the 3 µm to 5 μm spectral range and larger than the detectivity of 1.06  $\times$  10<sup>8</sup> Jones for AsP FET device at 8.05 µm wavelength. These studies demonstrated fabrication of MoS<sub>2</sub> based MIR photodetectors. Wu et al.342 used a Au-supported gap-mode surface plasmon increasing configuration to improve the optoelectronic properties, with which a monolayer MoS2 photodetector exhibited a photoresponsivity of 287.5 A W<sup>-1</sup> and a 880% increment in the photocurrent.

The self-powered photovoltaic photodetector developed from individual monolayer MoS2-WS2 heterostructures showed photoresponsivity of 4.36 mA W<sup>-1</sup>, EQE of 1.02%, and detectivity of  $4.36 \times 10^{13}$  Jones at 532 nm under laser power intensity of 28.64 mW cm<sup>-2</sup> under 0 V bias.<sup>343</sup> Photoresponsivity of 4.34 and 10.44 mA W<sup>-1</sup> were measured for positive bias (3 V) and reversed bias (-3 V), respectively. Ye et al.344 used individual bilayers of MoS2-WS2 heterostructures to develop photodetectors which showed photoresponsivity of  $6.72 \times 10^3$  A W<sup>-1</sup> and detectivity of  $3.09 \times 10^{13}$  Jones at 457 nm laser illumination. The performance of bilayered MoS2-WS2 heterostructure photodetectors were several orders of magnitude higher compared with MoS2 and WS2 monocrystals. All-2D photodetectors were developed using the type-II band alignment of vertically stacked WS<sub>2</sub>/MoS<sub>2</sub> heterobilayers and graphene elec-WS<sub>2</sub>/MoS<sub>2</sub> heterobilayer-based photodetectors showed over an order of magnitude increase in the photoresponsivity than that of homobilayer photodetector and two orders of magnitude increase compared to WS2 and MoS2 monolayer-based photodetectors. The photoresponsivity of 10<sup>3</sup> A  $W^{-1}$  was measured under a power density of 1.7  $\times$  10<sup>2</sup> mW cm<sup>-2</sup>. The significant increase in photoresponsivity resulted from the strong Coulomb interactions occurring between WS<sub>2</sub> and MoS2 layers.

Color-selective and flexible MoS2 phototransistors on polyarylate substrates using integrated Fabry-Perot cavity filters were developed by Yoo et al.345 The multilayer MoS2 phototransistors showed a mobility of >64.4 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> and an  $I_{on}$ /  $I_{\rm off}$  current ratio >10<sup>6</sup>. The Fabry-Perot filters facilitated the coverage of the visible spectral range from 495 to 590 nm. The MoS<sub>2</sub> phototransistors showed no significant degradation after integrating the Fabry-Perot cavity and the SU-8 interlayer. Huo and Konstantatos<sup>346a</sup> developed all-2D MoS<sub>2</sub> phototransistors using an out-of-plane vertical MoS<sub>2</sub> p-n junction. The vertical built-in field in the MoS2 p-n junction reduced the recombination of the photoexcited carriers and yielded a photoresponsivity of 7  $\times$  10<sup>4</sup> A W<sup>-1</sup>, detectivity of 3.5  $\times$  10<sup>14</sup> Jones, a photoconductive gain of >105 and a fast photoresponse. Liu et al. 346b prepared a vertically oriented MoS2 nanosheets array using TiO2 buffer thin film on a SiO2 substrate which also yielded a high photoresponse. The floating monolayer MoS2

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quantum well structure was also used to develop graphene/WS<sub>2</sub>/ MoS<sub>2</sub> heterostructure based photodetectors, which resulted in higher photoresponsivity of 4.4  $\times~10^6~A~W^{-1}$  at 851 nm laser illumination under 30 fW laser power due to the strong photogating effect.347

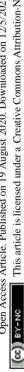
### Graphene electrodes

High photoresponsivities ranging from  $10^3$  A W<sup>-1</sup> to  $10^{10}$  A W<sup>-1</sup> have been observed for the graphene/MoS2 hybrid structurebased photodetectors. 126,226-228 Han et al. 300 developed photodetectors using CVD-grown MoS2 monolayers with both Au and graphene electrodes. MoS<sub>2</sub> photodetectors with graphene electrodes showed the current  $I_{\rm on}/I_{\rm off}$  ratio of 1  $\times$  10<sup>5</sup> and mobility of 0.48 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> compared to  $2 \times 10^3$  and 0.1 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> with gold electrodes. The shot-noise-limited detectivity of MoS<sub>2</sub> photodetectors was  $8.7 \times 10^{14}$  Jones for the graphene electrode and  $2.7 \times 10^{14}$  Jones for the Au electrode for 1 Hz bandwidth at the gate voltage  $(V_{\rm s}) = -30$  V. The detectivity of CVD-grown MoS<sub>2</sub> photodetectors were a few orders of magnitude higher compared to photodetectors made using exfoliated MoS2. Graphene/MoS<sub>2</sub>/graphene photodetectors were also fabricated where the MoS2 layer was encapsulated with a PMMA layer which showed mobility of 0.59 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>, better than nonencapsulated devices. Photoresponsivity of the PMMA encapgraphene/MoS<sub>2</sub>/graphene photodetectors measured as 1.4 imes 10<sup>5</sup> A W<sup>-1</sup> and 1.1 imes 10<sup>5</sup> A W<sup>-1</sup> at 633 nm under applied gate voltage of 10 V and -30 V, respectively. The graphene electrodes were found to be instrumental in improving the photoresponse of the MoS<sub>2</sub> photodetectors. Chee et al.301a used graphene/Ag contacts for MoS2 photodetectors where CVD-grown graphene film was inserted as an interfacial layer between the MoS<sub>2</sub> film and Ag electrode. The MoS<sub>2</sub> FETs having graphene/Ag contacts exhibited the higher mobility of 35 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup>, photoresponsivity of 2160 A W<sup>-1</sup>, and current  $I_{\text{on}}/I_{\text{on}}$  $I_{\rm off}$  ratio of 4 × 10<sup>8</sup>, compared to those of MoS<sub>2</sub> photodetectors with Ti/Au contacts due to the low work function of Ag and the Fermi level tunability in graphene. The n-doping by Ag electrode reduced the Fermi level of graphene, which consequently decreased the Schottky barrier height as well as contact resistance between the MoS2 layer and electrodes. This study demonstrated that low-resistance contacts with MoS2 and graphene played a significant role in enhancing the photoresponse of MoS<sub>2</sub> photodetectors. Bipolar phototransistors were developed by Li et al.301b using vertical Au/graphene/MoS2 vdWHs heterojunction where Au functions as the emitter and electrodes, MoS2 as the collector, and graphene as the base of the phototransistor. Au/graphene/MoS<sub>2</sub> vdWHs heterojunction-based photodetectors showed the photoresponsivity of 16 458 A W<sup>-1</sup> and detectivity of  $1.75 \times 10^{14}$  Jones at 405 nm laser illumination and incident power intensity of 0.45 mW cm<sup>-2</sup>. Lee et al.<sup>301c</sup> showed that the performance of MoS<sub>2</sub> photodetectors can be improved using graphene/MoS<sub>2</sub>/ graphene heterojunction-based phototransistors having short MoS<sub>2</sub> channel length greater than that of carrier diffusion length (220 nm) of MoS<sub>2</sub> and controlable Schottky barrier height (SBH). Fig. 23 shows the schematic illustration of MoS<sub>2</sub>

phototransistor with a graphene gate electrode, change of photoresponsivity with MoS2 channel length, the incident laser power dependent photoresponsivity and detectivity of graphene/MoS<sub>2</sub>/graphene heterojunction-based phototransistors at different gate bias voltage and time-dependent normalized photocurrent. The distance between the graphene source and the drain electrode was measured as 30 nm by atomic force microscopy (AFM) technique. The short channel effects were not observed in MoS2 transistors in the dark state in spite of their sub-30 nm channel length. The carrier recombination as well as the carrier transit time were found to be reduced by using sub-30 nm channel length which is much shorter compared to MoS2 diffusion length. Longer MoS2 channel length restricts the efficient flow of carriers from the source to the drain electrode. The Schottky barrier of phototransistors was manipulated by light and gate bias which supported decreased dark current and increased photocurrent. The SBH of the graphene/MoS<sub>2</sub> heterojunction was found to be decreased as the gate bias voltage was increased which supported the formation of ohmic contact. The SBH of the graphene/MoS<sub>2</sub> heterojunction was analyzed under different laser power intensity which was found to be 0.14 eV at  $V_{\rm gs} = -3$  V under the dark state. When 432 nm laser light was illuminated on the heterojunction, the SBH decreased with increasing laser power and, finally, disappeared at 0.14 µW laser power due to the photoinduced doping of graphene that eventually improved the performance of the graphene/MoS2 heterojunction phototransistors. Both photoresponsivity and detectivity significantly changed as a function of incident laser powers. The graphene/ MoS<sub>2</sub>/graphene heterojunction-based phototransistor showed photoresponsivity of 1996 A W<sup>-1</sup> and detectivity of  $3.57 \times 10^{10}$ Jones under laser power intensity of 0.34 nW at 432 nm laser wavelength and the maximum photocurrent of 2.15 µA with  $I_{\rm photo}/I_{\rm dark}$  current ratio of 4  $\times$  10<sup>4</sup> at laser power of 0.14  $\mu$ W. These heterojunction-based phototransistors showed the maximum photoresponsivity, detectivity and response time of  $2.2 \times 10^5$  A W<sup>-1</sup>,  $3.5 \times 10^{13}$  Jones and 2.8 ms at 432 nm, respectively, originating from the reduced MoS2 channel length and controlled Schottky barrier in the graphene/MoS2 heterojunction. These studies demonstrate that graphene electrodes played an important role in enhancing the performance of MoS2 photodetectors.

### 5.3 Semiconducting (2H) and metallic (1T) phases of MoS<sub>2</sub>

2D MoS<sub>2</sub> crystals exhibit several types of polymorphs, which have different electronic properties associated with semiconducting to metallic structural phase transformation.325a,b The stable polymorphs of MoS<sub>2</sub> have been used in developing ultra-broadband photodetectors. Wang et al.325c fabricated hybrid photodetectors using semiconducting trigonal prismatic 2H-phase and metallic octahedral 1T-phase MoS<sub>2</sub> nanosheets with organolead trihalide perovskites (MAPbX<sub>3</sub> where MA = methylammonium  $CH_3NH_3$  and X = I).  $1T-MoS_2/CH_3NH_3PbI_3$ hybrid thin films showed 90% PL quenching due to the efficient charge transfer from CH3NH3PbI3 to the 1T-MoS2 while 2H-MoS<sub>2</sub>/CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> films showed 60% PL quenching due to the



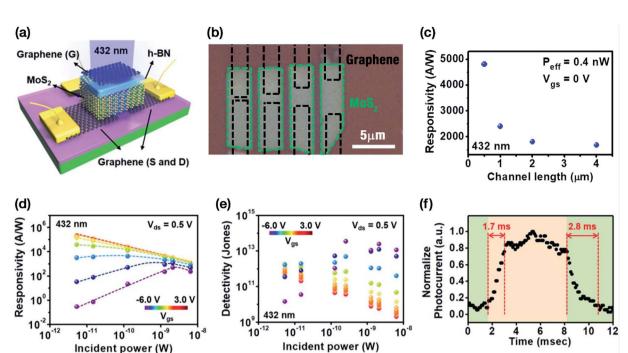


Fig. 23 (a) Schematic illustration of MoS<sub>2</sub> phototransistor with a graphene gate electrode. (b) Optical image showing different MoS<sub>2</sub> channel length. (c) Change of photoresponsivity as a function of MoS<sub>2</sub> channel length at 432 nm laser wavelength, (d) photoresponsivity (e) detectivity of graphene/MoS<sub>2</sub>/graphene heterojunction-based phototransistors as a function of incident laser power intensity at different applied gate bias voltage. (f) Normalized photocurrent as a function of time measured under low intensity light at 80 Hz frequency. Reprinted with permission from ref. 301c, copyright @ American Chemical Society.

injection of electrons and holes from CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> to 2H-MoS<sub>2</sub> as proposed by Kang et al. 192 1T-MoS2/CH3NH3PbI3 hybridbased photodetector showed photoresponsivity of 3096 A W<sup>-1</sup> and EQE value of 7.7  $\times$  10<sup>5</sup>% at 500 nm under laser power density of 37.9 μW cm<sup>-2</sup> whereas 2H-MoS<sub>2</sub>/CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> hybridbased photodetector exhibited comparatively lower photoresponsivity of 142 A  $W^{-1}$  and EQE of 3.5  $\times$  10<sup>4</sup>% at 500 nm under laser power density of 31.3 µW cm<sup>-2</sup>. Multilayered 1T-MoS<sub>2</sub>/CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> hybrid photodetectors exhibited even higher photoresponsivity and EQE, due to the increased conductivity from the thicker multilayers of MoS2. Multilayered 1T-MoS2 and 2H-MoS<sub>2</sub> based photodetectors exhibited detectivity of  $7 \times 10^{11}$ Jones and 2.6  $\times$  10<sup>11</sup> Jones at 0.14  $\mu$ W cm<sup>-2</sup> power density, respectively. This study showed that high photoresponsivity and EQE values can obtained by blending CH<sub>3</sub>NH<sub>3</sub>PbI<sub>3</sub> perovskite with metallic 1T-phase MoS2 nanosheets greater than that of semiconducting 2H-phase MoS2 nanosheets. In another interesting study, Wang et al.325d pointed out that photodetectors based on semiconducting 2H-phase MoS2 show weak photoresponse inspite of their high optical absorption, whereas the metallic 1T-phase MoS<sub>2</sub> exhibit fast carrier transport but suffers from the low photoresponse to visible light. By integrating the positive traits of 2H and 1T phases of MoS2, hybrid phototransistors were developed using a channel consisting of monolayer 2H-phase MoS2 on top of 1T@2H-MoS2 layer. The 1T@2H-MoS2 has metal-like properties due to the lattice matching. The photodetectors developed from vertically stacked 2H-MoS<sub>2</sub>/1T@2H-MoS<sub>2</sub> hybrid structure showed

photoresponsivity of 1917 A  $W^{-1}$ , detectivity of 7.55  $\times$  10<sup>11</sup> Jones, and EQE of value of 448 384% at 532 nm wavelength under an illuminating power of 2.35 mW cm<sup>-2</sup> with applied bias of 20 V due to the existing metallic 1T-phase MoS<sub>2</sub> contents in the metal-like mixture of 1T@2H-MoS2. The very high value of EQE in the 2H-MoS<sub>2</sub>/1T@2H-MoS<sub>2</sub> photodetectors indicated the Schottky barrier modulated operation mechanism. The photoresponsivity, detectivity and EQE values depended on the illuminating power intensity and were found to be varied by few orders of magnitude with different photodetector device structures. The photodetector solely based on monolayer 2H-MoS<sub>2</sub> (without 1T@2H-MoS2 layer) showed comparatively low photoresponse with a photoresponsivity of 56 A W<sup>-1</sup> and detectivity of  $\sim$ 1.3  $\times$  10<sup>11</sup> under the same experimental conditions with source-drain bias voltage of 10 V. Furthermore, the 1T@2H-MoS<sub>2</sub> photodetectors showed extremely low photoresponsivity of 10<sup>-4</sup> A W<sup>-1</sup>, even much lower than that of 2H-MoS<sub>2</sub> photodetectors (56 A W<sup>-1</sup>) under similar experimental conditions. The performance of photodetectors followed the sequence: 2H- $MoS_2/1T@2H-MoS_2 > 2H-MoS_2 > 1T@2H-MoS_2$ . The dramatically high performance of 2H-MoS<sub>2</sub>/1T@2H-MoS<sub>2</sub> photodetectors originated from the higher carrier mobility of the 1T@2H-MoS<sub>2</sub> layer and the synergistic interfacing between 2H-phase MoS2 and mixed 1T@2H-MoS2 layer.

### 5.4 Configuration of MoS<sub>2</sub> heterojunctions

The role of configuration of device heterojunctions has been emphasized for developing high performance

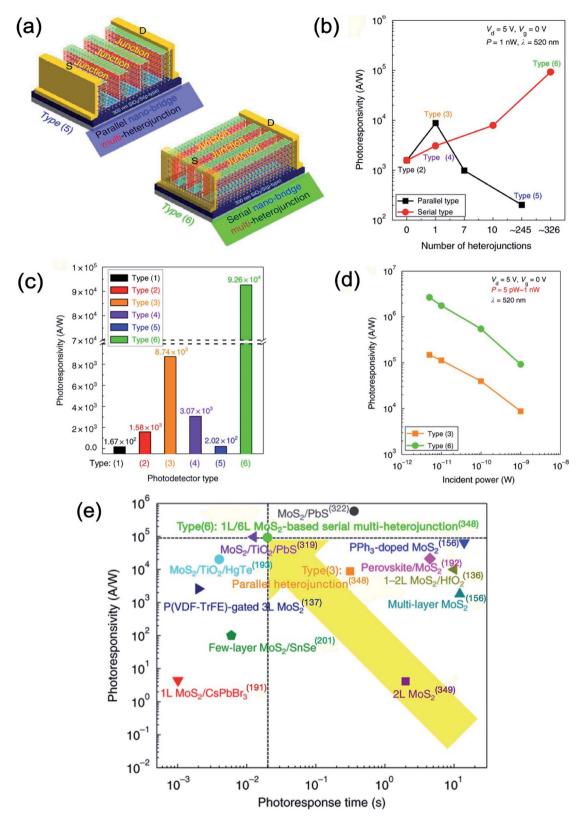


Fig. 24 (a) The schematic diagram of MoS<sub>2</sub> FETs for parallel nano-bridge multi-heterojunction type (5) and serial nano-bridge multi-heterojunction type (6) photodetectors. (b) Photoresponsivity as a function of the number and direction (parallel and serial) of heterojunctions in the MoS<sub>2</sub> channel. (c) The photoresponsivity of type (1) to (6) MoS<sub>2</sub> multi-heterojunctions. (d) Photoresponsivity of type (3) and (6) MoS<sub>2</sub> photodetectors as a function of the incident laser power at 500 nm. (e) A comparison of photoresponsivity and photoresponse time of parallel multi-heterojunction type (3) and serial multi-heterojunction type (6) based MoS<sub>2</sub> photodetectors with previously reported data on MoS<sub>2</sub> photodetectors (see ref. 136, 137, 156, 191–193, 201, 319, 322 and 349). Reprinted with permission from ref. 348, copyright © Springer Nature.

photodetectors. Kim et al.348 reported MoS2 photodetectors using serial nano-bridge multi-heterojunctions. The MoS2 photodetectors based on laser irradiation were assigned as type (1) monolayer, type (2) multilayer, type (3) parallel heterojunction, type (4) serial heterojunction, type (5) parallel nanobridge multi-heterojunction, and type (6) serial nano-bridge multi-heterojunction. Fig. 24 shows a schematic diagram of MoS<sub>2</sub> FETs for parallel nano-bridge multi-heterojunction type (5) and serial nano-bridge multi-heterojunction type (6) photodetectors, photoresponsivity as a function of the number of heterojunctions in the MoS2 channel and the incident laser power as well as their comparison with previously reported data photodetectors. 136,137,156,191-193,201,319,322,349 responsivity of type (2) MoS<sub>2</sub> photodetectors (1.58  $\times$  10<sup>3</sup> A W<sup>-1</sup>) was found to be  $\sim 9.46$  folds higher compared with type (1) photodetectors  $(1.67 \times 10^2 \text{ A W}^{-1})$  because more photocarriers were generated by a greater number of layers and lower exciton binding energy associated with 6L-MoS<sub>2</sub> (0.2 eV). The photoresponsivities of type (3) and type (4) MoS<sub>2</sub> photodetectors were  $8.74 \times 10^3$  A W $^{-1}$  and  $3.07 \times 10^3$  A W $^{-1}$  which were  ${\sim}5.53$  and  $\sim$ 1.94 times higher compared with type (2) photodetectors (1.58  $\times$  10<sup>3</sup> AW<sup>-1</sup>), respectively, arising from the easier electron-hole pair generation. The highest photoresponsivity of 2.67  $\times$  10<sup>6</sup> A  $W^{-1}$  at  $\lambda = 520$  nm and then  $1.65 \times 10^4$  A  $W^{-1}$  at  $\lambda = 1064$  nm were observed for the MoS<sub>2</sub> serial-type heterojunctions with  $\sim$ 326, and monolayer/multilayer (6L) heterojunctions.

The mechanisms of photoconductivity in atomically thin layered MoS<sub>2</sub> has been described by Furchi et al. 349 Sun et al. 350 developed photodetector using multilayer/monolayer MoS2 heterojunction where the source electrodes were connected to the 0.65 nm thick MoS<sub>2</sub> monolayer and the drain electrodes were connected with the 6.9 nm thick MoS2 multilayer and the back gate was heavily p-doped Si. The multilayer/monolayer  $MoS_2$  heterojunction showed photoresponsivity of  $10^3$  A W<sup>-1</sup>, detectivity of  $7 \times 10^{10}$  Jones and photosensitivity of  $1.7 \times 10^5$  at 470 nm. Abnormal photoresponse was noticed under positive gate voltage due to the heterojunction formation. Yan et al. 351 fabricated photodetectors using CVD-grown MoS2 bilayer flakes which showed photoresponsivity of 7160 A W<sup>-1</sup>, detectivity of  $6.62 \times 10^{10}$  Jones and response/recovery times of 97 ms/291 ms, compared to photoresponsivity of 2900 A W<sup>-1</sup> and detectivity of  $2.44 \times 10^{11}$  Jones for the monolayer MoS<sub>2</sub> flakes.

### 5.5 MoS<sub>2</sub>/inorganic semiconductor heterostructures

Gallium nitride (GaN), a wide-bandgap semiconductor, has been used with  ${\rm MoS_2}$  for developing hybrid photodetectors. The self-powered few-layer  ${\rm MoS_2/GaN}$  heterojunction-based deepultraviolet (DUV) photodetector was developed by Zhuo  $et~al.^{316}$  In order to develop a  ${\rm MoS_2/GaN}$  p–n heterojunction photodetector, the  ${\rm MoS_2}$  thin films were transferred onto a GaN substrate where e-beam evaporation method was used to deposit Au electrode on the  ${\rm MoS_2}$  film and Ni/Au electrode on the GaN layer. The  ${\rm MoS_2/GaN}$  photodetector exhibited the current  $I_{\rm on}/I_{\rm off}$  ratio of  $10^5$  at 2.4 mW cm $^{-2}$  and over  $10^3$  at a laser light intensity of 2  $\mu$ W cm $^{-2}$ , indicating the detection of a weak UV light signal under 265 nm laser illumination at zero bias

voltage (0 V) without any external power (self-powered mode). The linear dynamic range (LDR) of 97.3 dB was calculated at zero bias voltage, much better than those of other photodetectors. The rise/fall times were found to be 0.302 ms and 3.605 ms at 100 Hz which further improved at 5 kHz. The MoS<sub>2</sub>/GaN photodetectors exhibited photoresponsivity of 187 mA W<sup>-1</sup>, detectivity of  $2.34 \times 10^{13}$  Jones, fast response speeds of  $46.4 \mu s/$ 114.1 µs at 5 kHz under a DUV light illumination of 265 nm at 0 V bias. Liu et al.317a fabricated ML MoS2-based phototransistor on a transparent GaN wafer using CVD technique. High quality MoS<sub>2</sub>/GaN hybrid films were obtained because of the small thermal expansion coefficient (TEC) mismatch and near lattice match between MoS2 and GaN. The photocurrent MoS2/GaNbased FETs was found to be 3-4 times higher at 405 nm compared with 638 nm arising from high absorption and photocurrent gain process. The value of EQE also increased significantly, from 115% at 638 nm to 5289% at 405 nm. The photoresponsivity of 0.59, 2.78, and 17.2  $AW^{-1}$  was measured at 638, 532, and 405 nm wavelengths under 2 mW laser power, respectively. The response time  $(t_{rise})$  decreased from 4.2 s at 638 nm to 0.1 s at 405 nm. MoS<sub>2</sub>/GaN hybrid-based photodetector showed the maximum photoresponsivity of 17.2 A  $W^{-1}$ , EQE of 5289%, and photocurrent gain of 53.6 at 405 nm under incident laser-power of 2 mW using an applied voltage of 9 V. The specific detectivity and the low noise equivalent power (NEP) varied from  $6.3 \times 10^{10}$  to  $1.8 \times 10^{12}$  Jones and  $2.8 \times 10^{-12}$ to  $9.6 \times 10^{-14}$  W Hz<sup>-1/2</sup> in 405 nm to 638 nm wavelength range, respectively. Li et al.317b demonstrated the improvement of photoresponse of ML MoS<sub>2</sub>/GaN photodetector by depositing 3 nm thick Al<sub>2</sub>O<sub>3</sub> layer on the surface with ALD method. The photocurrent of Al<sub>2</sub>O<sub>3</sub>/MoS<sub>2</sub>/GaN heterostructure-based photodetector increased more than twice compared to MoS<sub>2</sub>/GaN device at 365 nm wavelength under applied voltage of 20 V due to the tensile strain enhancement. The Al<sub>2</sub>O<sub>3</sub>/MoS<sub>2</sub>/GaN photodetector showed over two-fold increase in the photoresponsivity, EQE, and photogain than that of MoS2/GaN photodetector where EQE and photogain values increased from 3848% to 8381% and 239 to 520, respectively.

Indium selenide (InSe) is a well-known photodetector. 352a-d The MoS<sub>2</sub> QDs decorated indium selenide (InSe) nanosheets were applied to develop hybrid phototransistors which yielded the photoresponsivity of  $9.304 \times 10^3$  A W<sup>-1</sup>, three orders  $(10^3)$  of magnitude higher than that of InSe photodetector (12.3 A W<sup>-1</sup>).<sup>336</sup> The higher photoresponsivity of hybrid photodetector originated from the MoS<sub>2</sub> QDs injected photoexcited carriers to the InSe phototransistor. Ulaganathan et al. 353 decorated MoS<sub>2</sub> quantum dots (QDs) with InSe nanosheets to develop hybrid phototransistors. The MoS<sub>2</sub>/InSe-FET showed responsivity of 9304 A W<sup>-1</sup> under illumination at 488 nm at source-drain voltage  $(V_{ds}) = 1$  V and gate voltage  $(V_g) = 0$  V, which was 105 times higher compared to InSe based photodetector (0.101 A  $W^{-1}$  at 532 nm) and nearly 10 times higher compared to 2D-graphene/2D-InSe hybrid photodetector (940 A W<sup>-1</sup> at 532 nm).<sup>352d</sup> Here again, the higher photoresponsivity of MoS<sub>2</sub>/InSe hybrid photodetectors originated due to the transfer of photogenerated charge carriers from MoS2 QDs to the InSe nanosheets. β-In<sub>2</sub>Se<sub>3</sub> is a group IIIA-VIA atomic layered

semiconducting material having a small bandgap, which has been used for developing MoS $_2$  hybrid photodetectors. The few layer  $\beta\text{-In}_2\text{Se}_3$  thin films were epitaxially grown on the top of CVD-MoS $_2$  monolayers by Mahapatra  $et~al.^{354}$  The  $\beta\text{-In}_2\text{Se}_3/\text{MoS}_2$  vdW heterostructure-based photodetectors showed significantly higher photoresponse than that of pure  $\beta\text{-In}_2\text{Se}_3$  photodetectors. The photocurrent of  $\text{In}_2\text{Se}_3/\text{MoS}_2$  hybrid-based devices was found to be 1.3  $\times$  10 $^3$  times higher compared with the dark current at 532 nm under laser power of 8.47  $\mu\text{W}$  and the EQE value reached 5.49  $\times$  10 $^3$ % under laser power of 4 mW cm $^{-2}$  with applied bias.

**RSC Advances** 

Silicon355 has been widely used for developing broadband hybrid photodetectors for communication technology. Guo et al.356 used MoS2/Si heterostructure to fabricate a photodetector showing photoresponsivity of 746 mAW<sup>-1</sup> and detectivity of 6.03  $\times$  10<sup>11</sup> Jones and response/recovery time of 178  $\mu$ s/198 us in the 405 to 980 nm range. In another study, multilayer MoS<sub>2</sub> films were deposited on Si quantum dots (Si QDs) to develop heterojunction photodetectors which showed much faster response/recovery time of 60 ns/756 ns and detectivity of  $6.1 \times 10^{13}$  Jones.<sup>357</sup> Au nanostructure-based plasmonicenhanced multilayer MoS<sub>2</sub> photodetector deposited on p-type Si substrate exhibited photoresponsivity of  $\sim$ 37 A  $W^{-1}$  and detectivity of  $\sim 10^{12}$  Jones in 405–780 nm wavelength range. 358 The photoresponsivity of the Au plasmonic-enhanced MoS<sub>2</sub>/Si photodetector was enhanced by 8.0, 5.3 and 11 times at 405 nm, 650 nm and 780 nm under 5 V bias, respectively, compared to the pristine p-Si photodetector. The Au plasmonic-enhanced MoS<sub>2</sub>/Si photodetector also displayed a fast response time of 1 μs and a recovery time of 18 μs.

The 2D MoS<sub>2</sub>/1D ZnO heterostructure-based photodetectors have been developed to increase the light absorption range and photoresponsivity. The dark current of p-MoS<sub>2</sub>/n-ZnO heterostructure was measured as 0.88 nA which increased significantly to 103.1 nA and 2.52 nA at 365 nm (light intensity of 112 mW cm<sup>-2</sup>) and 532 nm (64 mW cm<sup>-2</sup>) under +5 V of applied voltage, respectively, demonstrating high sensitivity to UV and visible illuminations. The current  $I_{\rm on}/I_{\rm off}$  ratio was found to be 109 at 365 nm and 3.3 at 532 nm. The n-MoS<sub>2</sub>/n-ZnO photodetectors showed the photocurrents of 33.6 nA to 88.2 nA and 0.3 nA to 1.86 nA at 365 nm (5.7 to 47.2 mW cm<sup>-2</sup>) and at 532 nm (0.525 to 56.7 mW cm<sup>-2</sup>), respectively. The p-MoS<sub>2</sub>/n-ZnO photodetectors showed photoresponsivity of 24.36 A W<sup>-1</sup> and EQE of 8.28  $\times$  10<sup>3</sup>% under 365 nm light illumination.

Semimetal cadmium arsenide (Cd $_3$ As $_2$ ) has been used for fabricating broadband photodetectors due to its higher mobility as well as high absorption of light in a broad spectral region. Cd $_3$ As $_2$  nanoplates have been integrated with multilayer MoS $_2$  to develop a heterojunction photodetector which yielded high photoresponsivity of 2.7  $\times$  10 $^3$  A W $^{-1}$  at room temperature. Likely, CdSe nanoplates were vertically assembled on MoS $_2$  monolayer to develop vertical CdSe/MoS $_2$  heterostructures. Heterostructures photodetector exhibited photoresponsivity of 1.63 A W $^{-1}$  and fast response speed of 370  $\mu$ s. In another study, 2D MoS $_2$  nanosheet and 0D CdSe nanocrystal-based hybrid phototransistor were developed which showed substantially enhanced photoresponsivity of 2.5

 $\times$  10<sup>5</sup> A W<sup>-1</sup> and the rise/fall times of 60 ms.<sup>323</sup> The photocurrent of MoS2/CdSe hybrid photodetector increased with increasing laser power intensities at 405 nm. Ghosh et al.364 developed photodetectors using a nanocomposite of single flake MoS<sub>2</sub> and lanthanide doped upconversion nanoparticles (UCNPs). The MoS<sub>2</sub>/UCNPs based photodetector showed highest photoresponsivity of 1254 A W<sup>-1</sup>, detectivity of  $1.05 \times 10^{15}$ Jones and a gain of  $7.12 \times 10^{-4}$  cm<sup>2</sup> V<sup>-1</sup> at 980 nm for 1.0 V bias. The highest detectivity of  $9.0 \times 10^{13}$  Jones at 405 nm and the lowest detectivity of  $3.4 \times 10^{13}$  Jones at 808 nm was observed for MoS<sub>2</sub>/UCNPs devices. Likely, MoS<sub>2</sub>/UCNPs photodetectors showed the highest normalized gain  $(\Gamma_n)$  of  $1.48 \times 10^{-4}$  cm<sup>2</sup> V<sup>-1</sup> at 405 nm and the lowest  $\Gamma_{\rm n}$  of 2.8 imes 10<sup>-5</sup> cm<sup>2</sup> V<sup>-1</sup> at 808 nm laser wavelength, which is an order of magnitude higher compared with those reported for MoS<sub>2</sub> monolayer ( $\Gamma_{\rm n} = 4.8 \times$ 10<sup>-6</sup> cm<sup>2</sup> V<sup>-1</sup>). Multilayer MoS<sub>2</sub> films on monocrystalline SiC substrate using CVD were deposited by Xiao et al. 365 MoS<sub>2</sub>/SiC hybrid photodetector showed photoresponsivity of 5.7 A W<sup>-1</sup> at 365 nm under 4.35 μW incident light power. Instead of Si, Wu et al.366 used Si nanowire arrays (SiNWA) with few-layer MoS2 films to enhanced light absorption region of photodetectors. The dark current of the MoS<sub>2</sub>/SiNWA photodetector was found to be much lower compared with MoS<sub>2</sub>/bulk Si photodetector; contrary to this, the photocurrent of the MoS<sub>2</sub>/SiNWA photodetectors was much increased than that of the MoS2/bulk Si photodetector due to the increased light absorption and contact area between  $MoS_2$  and Si. The  $I_{on}/I_{off}$  current ratio of  $MoS_2/I_{off}$ SiNWA photodetectors varied from  $3.2 \times 10^2$  to  $1.1 \times 10^5$  as the light intensity changed from 0.031 mW cm<sup>-2</sup> to 32 mW cm<sup>-2</sup> under zero bias at 650 nm. The MoS<sub>2</sub>/SiNWA heterojunctionbased photodetector showed photoresponsivity of 53.5 A W<sup>-1</sup>, and detectivity of  $2.8 \times 10^{13}$  Jones under laser power intensity of 6.3 μW cm<sup>-2</sup>, much higher than that of MoS<sub>2</sub>/bulk Si photodetector. 311-313 The rise/fall times of photodetectors was found to decrease with increasing light intensity where the rise times varied from 54.2, 27.7, 23.5 to 22.8 µs, and fall times from 69.9, 68.6, 67.4 to 61.5 μs under laser power intensity of 2.5, 16.8, 24.5 and 38.6 mW cm<sup>-2</sup>, respectively.

Organic/inorganic hybrid halide perovskite (C<sub>6</sub>H<sub>5</sub>C<sub>2</sub>H<sub>4</sub>- $NH_3$ <sub>2</sub> $PbI_4 = (PEA)_2PbI_4$  with ML  $MoS_2$  has been used to develop hybrid photodetectors by Wang et al. 367 (PEA)2PbI4 functions as an electron reservoir to decrease free charge carriers as well as a to passivate defects. The dark current was reduced by six orders of magnitude by depositing (PEA)2PbI4 thin film over MoS<sub>2</sub> photodetector due to the charge transfer from ML MoS<sub>2</sub> to (PEA)<sub>2</sub>PbI<sub>4</sub> thin film. The use of (PEA)<sub>2</sub>PbI<sub>4</sub> over ML MoS<sub>2</sub> reduced the charge carrier density which yielded a broadband photodetector (200 to 900 nm) exhibiting photoresponsivity of 16.8 A W<sup>-1</sup>, detectivity of 1.06  $\times$  10<sup>13</sup> Jones, EQE of 3.3  $\times$  10<sup>3</sup> and on/off ratio of 105. The photoresponse speed of a hybrid photodetector was enhanced over 100-times that of a pristine MoS<sub>2</sub> photodetector due to (PEA)<sub>2</sub>PbI<sub>4</sub> passivation. (PEA)<sub>2</sub>PbI<sub>4</sub>/ MoS2 hybrid photodetectors also work at 0 V bias, which is a self-powered mode where photocurrent showed an increase with increasing laser power intensity from 2.8 nW to 109.8 nW and the rise/decay times of 38 ms/24 ms under 637 nm laser

wavelength. Shen et al.368 synthesized a series of helicene 5,14-diaryldiindeno[2,1-f:1',2'-j]picene (DDP) derivatives namely 5,14-dimesityldiindeno[2,1-f:1',2'-j]picene (1ab), 5,14bis(2,4,6-trimethoxyphenyl)diindeno[2,1-f:1',2'-f]picene 9,10-dimethyl-5,14-dimesityldiindeno[2,1-f:1',2'-j]picene (1bb) and integrated with monolayer MoS2 to develop hybrid photodetectors. Time-resolved measurements showed the interfacial charge-transfer from the DDP derivative to the monolayer MoS<sub>2</sub> confirmed by the stability of exciton property of the (1ac)/MoS2 organics/inorganic hybrid heterostructure. The 1ac/MoS2 hybrid based photodetector showed high photoresponsivity of  $4.99 \times 10^7$  A W<sup>-1</sup> and response time of 45 ms at 633 nm using laser light intensity of 5.75 nW under  $V_d = 5 \text{ V}$  and  $V_g = 0$  V because of the efficient separation of photoexcited carriers and the alignment of type-II energy band. The photoresponsivity of the organic/inorganic hybrid photodetectors followed the sequence of  $(1ac)/MoS_2 > (1ab)/MoS_2 > (1bb)/MoS_2$ as a function of light intensity and after storing for one month. Furthermore, 1ac/MoS2 hybrid photodetector did not exhibit any degradation after one-month storage. MoS2 hybrid heterostructure-based photodetectors have been mainly studied

The MoS<sub>2</sub> atomic layers were also prepared by different methods. Kumar et al.369 developed large-area MoS2 layers using pulsed laser deposition (PLD) method which showed photoresponsivity of 3 imes 10<sup>4</sup> A W<sup>-1</sup> and detectivity of 1.81 imes 10<sup>14</sup> Jones at 365 nm under 24 μW cm<sup>-2</sup> incident light power at applied bias of 2.0 V. The photoresponsivity of the PLD-grown few-layer MoS<sub>2</sub> photodetectors was found to be  $3 \times 10^4$ , 1.08  $\times$  10<sup>4</sup>, 7.0  $\times$  10<sup>3</sup>, and 6.3  $\times$  10<sup>3</sup> A W<sup>-1</sup> at 365, 436, 546, and 655 nm wavelengths under applied bias of 2 V, respectively. FL-MoS<sub>2</sub> photodetectors also showed low dark current of 10<sup>-10</sup> A and photoresponse of  $1.37 \times 10^5$ . Schneider et al.<sup>370</sup> used metalorganic vapor-phase epitaxy (MOVPE) method to develop FL MoS<sub>2</sub> based flexible photodetectors. The photoresponsivity and specific detectivity of MoS2 photodetectors can be changed between 150 A W<sup>-1</sup> to 920 A W<sup>-1</sup> and 10<sup>12</sup> Jones to 10<sup>10</sup> Jones by using electrostatic gating, respectively.

having a type II band alignment.

Singh et al.371 reported Pd/Al2O3/MoS2/ITO photodetector showing photoresponsivity of 488 A  $\mathrm{W}^{-1}$ , detectivity of 8.22  $\times$  $10^{12}$  Jones and EQE of 1.9  $\times$   $10^{5}$ % at 308 nm wavelength under laser light intensity of 13.6 µW/cm<sup>2</sup> with 1 V applied bias voltage. Ye et al.372 demonstrated vertical growth of Sb2O3 flakes on monolayer MoS<sub>2</sub> crystals by using CVD technique. The Sb<sub>2</sub>O<sub>3</sub> flakes of different thickness and size covered monolayer MoS2 crystals in 10, 21, 44, 54 and 100% ratio and their based backgated FETs fabricated on SiO2/Si wafer affected the carrier mobility and subthreshold swing (SS) of the Sb<sub>2</sub>O<sub>3</sub>/MoS<sub>2</sub> hybrid photodetectors. The photocurrent, photoresponsivity, detectivity, sensitivity and EQE of hybrid FETs were measured as a function of laser power intensity under 360, 457, 532, 671, 914, and 1064 nm light illuminations. The hybrid FET-21% exhibited photocurrents of 263 and 2.5 µA at laser power intensities of 177 and 11 mW cm<sup>-2</sup> under 360 and 1064 nm laser illuminations, respectively. The photoresponsivity of  $5.3 \times 10^4 \text{ A W}^{-1}$  and detectivity of  $2.0 \times 10^{15}$  Jones were measured at 457 nm wavelength whereas in the NIR region, Sb<sub>2</sub>O<sub>3</sub>/MoS<sub>2</sub> hybrid

photodetectors showed photoresponsivity of 7.8 A W<sup>-1</sup>, detectivity of  $3.4 \times 10^{11}$  Jones, and response speed of <60 ms with 1064 nm laser wavelength at room temperature. Sb<sub>2</sub>O<sub>3</sub>/MoS<sub>2</sub> hybrid photodetectors (FET-21%) showed photoresponsivity of  $1.1 \times 10^4 \text{ A W}^{-1}$  and detectivity of  $4.5 \times 10^{14}$  Jones under 360 nm laser wavelength. The hybrid FET-21% also showed sensitivity values of  $6 \times 10^2$ ,  $2.5 \times 10^3$ ,  $3 \times 10^3$ ,  $2.4 \times 10^3$ , 0.2, and 0.5 cm<sup>2</sup> W<sup>-1</sup> and EQE values of  $4.0 \times 10^6$ ,  $1.4 \times 10^4$ ,  $1.0 \times 10^6$  $10^4$ , and  $5.5 \times 10^3$ , 0.4, and 0.9% under laser illuminations of 360, 457, 532, 671, 914, and 1064 nm, respectively. Higher photoresponse has been observed in 2D metal NiTe2 and semiconductor MoS<sub>2</sub> heterostructure-based back-gated FETs and photodetectors compared to a pristine MoS<sub>2</sub> monolayer.<sup>373</sup> As discussed earlier, that the MoS2 vdWH-based photodetectors show great promise for pratical applications, therefore, new vdW heterostructures have been targetted. The NiTe2/MoS2 vdW heterostructure-based photodetectors showed several times faster rise/decay times than that of a MoS<sub>2</sub> photodetector due to the epitaxial grown metallic vdWHs. Photodetectors were also developed from the WSe2 and MoS2 vdWHs where MoS2 was used as a channel in the phototransistor.374 The MoS2 vdWHbased phototransistor showed high photoresponsivity of 2700 A W $^{-1}$ , detectivity of 5  $\times$  10 $^{11}$  Jones, and response speed of 17 ms. In these phototransistors, the vertical built-in electric field in the WSe<sub>2</sub>-MoS<sub>2</sub> p-n junction separated the photoexcited charge carriers, which yielded a photoconductive gain of 106. Ying et al.375 fabricated BaTiO3/MoS2 heterostructure-based photodetectors with type I band alignment which showed photoresponsivity of 120 A  $\mathrm{W}^{-1}$  and EQE of 4.78  $\times$  10<sup>4</sup>% compared with 1.7 A W<sup>-1</sup> and 4.5  $\times$  10<sup>2</sup>% for the bare MoS<sub>2</sub> at 365 nm under low laser power intensity of  $0.095 \text{ mW cm}^{-2}$ . Both micro-Raman spectroscopy and photoluminescence indicated the occurrence of carrier extraction and carrier injection processes in the MoS2 layer, leading to the boosting of the number of carriers in the MoS<sub>2</sub> channel. The high performance of type-I hybrid heterostructure-based photodetectors originated from the carrier extraction process between BaTiO<sub>3</sub> NPs and MoS2 layer.

## 5.6 MoS<sub>2</sub> nanoscrolls

MoS<sub>2</sub> nanoscrolls have been prepared by argon plasma treatment of monolayer MoS2 nanosheet where the MoS2 nanoscroll formation also results in a partial removal of sulfur atoms from the top sulfur layer in MoS2.376 The luminescent MoS2 nanoscrolls have also been prepared by the supercritical fluid processing method. The exfoliated MoS2 nanoscrolls showed photoluminescence from 420 to 600 nm due to the size reduction and polydispersity.377 The 1D MoS2 nanoscrolls have been prepared from CVD-grown triangular MoS2 nanosheets where the formation of a MoS<sub>2</sub> nanoscroll takes place from the edge of a triangular nanosheet along the armchair orientation of MoS<sub>2</sub>. The carrier mobility as well as physical contact properties of 1D MoS2 nanoscroll-based FETs were found to be quite different than that of 2D MoS2 nanosheets. The 2D semiconductor MoS2 nanosheets can be transformed into 1D metallic MoS2 nanoscrolls. This demonstrated that 1D TMD-

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based nanoscrolls with unique chemical, physical and electrical properties can be fabricated.

The photodetectors fabricated using MoS<sub>2</sub> or WS<sub>2</sub> nanoscroll were compared with monolayer MoS<sub>2</sub> or WS<sub>2</sub> photodetectors.<sup>379</sup> MoS<sub>2</sub> or WS<sub>2</sub> nanoscroll-based devices showed photosensitivity enhancement by two orders of magnitude, demonstrating the potential of 2D TMD-based 1D nanoscrolls in optoelectronic applications. 1D MoS<sub>2</sub> and WS<sub>2</sub> nanoscroll-based photodetectors exhibited very high photocurrent-to-dark-current ratio compared with 2D nanosheet-based photodetectors. Deng et al. 380 prepared MoS<sub>2</sub> nanoscroll-based photodetectors using the avalanche multiplication effect where a low triggering electrical field is required than that of MoS2 atomic layers. Fig. 25(a-c) shows schematic illustration of MoS<sub>2</sub> nanoscrollbased avalanche photodetectors having MoS2 nanoscroll channel (area of 1.8 µm<sup>2</sup>) connected with source and drain metal electrodes, photoresponsivity and detectivity as a function of applied bias voltage  $(V_{ds})$  under 532 nm laser illumination. Self-assembled MoS2 nanoscrolls were prepared using ethanol droplet and by rolling the monolayer MoS<sub>2</sub> flake. The doped silicon film was used as the substrate as well as a gate electrode. A MoS<sub>2</sub> nanoscroll is formed under strain compared with a monolayer MoS<sub>2</sub> flake, therefore, an analysis of the MoS<sub>2</sub> bandgap was carried out under applied tensile strain. As the uniaxial tensile strain was increased from 0% to 3% for the

monolayer MoS<sub>2</sub> flake, the bandgap of MoS<sub>2</sub> decreased from 1.77 to 1.5 eV, associated to a decrease in avalanche critical electric field  $(E_{ava})$  in MoS<sub>2</sub> nanoscrolls. The avalanche multiplication effect was noticed in MoS2 nanoscrolls which also showed high multiplication factor and impact ionization coefficient. The excess noise factor was measured as a function of the multiplication factor. The multiplication factor of 40 was recorded at  $V_{ds}$  of 45 V which depended on the applied electric field. The avalanche gain of 24 was also measured at  $V_{\rm ds} = 45~{\rm V}$ for the  $MoS_2$  nanoscroll-based devices. The electrical field ( $E_{ava}$ ) to trigger avalanche multiplication in MoS<sub>2</sub> nanoscrolls was found to be dramatically decreased compared with monolayer  $MoS_2$  flakes. The decrease of  $E_{ava}$  in  $MoS_2$  nanoscrolls was associated with several factors including reduced bandgap, substrate contacts and phonons suppressed scattering of the free carriers. The decrease in bandgap of MoS2 nanoscroll was also evidenced by a red-shift compared with the monolayer MoS<sub>2</sub> flake. MoS<sub>2</sub> nanoscroll-based photodetectors exhibiting photoresponsivity over  $10^4$  A W<sup>-1</sup>, detectivity of  $2 \times 10^{12}$  Jones and 30 times higher avalanche gain compared with monolayer MoS<sub>2</sub> flake. This study showed low-power consumption MoS<sub>2</sub> nanoscroll-based photodetections where avalanche multiplication effect enhanced the photoresponsivity in MoS2 nanoscrolls compared with atomically thin monolayer MoS2. Deng et al.381 reported photodiodes having p-type WSe2 and single MoS2

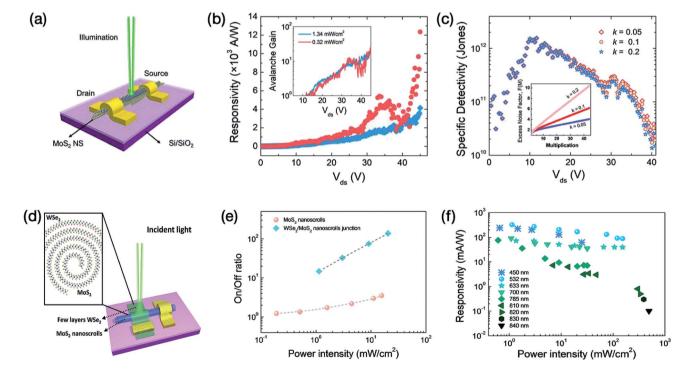


Fig. 25 (a) Schematic illustration of  $MoS_2$  nanoscroll-based avalanche photodetector under illumination. (b) Photoresponsivity of the avalanche photodetector as a function of applied bias voltage ( $V_{ds}$ ) under 532 nm laser illumination at different incident light power intensities. Inset shows the  $V_{ds}$  dependent avalanche gain. (c) Specific detectivity of the avalanche photodetector as a function of  $V_{ds}$ . The inset is a plot of excess noise factor as a function of the multiplication factor. Reprinted with permission from ref. 380, copyright © American Chemical Society. (d) Schematic illustration of the WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based photodiode along with the cross-section of the heterojunction containing MoS<sub>2</sub> nanoscrolls and few layers WSe<sub>2</sub> where electrodes are source and drain, respectively. (e) The current  $I_{on}/I_{off}$  ratio of single MoS<sub>2</sub> nanoscroll and WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based heterojunction as a function of incident power intensity at 532 nm wavelength. (f) Photoresponsivity of the WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based hybrid photodetectors as a function of incident laser power intensity at different wavelengths, showing broadband photodetection by the hybrid heterostructure photodiode. Reprinted with permission from ref. 381, copyright © Wiley.

nanoscrolls which showed suppressed dark current and two orders of magnitude increase in the ratio of photocurrent to dark current compared with a single MoS2 nanoscroll-based photodiode. Fig. 25(d-f) shows schematic illustration of the WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based photodiode, incident power intensity dependent current Ion/Ioff ratio of single MoS2 nanoscroll and WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based heterojunction and photoresponsivity of the WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based hybrid photodetector as a function of incident power intensity. The response speed of WSe2/MoS2 nanoscroll-based device increased by three orders of magnitude than that of a single MoS<sub>2</sub> nanoscroll device. The WSe<sub>2</sub>/MoS<sub>2</sub> nanoscroll-based photodetectors exhibited the photoresponsivity of 0.3 A W<sup>-1</sup>, EQE values of 25% at zero bias voltage and 75% at a reverse bias of 1 V at 532 nm under laser power intensity of 1.14 mW cm<sup>-2</sup> and response speed of 5 ms with laser power intensity of 60 mW cm<sup>-2</sup>. The atomic layered WSe<sub>2</sub>/MoS<sub>2</sub> nanoscrolls were found to be superior to those of MoS<sub>2</sub> nanoscrolls. Wang et al. 382 developed WS<sub>2</sub>/MoS<sub>2</sub> vdWH-based nanoscrolls by dropping aqueous alkaline droplets on CVD-grown BL WS2/MoS2 vdW hybrid heterostructure, which were prepared by growing 1L WS2 islands on top of 1LMoS<sub>2</sub> nanosheets. The optical microscopy, AFM, ultralow frequency (ULF) Raman spectroscopy and TEM techniques were used to characterize the WS<sub>2</sub>/MoS<sub>2</sub> vdWHbased nanoscrolls and ULF breathing and shear mode peaks were observed which originated from the strong interlayer interaction. The photosensitivity of WS2/MoS2 nanoscroll-based photodetectors were found to be ten times higher compared withWS2/MoS2 vdWH-based photodetectors under blue, green and red laser illuminating lights; the ultrafast charge transfer process occurring in nanoscrolled structure at alternative WS<sub>2</sub>/ MoS<sub>2</sub> and MoS<sub>2</sub>/WS<sub>2</sub> multi-interfaces could be associated with such a high performance.

The research data collected on the figure-of-merit of MoS<sub>2</sub> based photodetectors have been extensively documented. Tremendous interest is growing in the field of MoS2 based photodetectors as new research ideas are emerging on a rapid pace.383-387 Ahmed et al.388 fabricated graphene/h-BN/MoS2 trilayer vdW heterostructure-based phototransistors to examine the photogating mechanism where h-BN layer was used as an interfacial barrier to monitor the charge transfer process. Mechanically exfoliated monolayer graphene, MoS2 and multilayer h-BN were used to fabricate the graphene/h-BN/MoS2 vdW heterostructures on the SiO<sub>2</sub>/(p<sup>++</sup>)-Si substrate. All optoelectronic measurements were conducted at 180 K temperature under the high vacuum conditions. The incident power density dependent photoresponsivity, NEP and detectivity of vdW heterostructure-based photodetectors were measured from 640 nm to 1720 nm wavelength region. Fig. 26 shows the figure of merit of the graphene/h-BN/MoS2 vdW heterostructure-based photodetectors. The photoresponsivity values of  $5 \times 10^9$  A W<sup>-1</sup> in the visible region,  $2 \times 10^9$  A W<sup>-1</sup> at 940 nm,  $10^8$  A W<sup>-1</sup> at 1550 nm and  $2 \times 10^7$  A W<sup>-1</sup> at 1720 nm were observed using source drain bias of 20 mV at low power density. The low NEP value of  $2 \times 10^{-20}$  W Hz<sup>-1/2</sup> at 940 nm was found to be further increased to  $2 \times 10^{-18}$  W Hz<sup>-1/2</sup> for 1720 nm. Being correlated to NEP, the high detectivity values of  $10^{16}$  Jones at 640 nm, 5  $\times$  $10^{15}$  Jones at 940 nm and 5  $\times$   $10^{13}$  Jones at 1720 nm were deduced for the vdW hybrid photodetectors, which are two orders of magnitude higher compared to graphene-based IR photodetectors. The values of photoresponsivity, NEP and detectivity for vdWHs differ by several orders of magnitude as a function of laser power density at different measurement wavelengths. This study demonstrated that the defect states can strongly affect to the photoresponse of the graphene/h-BN/MoS<sub>2</sub> hybrid photodetectors. The strong photoresponse has been observed in MoS<sub>2</sub> atomic layers when integrated with other vdW nanomaterials. As summarized in Table 1 and documented throughout this article, MoS2-based photodetectors show photoresponsivity raging from mA W<sup>-1</sup> to 10<sup>10</sup> A W<sup>-1</sup>, detectivity from 107 to 1015 Jones and ultra-fast response speed up to nanoseconds (10<sup>-9</sup> s), which varies by several orders of magnitude over an ultra-broadband spectral range from 265 nm to 10 µm under different incident power densities. The performance of MoS2 photodetectors is derived from the design of MoS<sub>2</sub> based phototransistors, photoconductors and photodiodes. Several different mechanisms including photoconductive, photovoltaic, photobolometric and surface plasma-wave

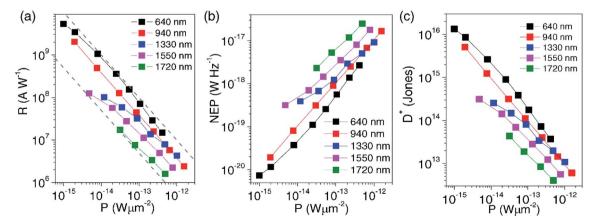


Fig. 26 Figure of merit of the graphene/h-BN/MoS<sub>2</sub> vdW heterostructure-based photodetectors. Plots of (a) photoresponsivity (R), (b) noise equivalent power (NEP) and (c) specific detectivity (D\*) as a function of incident power density (P) in the 640 nm to 1720 nm wavelength region. Reprinted with permission from ref. 388, copyright © Institute of Physics Publishing.

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piezoelectric effect was observed in BP and MoS<sub>2</sub> vdW heterostructures.

enhanced effects contribute to the performance of MoS<sub>2</sub> photodetectors. Abraham and Majumdar<sup>389</sup> analyzed the benchmarking and characterization protocol for photodetectors developed using various types of nanomaterials and pointed out that NEP is one of the most important sensitivity parameters for the figure of merit compared to the photoresponsivity and detectivity. The measurements of NEP as a function of modulation frequency of a photodetector could be used for a better comparison of the figure of merit of heterogeneous photodetectors. The photoresponsivity (R) data were plotted as a function of modulation frequency (f) and NEP for a wide variety of nanomaterial-based photodetectors. Photodetectors with vertical current transport were found to perform much better than photodetectors having lateral current transport as a function of modulation frequency with an exception of graphene-based photodetectors, which is associated with high carrier mobility. However, the measurements of photoresponsivity of these nanomaterials significantly vary depending upon the applied bias voltage and different intensity of laser power; therefore, an accurate comparison is rather convoluted. In the photoresponsivity versus NEP plot, the MoS2-based photodetectors such as monolayer MoS<sub>2</sub> phototransistors, <sup>171</sup> vertical MoS<sub>2</sub> p-n junction, MoS<sub>2</sub>/PbS, graphene/WS<sub>2</sub>/ MoS<sub>2</sub>, <sup>347</sup> etc., are in par with PbS-based photodetectors. <sup>390</sup> The plot of photoresponsivity versus NEP does not show an important correlation between these two parameters and the higher values of photoresponsivity does not inevitably lead to high sensitivity of photodetectors. High sensitivity of a photodetector can be achieved with a relatively low photoresponsivity by controlling the noise of photodetectors.

6. Strain-induced and self-powered MoS<sub>2</sub> photodetectors

Energy harvesting from piezoelectric materials such as ceramics, single crystals, organic polymers and their based hybrid composites has been investigated over many decades. The commonly known piezoelectric materials include lead zirconate titanate (PZT), barium titanate (BaTiO<sub>3</sub>), lithium niobate (LiNbO<sub>3</sub>), zinc oxide (ZnO), quartz, polyvinylidene difluoride (PVDF), poly(vinylidene fluoride-trifluoroethylene) (VPF-TrFE), nylons, liquid crystal polymers, biomaterials, etc. 391-398 The piezoelectric, pyroelectric and ferroelectric materials offer capabilities of generating usable energy under applied mechanical strain, temperature, electric field, water, light, etc. therefore, have been integrated in energy harvesting devices for their applications in self-powering footwears, speakers and headphones, motors, batteries, sensors, actuators, catalysis, photovoltaics, optical memory devices, spintronics, robotics, triboluminescence, etc. 399-402 In addition to silicon, Ge, SiC, ZnO, TiO2, cement, polymers, diamond, and carbon nanotubes, the piezoresistive effects have been studied in 2D nanomaterials403-410 for applications in piezoresistive strain/stress sensors. Black phosphorus (BP) has been used with MoS<sub>2</sub> to develop BP/MoS<sub>2</sub> vdW heterostructure-based photodetectors with a type-II band alignment. 404 The strain induced

Piezoelectric and pyroelectric generators have been developed using different types of inorganic and organic materials for their applications in optoelectronic and photonic devices. Kim et al.411 reported piezoelectric effect in CVD-grown monolayer MoS2 films and fabricated direction-dependent flexible piezoelectric nanogenerators where the atomic orientation in monolayer MoS2 dictated the magnitude of the piezoelectric effect. The output power of nanogenerators (NG) was found to be two times higher for the armchair direction of MoS<sub>2</sub> compared with zigzag direction of MoS2 under the same applied strain and the strain velocity. The armchair MoS2 showed piezoelectric coefficient  $d_{11}$  of 3.78 pm  $V^{-1}$  whereas the zigzag  $MoS_2$  exhibited much lower  $d_{11}$  value of 1.38 pm  $V^{-1}$ . The armchair MoS2 nanogenerator exhibited higher output voltage of 20 mV as well as the higher output current of 30 pA than that of 10 mV and 20 pA for the zigzag MoS2 nanogenerator, confirming the role of atomic orientation in enhancing piezoelectric effect in 1L MoS2 nanogenerators. Tsai et al.412 reported piezoresistive effect in flexible MoS2 FETs which was associated with the strain-induced bandgap change as confirmed using optical reflection spectroscopy. The bandgap of the 3L MoS2 was found to decrease by 0.0 6 eV (from 1.58 eV to 1.52 eV) under 0.2% applied strain. The effects of both piezoelectricity and piezoresistivity on photoresponse of atomic layered MoS<sub>2</sub> have been studied.

Strain-induced photodetection has been observed in MoS<sub>2</sub> atomic layers and MoS2 based hybrid heterostructures. The monolayer MoS2 based photodetector showed photoresponsivity of  $2.3 \times 10^4 \,\mathrm{A} \,\mathrm{W}^{-1}$  under a compressive strain of -0.38% at low laser power intensity of 3.4  $\mu$ W cm<sup>-2</sup> with 442 nm wavelength.264 Gas sensitivity has been reported in 1L MoS<sub>2</sub> via photogating and piezo-phototronic effects. 413 Monolayer MoS2 based flexible homogenous photodiode showed 619% and 319% enhancement in photoresponsivity and detectivity after applying 0.51% tensile strain, where the photoresponsivity and detectivity reached maximum values of 1162 A W<sup>-1</sup> and 1.72 × 10<sup>12</sup> Jones, respectively, compared with a strain-free photodiode.414 The in-plane anisotropic photoresponse has been reported in monolayer MoS2.415 The crystal symmetry of monolayer  $MoS_2$  was found to be reduced from  $D_{3h}$ to  $C_{2v}$  under applied uniaxial tensile strain. The absorption along the armchair direction of monolayer MoS2 was found to be two times higher compared to zigzag direction under 4.5% strain, which also increased with increasing strain, whereas the absorption along zigzag direction of monolayer MoS2 showed a slight change. The photoresponse of monolayer MoS<sub>2</sub> changed from isotropic to anisotropic at 520 nm light illumination. The photoresponse was not observed in monolayer MoS<sub>2</sub> devices until uniaxial tensile strain reached to a value of 3.5% and the anisotropic ratio higher than 2 was recorded under 4.5% uniaxial tensile strain at 520 nm and 830 nm wavelengths.

In another study, the photoresponsivity of flexible  $MoS_2/WSe_2$  heterojunction-based photodiodes increased by 86% under a static strain of -0.62% when applied along the

armchair direction of MoS<sub>2</sub> due to the piezoelectric effect.<sup>416</sup> Similar strain-induced photoresponse has been measured in MoS<sub>2</sub> and ZnO p–n heterojunction photodiodes where photocurrent increased over four times under an applied pressure of 23 MPa.<sup>417</sup> The photoresponsivity of ML MoS<sub>2</sub>/GaN heterojunction photodiodes was also inhanced by 3.5 times under 258 MPa applied pressure originating from strain-induced piezoelectric phenomenon.<sup>418</sup>

The effect of piezoresistivity on performance of MoS<sub>2</sub> photodetectors has also been studied. Li et al.419 reported piezoelectric and piezoresistive effects in a flexible CVD-grown monolayer MoS2/polyethylene naphthalate (PEN) substratebased photodetector. An enhancement of photoresponse such as light-dark current ratio from 29 to 1200.3 (41 times) at 1 V bias voltage and self-powered current from 25.2 to 213.6 pA (8.3 times) was observed in armchair direction monolayer MoS2 after applying 0.8% strain due to the piezoelectric effect. However, the photoresponsivity decreased from 163.9 to 95.7 A W<sup>-1</sup> under 0.8% applied strain at 5 V bias voltage. The photocurrent increased from 0.37 to 2.35 µA and photoresponsivity from 114.3 to W to 590 A W-1 in zigzag direction monolayer MoS<sub>2</sub> under 1.4% applied strain at 5 V due to the piezoresistive effect. The zigzag direction monolayer MoS2 showed no piezoelectric effect. Kelvin probe force microscopy was used to analyze both piezoelectric and piezoresistive effects in monolayer MoS2. Gant et al.420 reported strain-induced increase in both photocurrent and photoresponsivity of flexible monolayer MoS<sub>2</sub> photodetectors. The monolayer MoS<sub>2</sub> based photodetector showed significant increase in photocurrent at 740 nm light illumination under incident power density of 5 mW cm<sup>-2</sup> with 5 V applied bias voltage when tensile biaxial strain was increased from 0.16% to 0.48%. In biaxially strained polycarbonate substrate-based flexible MoS<sub>2</sub> photodetectors, the photoresponsivity increased 100 and 1000 times by increasing applied strains from -0.8% to 0.48% and from -1.44% to 0.48%, respectively.

2D material-based self-powered heterojunction photodetectors are also gaining much attention because no external power is required for the photodetection.421 The self-powered p-MoTe<sub>2</sub>/n-MoS<sub>2</sub> vdWH-based photodetector having ITO electrodes showed photoresponsivity of 146 mA W<sup>-1</sup> and fast photoresponse of  $\sim$ 172 µs from 450 nm to 980 nm. 422 The photodetector also exhibited bidirectional photocurrent response associated with type-II band aligned heterostructure and ITO electrodes. Yang et al. 423 used narrow bandgap layered semiconductor germanium selenide (GeSe) for developing hybrid photodetectors where photoconductive GeSe/graphene photodetectors were compared with photovoltaic GeSe/MoS<sub>2</sub> photodetectors. The photodetector based GeSe/graphene vdWHs showed higher photoresponsivity up to 10<sup>4</sup> A W<sup>-1</sup> under laser light intensity of 0.17 mW cm<sup>-2</sup> at 532 nm whereas the GeSe/MoS<sub>2</sub> heterostructure based photodetector exhibited low photoresponsivity of 0.1 A W<sup>-1</sup> but a faster recovery time of 5 ms compared with 2 s for GeSe/graphene heterostructure. GeSe/MoS<sub>2</sub> photodetector retained constant photoresponse under applied reverse bias because of the reduced carrier conduction within depletion region. Xin et al.424 fabricated

polarization-sensitive self-powered photodetectors using type-II band aligned GeSe/MoS2 vdWHs to increase photoresponse spectrum and support efficient separation as well as transportation of the photoexcited charge carriers. GeSe/MoS<sub>2</sub> p-n heterojunctions were developed using mechanically exfoliated GeSe and MoS<sub>2</sub> nanoflakes on p-doped Si substrate having a SiO<sub>2</sub> film of 300 nm thickness. Fig. 27(a-c) shows a type-II band aligned GeSe/MoS<sub>2</sub> p-n hetero-junction photodetector with Ti/Au electrodes, and time-dependent photoresponse at different illumination wavelengths (UV-NIR region), and photoresponsivity and detectivity of the self-powered GeSe/MoS<sub>2</sub> heterojunction photodetectors as a function of wavelength from 380 to 1064 nm at  $V_{\rm ds}$  of 0 V (zero bias). The self-powered GeSe/  $MoS_2$  photodetector achieved  $I_{on}/I_{off}$  current ratio of 10<sup>4</sup> at zero bias, photoresponsivity of 105 mA W<sup>-1</sup> and EQE of 24.2%. GeSe/ MoS<sub>2</sub> vdWH-based photodetectors showed photoresponse from 380 to 1064 nm and showed maximum photoresponsivity of 590 mA W<sup>-1</sup> at 532 nm wavelength. The photoresponsivity of the self-powered GeSe/MoS<sub>2</sub> p-n heterojunction photodetector varied from 6.1 mA W<sup>-1</sup> to 150 mA W<sup>-1</sup> while the detectivity remained at 10<sup>11</sup> Jones in the 380 nm to 1064 nm (UV-NIR) range. Photoresponse was also measured as a function of polarization angle from 0° to 360° where the current on/off ratios were found to be  $7.23 \times 10^3$ ,  $3.65 \times 10^4$ , and  $2.99 \times 10^3$ at 30°, 90° and 120° polarization angles under 532 nm light illumination with  $V_{\rm ds}$  of 0 V, respectively. The highest photocurrent of  $-3.08~\times~10^{-10}~A$  was recorded at  $90^{\circ}$  and  $270^{\circ}$ polarization angles corresponding to the armchair direction of GeSe which was also a parallel direction of the polarization, whereas the lowest photocurrent of  $-1.04 \times 10^{-10}$  A was measured at 0° and 180° polarization angles which corresponded to the zigzag direction of GeSe. The polarizationsensitive photodetection in the self-powered GeSe/MoS<sub>2</sub> photodetector was observed due to the absorption and anisotropic electronic transport associated with GeSe nanoflakes.

The perovskites have been used with MoS2 to develop organic/inorganic hybrid-based photodiode-solar cell bifunctional devices. Shin et al. 425 used MoS2 as a hole transport layer (HTL) and graphene (GR) co-doped with AuNPs and (trifluoromethanesulfonyl)-amide (co-GR) as transparent conductive electrodes (TCE) to develop flexible p-i-n-type perovskite-based photodiode/solar cell bifunctional devices (PPSBs). Self-powered p-i-n-type PPSB devices were fabricated on both rigid glass and flexible PET substrates. Fig. 27(d-f) shows a diagram of p-i-n-type PPSB device consisting of Al/ BCP/PCBM/MAPbI<sub>3</sub>/MoS<sub>2</sub>/co-GR; energy levels diagram, wavelength-dependent photoresponsivity and detectivity at 0 V bias (self-powered mode), current  $I_{\rm on}/I_{\rm off}$  switching curve at 500 nm and as a function of bending cycles. In the solar cell (photovoltaic) mode under 1 sun illumination (100 mW cm $^{-2}$ ), the PPSB device on a glass substrate showed open-circuit voltage  $(V_{oc})$  of 0.88 V, the short circuit current density  $(I_{sc})$  of 19.97 mA cm $^{-2}$ , a fill factor (FF) of 74.46%, and power conversion efficiency (PCE) of 13.09%. PPSB device also operated without any external power (0 V bias), which is a self-powered mode. The current of the PPSB photodiode was found to increase 10<sup>6</sup> times under illumination in the self-powered mode

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and the photocurrent rise/fall times ranged 0.7–0.9 s and 0.4–0.6 s, respectively. The PPSB photodiode (0 V bias) on a glass substrate showed current  $I_{\rm on}/I_{\rm off}$  ratio of 1310, 9580, 136 110, and 8; and photoresponsivities of 50, 309, 410, and 12 mA W<sup>-1</sup> at 300, 500, 700, and 800 nm, respectively. The noise equivalent power (NEP), detectivity, and linear dynamic range (LDR) were calculated as  $3.95 \times 10^{-12}$  W Hz<sup>-1/2</sup>,  $7.99 \times 10^{10}$  Jones, and 117 dB, respectively. The flexible PPSB-based solar cell showed PCE of 11.91%. The flexible PPSBs also exhibited the similar photoresponse at 500 nm as glass substrate ones. The photoresponsivity and detectivity of the flexible PPSB device were measured between 350 nm to 750 nm where optimum values

reached at 0.39 A W<sup>-1</sup> and 3.41  $\times$  10<sup>10</sup> Jones, respectively. The same research group<sup>426</sup> also developed organic/inorganic perovskites/MoS<sub>2</sub> hybrid-based photodiode–solar cell nanosystems (PPSNs) using BL MoS<sub>2</sub> as the electron-transport layer (ETL) and triethylenetetramine-doped graphene (TETA-GR) as the transparent conductive electrode (TCE). The TETA-GR/MoS<sub>2</sub>/MAPbI<sub>3</sub>/PTAA/Au glass substrate-based rigid and PET substrate-based flexible PPSNs showed photoresponsivity of 0.42 and 0.40 A W<sup>-1</sup>, NEP of 37.2 and 80.1 pW Hz<sup>-1/2</sup>, detectivity of 1.1  $\times$  10<sup>10</sup> and 5.0  $\times$  10<sup>9</sup> Jones in the photodiode mode under zero bias (self-powered), respectively. The PPSNs exhibited the PCE value of 14.27% for rigid device and 12.12% for flexible

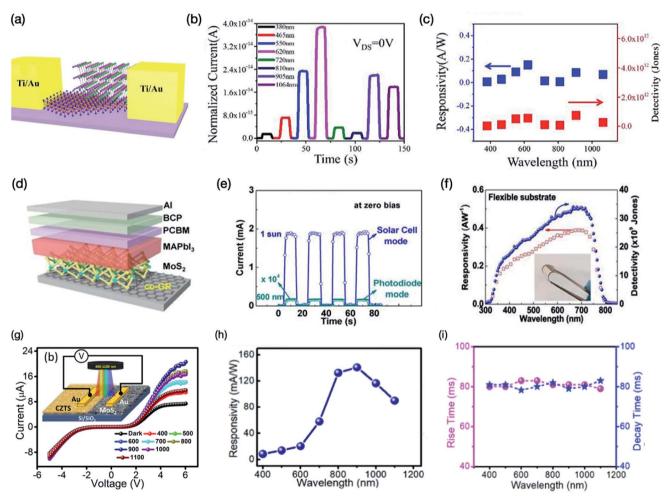


Fig. 27 (a) Schematic illustration of a type-II band aligned GeSe/MoS<sub>2</sub> p-n heterojunction photodetector having Ti/Au electrodes, separation of the photoexcited electrons-holes carriers and energy band diagram under 532 nm light illumination at  $V_{ds}$  of 0 V (zero bias). (b) Time-dependent photoresponse of the heterojunction photodetector under different illumination wavelengths at  $V_{ds}$  = 0 V. (c) Photoresponsivity and detectivity of the GeSe/MoS<sub>2</sub> heterojunction photodetectors as a function of wavelength. Reprinted with permission from ref. 424, copyright © American Chemical Society. (d) Schematic illustration of a self-powered MoS<sub>2</sub> photodetector based on p-i-n-type perovskite photodiode/solar cell bifunctional (PPSB) device consisting of Al/BCP/PCBM/MAPbl<sub>3</sub>/MoS<sub>2</sub>/co-GR; where BCP = bathocuproine, PCBM = phenyl-C<sub>61</sub>-butyric acid methyl ester, MAPbl<sub>3</sub> = methylammonium lead tri-iodide perovskite, co-GR = graphene electrode co-doped with AuNPs and (tri-fluoromethanesulfonyl)-amide. MoS<sub>2</sub> based flexible PPSB photodetector was fabricated using a PET substrate. (e) Current  $I_{on}/I_{off}$  switching behavior of flexible PPSB photodetectors at 500 nm at 0 V bias. (f) Wavelength-dependent photoresponsivity and detectivity of flexible photodetector recorded at 0 V bias, therefore in a self-powered mode. Inset is an optical image of a flexible self-powered PPSB photodetector. Reprinted with permission from ref. 425, copyright © Elsevier; (g) schematic illustration of CZTS/MoS<sub>2</sub> p-n heterojunction-based photodetector and current-voltage (I-V) curves in the dark and at different laser wavelengths (400 nm to 1100 nm) under illumination. (h) Curve of photoresponsivity as a function of wavelength and (i) calculated rise/decay times of the self-powered CZTS/MoS<sub>2</sub> photodetector from 400 nm to 1100 nm wavelengths. Reprinted with permission from ref. 428, copyright © Elsevier.

PPSN device in the photovoltaic mode. PTAA refers to poly[bis(4-phenyl)(2,4,6-trimethylphenyl)amine] which is used as a hole transport material (HTM) in solar cells.

He et al.427 developed broadband self-powered photodetectors using vertically-stacked multilayer GaSe/MoS2 heterostructures where the thickness of GaSe and MoS2 films was 6.3 nm (≈7 L) and 6 nm (≈8 L), respectively. Wavelengthdependent photoresponsivity, EQE, and detectivity of selfpowered GaSe/MoS2 hybrid heterostructure-based photodetectors were measured as a function of wavelength without bias voltage (V = 0). The performance of photodetectors having ohmic-contact ITO electrodes were compared with Schottky-contact Ni/Au electrodes. The GaSe/MoS2 heterostructurebased self-powered photodetectors covered visible to NIR spectral range. Self-powered photodetectors with ITO/GaSe/ MoS<sub>2</sub>/ITO configuration showed a high rectification ratio of 1.5  $\times$  10<sup>4</sup> at  $V_{\rm ds} = \pm 1$  V, EQE value of 160%, photoresponsivity of  $0.67 \text{ A W}^{-1}$ , and detectivity of  $2.3 \times 10^{11}$  Jones at 520 nm and four times faster response time than that of (Ni/Au)/GaSe/MoS<sub>2</sub>/ (Ni/Au) photodetectors indicating the role of electrode-contact in influencing the performance of GaSe/MoS2 hybrid photodetectors. The photoresponsivity of ITO/GaSe/MoS<sub>2</sub>/ITO photodetector was found to be very weak at 808 nm wavelength compared with visible light wavelengths.

Copper zinc tin sulfide (Cu<sub>2</sub>ZnSnS<sub>4</sub>) thin films have been used as absorbing layers in photovoltaic devices. Agrawal et al.428 reported type-II band-alignment by forming a hybrid heterostructure between p-type 3D Cu<sub>2</sub>ZnSnS<sub>4</sub> (CZTS) and n-type 2D MoS<sub>2</sub> which showed significant PL quenching at the heterojunction interface. Fig. 27(g-i) shows a schematic illustration of CZTS/MoS<sub>2</sub> p-n heterojunction photodetector and the current-voltage (I-V) curves in the dark and at different laser wavelengths (400 nm to 1100 nm) under illumination, photoresponsivity and calculated rise/decay times of the self-powered CZTS/MoS2 photodetector from 400 nm to 1100 nm wavelengths. The CZTS/MoS<sub>2</sub> p-n heterojunction-based photodetectors exhibited photovoltaic properties, with a photoresponsivity of 141 mA W<sup>-1</sup>, the current  $I_{\rm on}/I_{\rm off}$ ratio of 112, and fast rise/decay times of 81/79 ms at 900 nm. The CZTS/MoS2 p-n heterojunction photodetector also showed an increase in photoresponsivity to 79 A W<sup>-1</sup> under an applied bias voltage of 6 V and high stability up to 1500 h (62.5 days) of operation. Agrawal et al.429 also developed self-powered photodetector using p-type Cu2ZnSnS4 (CZTS) active electrodes with n-type vertical MoS2 flakes. The CZTS/MoS2 p-n heterojunction photodetector showed photoresponsivity of 49.31 A W<sup>-1</sup> and EQE value of 7.6  $\times$  10<sup>3</sup>% with enhanced photoresponse in visible and NIR region compared with metal electrodes. The heterojunction photodetector showed detectivity of  $3.4 \times 10^{13}$  Jones in NIR and  $2.4 \times 10^{13}$  Jones in visible wavelength region. The photoresponsivity of photodetector with CZTS electrodes was increased by 11 times compared with gold electrodes at 1100 nm (NIR region). Furthermore, the photodetetcor with CZTS electrodes also exhibited long term stability up to 4000 h (166 days).

Self-powered photodetectors were developed using  $MoS_2$  thin film and bulk  $GaAs.^{430}$  The  $MoS_2/GaAs$  heterojunction-based photodetector operated from DUV to NIR spectral region and exhibited photoresponsivity of 35.2 mA  $W^{-1}$ ,

detectivity of 1.96  $\times$  10<sup>13</sup> Jones and rise and fall times of 3.4  $\mu s/$ 15.6 µs at zero bias. These MoS<sub>2</sub>/GaAs heterojunction photodetectors also demonstrated polarization sensitivity to an optical signal with 4.8 ratio between the peak-to-valley. The 0D/ 3D MoS<sub>2</sub> QDs/GaAs heterojunction photodetectors were fabricated using n-type GaAs substrates with varied doping concentrations which resulted in n-n heterojunctions between n-type MoS<sub>2</sub> QDs and bulk n-type GaAs. 431 The MoS<sub>2</sub>/GaAs heterojunction photodetectors operated between 400-950 nm and showed highest photoresponsivity of 400 mA W<sup>-1</sup> and detectivity of  $4 \times 10^{12}$  Jones at 500 nm at zero bias voltage, which is a self-powered photodetection. Shi et al.432 integrated 0D InP@ZnS core-shell QDs with 2D bilayer MoS2 to develop selfpowered hybrid phototransistors by using interdigitated Pt electrodes which acted as light collectors as well as plasmonic resonators. 0D/2D InP@ZnS/MoS2 hybrid photodetectors showed photoresponsivity of 1374 A W<sup>-1</sup> and self-powered properties with a fast photospeed of 21.5 µs. The photoresponsivity of MoS<sub>2</sub> was measured as 222.5 A W<sup>-1</sup> at 532 nm under illuminating power intensity of 34 mW cm<sup>-2</sup> at gate voltage of 40 V, which decreased to 81 A W<sup>-1</sup> as the laser power intensity was increased to 170 mW cm<sup>-2</sup> due to the temperature induced increment in recombination and scattering of carries. The photocurrent of InP@ZnS/MoS2 hybrid phototransistors was enhanced compared to MoS<sub>2</sub> phototransistors as a function wavelength at 447, 532 and 671 nm. The stability of hybrid photodetectors was also examined at 8%, 17%, 25%, 31%, and 42% of humidity at 532 nm illuminating laser light applying 200 Hz frequency without any applied bias voltage. InP@ZnS/ MoS<sub>2</sub> hybrid phototransistor devices exhibited reproducibility over 4000 repeated cycles under 2000 Hz frequency and improved environmental stability over MoS2 phototransistors over a period of three months, indicating the protecting role of InP@ZnS QDs for the MoS2 layer in order to prevent the degradation of photodetectors under ambient environmental conditions.

The self-powered photodetectors were developed using MoS<sub>2</sub>/AlN/Si hybrid heterostructure where MoS<sub>2</sub> thin films were deposited on AlN/Si(111).433 The hybrid photodetector exhibited photoresponse from 300 nm to 1100 nm at 0 V, having the photoresponsivity of 9.93 A W<sup>-1</sup> at 900 nm and rise/decay times of 12.5 μs/14.9 μs. At zero bias, the photoresponsivity of MoS<sub>2</sub>/ AlN/Si hybrid (9.93 A W<sup>-1</sup>) was found to be over five times higher than that of MoS<sub>2</sub>/Si photodetector (1.88 A W<sup>-1</sup>). The oxygen defects in AlN supported the transportation of photogenerated charge carriers in the hybrid photodetector. Selfpowered photodetectors using a vertical MoO<sub>3</sub>/MoS<sub>2</sub> heterojunction434 have been fabricated which showed photoresponsivity of 670 mA  $\mathrm{W}^{-1}$  and detectivity of 4.77  $\times$  10<sup>10</sup> Jones under 0 V bias and current  $I_{\rm on}/I_{\rm off}$  current ratio of  $10^3$ .  $MoS_{2(1-x)}Se_{2x}$  nanostructured alloys have been used for developing photodetectors by atomic-level tailoring. Hou et al.385 used hydrothermal method to prepare  $MoS_{2(1-x)}Se_{2x}$  (x = 0, 0.5,1) nanostructures. The MoSSe alloy-based photodetectors exhibited photocurrent of 12.6 µA, photoresponsivity of 1.753 mA W<sup>-1</sup> and rise/fall times of 4.7 s at 660 nm under laser illumination of 1.75 mW mm<sup>-2</sup>. The photocurrents of MoSSe alloy

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based photodetectors were considerably increased compared with pure MoS2 and MoSe2 based photodetectors. The photoresponsivity of CVD-grown Au/MoS<sub>1,15</sub>Se<sub>0,85</sub>/Au based photodetectors was found to be much higher,  $2.06 \times 10^3$  mA W<sup>-1</sup> at 532 nm with rise/fall times of 18 s/35 s. 386 In another study by Xu et al., 435 the bandgap of  $MoS_{2(1-x)}Se_{2x}$  was tailored between 1.83 eV to 1.73 eV by adjusting the Se composition and thickness within a single domain. The spatially bandgap-graded  $MoS_{2(1-x)}Se_{2x}$ based phototransistors showed responsivity of 191.5 A W<sup>-1</sup>, detectivity of 10<sup>12</sup> Jones, photoconductive gain of 10<sup>6</sup> to 10<sup>7</sup> and response speed of 51 ms under -0.5 V bias voltage. The phototransistor showed photoresponsivity values of 23.2, 191.5, and 26.2 A  $\mathrm{W}^{-1}$  at 405, 650, and 808 nm laser illuminations under -0.5 V bias voltage, respectively. The homojunction phototransistors yielded photoresponsivity of 311 mA W<sup>-1</sup>, detectivity of 10<sup>11</sup> Jones, and the current  $I_{\rm on}/I_{\rm off}$  ratio of 10<sup>4</sup> at 405 nm wavelength under laser power intensity of 1.73 mW mm<sup>-2</sup> for the at zero bias (selfpowered operation)  $MoS_{2(1-x)}Se_{2x}$  phototransistors. Han et al.436 developed a self-driven photodetection device using an MoS<sub>2</sub> nanosheet-based photodetector, a vertical contactseparate mode triboelectric nanogenerator (CS-TENG) as the power source, and LEDs as the alarm system. The mechanism is

based on the impedance matching effect between TENG specific output and the performance of MoS<sub>2</sub> photodetector which is sensitive to visible light. The voltage of TENG is regulated with a Zener diode, the enabling self-powered MoS<sub>2</sub> photodetector to function properly. The MoS2 photodetector exhibited high current  $I_{\rm on}/I_{\rm off}$  ratio of  $1.02 \times 10^4$  and the rise/fall times of 0.32/0.36 s at 405 nm wavelength. Zhao et al.437 developed a surface ionic gate (SIG) transistor using MoS2 monolayer where gas ions are adsorbed by MoS2, which functions as a gate to control the carrier concentration and transport process. The modulation can be adjusted by the TENG operation cycles and the current  $I_{\rm on}/I_{\rm off}$  ratio of  $10^4$  was obtained. In this SIG-based MoS<sub>2</sub> photodetector, the photocurrent recovery time is 74 ms, much faster than devices without SIG modulation. The photocurrent of the SIG-based MoS<sub>2</sub> photodetector was found to increase linearly as a function of time for a period of 120 s, useful for developing a photodetector with luminous flux.

Table 2 summarizes the data collected on the photoresponsivity, detectivity and response/recovery time ( $\tau_{\rm rise}/\tau_{\rm decay}$ ) of self-powered MoS<sub>2</sub> based photodetectors along with their measurement wavelengths and incident laser powers. The strain-induced 2D nanomaterial-based self-powered photodetectors have been reported where piezoelectric effect also plays

Table 2 The performance of self-powered MoS<sub>2</sub> photodetectors in terms of their photoresponsivity, detectivity and response/recovery time  $(\tau_{\text{rise}}/\tau_{\text{decay}})$  along with their measurement wavelength and incident laser power (Jones = cm Hz<sup>1/2</sup> W<sup>-1</sup>)<sup>a</sup>

MoS <sub>2</sub> Photodetector	Conditions (wavelength, incident power)	Photoresponsivity (A $W^{-1}$ )	Detectivity (Jones)	Response time $(\tau_{\rm rise}/\tau_{\rm decay})$	Ref.
RGO-MoS <sub>2</sub> /pyramid Si	$(\lambda = 808 \text{ nm}, 100 \text{ nW})$	21.8	$3.8\times10^{15}$	2.8 μs/46.6 μs	178
p-WSe <sub>2</sub> /n-MoS <sub>2</sub>	$(\lambda = 514 \text{ nm}, 5 \mu\text{W})$	0.04	_	100 μs	123
p-WSe <sub>2</sub> /n-MoS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 7 \mu\text{W})$	0.01	_	1 μs	165
p-GaTe/n-MoS <sub>2</sub>	$(\lambda = 633 \text{ nm}, 100 \text{ mW cm}^{-2})$	1.365	_	10 ms	167
1L MoS <sub>2</sub> /P-Si	$(\lambda = 532 \text{ nm}, 0.95 \text{ mW})$	117	$1  imes 10^9$	74 ms/115 ms	314
MoS <sub>2</sub> /Si (PVD)	$(\lambda = 808 \text{ nm})$	0.21	$10^{13}$	3 μs/40 μs	162
ITO/GaSe/MoS <sub>2</sub> /ITO	$(\lambda = 520 \text{ nm})$	0.67	$2.3 \times 10^{11}$	155 μs/215 μs	427
(Ni/Au)/GaSe/MoS <sub>2</sub> /(Ni/Au)	$(\lambda = 520 \text{ nm})$	0.037	$1.9\times10^{10}$	620 μs/740 μs	427
p-MoTe <sub>2</sub> /n-MoS <sub>2</sub>	$(\lambda = 800 \text{ nm})$	0.038	_	_	205e
p-MoS <sub>2</sub> /n-WS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 28.64 \text{ mW cm}^{-2})$	0.043	$4.36 \times 10^{13}$	4 ms	343
p-GaN nanowires/n-MoS2	$(\lambda = 550 \text{ nm})$	734.5	_	5 ms	258c
(strain)					
p-MoS <sub>2</sub> /n-GaN	$(\lambda = 265 \text{ nm})$	0.187	$2.34 \times 10^{13}$	46.4 $\mu s/114.1 \ \mu s$	316
p-GeSe/n-MoS <sub>2</sub>	$(\lambda = 532 \text{ nm})$	0.105	$1.03 \times 10^{10}$	110 ms/750 ms	424
MoS <sub>2</sub> /CH <sub>3</sub> NH <sub>3</sub> PbI <sub>3</sub>		0.06	_	2149 ms/899 ms	327
p-Cu <sub>2</sub> ZnSnS <sub>4</sub> /n-MoS <sub>2</sub>	$(\lambda = 900 \text{ nm})$	0.141		81 ms/79 ms	
MoS <sub>2</sub> /GaAs	$(\lambda = 780 \text{ nm}, 73 \text{ nW cm}^{-2})$	0.352	$1.96 \times 10^{13}$	$3.4 \ \mu s/15.6 \ \mu s$	430
n-MoS <sub>2</sub> /n-GaAs	$(\lambda = 650 \text{ nm}, 20 \text{ mW cm}^{-2})$	$0.43 \times 10^{-3}$	$2.28\times10^{11}$	1.87 $\mu s/3.53 \ \mu s$	438
$MoS_2/\beta$ - $Ga_2O_3$	$(\lambda = 245 \text{ nm}, 20.1  \mu\text{W cm}^{-2})$	$2.05 \times 10^{-3}$	$1.21\times10^{11}$	_	439
Pd-MoS <sub>2</sub> /Si	$(\lambda = 950 \text{ nm}, 1.0 \text{ mW cm}^{-2})$	0.654	$1.0 \times 10^{14}$	$2.1~\mu s/173.8~\mu s$	440
Pd/Al <sub>2</sub> O <sub>3</sub> /MoS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 0.95 \text{ mW})$	0.308	_	972 ms/878 ms	441
Pd/HfO <sub>2</sub> /MoS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 0.95 \text{ mW})$	0.538	_	969 ms/875 ms	441
Graphene/InSe/MoS <sub>2</sub>	$(\lambda = 532 \text{ nm}, 1.26 \text{ mW cm}^{-2})$	0.11	$1.08\times10^{10}$	1 ms	442
InSe/Se	$(\lambda = 460 \text{ nm}, 1 \text{ mW cm}^{-2})$	0.032	$1.7 \times 10^{11}$	30 ms/37 ms	352 <i>c</i>
$p-Cu_9S_5/n-MoS_2$	$(\lambda = 532 \text{ nm}, 9.36 \text{ mW cm}^{-2})$	76	$1.6 \times 10^{12}$	8 ms/2 ms	443
p-Cu <sub>2</sub> ZnSnS <sub>4</sub> /n-MoS <sub>2</sub>	$(\lambda = 900 \text{ nm}, 1.02 \mu\text{W cm}^{-2})$	0.141	_	81 ms/79 ms	428
Au/p-Cu <sub>2</sub> ZnSnS <sub>4</sub> /n-MoS <sub>2</sub> /Au	$(\lambda = 800 \text{ nm}, 0.43  \mu\text{W cm}^{-2})$	49.31	$2.4 \times 10^{13}$	0.5  s/0.8  s	429
TETA-GR/MoS <sub>2</sub> /MAPbI <sub>3</sub> /PTAA	$(\lambda = 500 \text{ nm})$	0.42	$1.1\times10^{10}$	$1.63 \ \mu s/0.98 \ \mu s$	426
$InP@ZnS/MoS_2$	$(\lambda = 532 \text{ nm}, 34 \text{ mW cm}^{-2})$	$1.3 \times 10^{3}$	_	21.5 μs/133.3 μs	432
$MoS_{2(1-x)}Se_{2x}$	$(405 \text{ nm}, 1.73 \text{ mW mm}^{-2})$	0.311	10 <sup>11</sup>	_	435

<sup>&</sup>lt;sup>a</sup> (TETA-GR): triethylenetetramine-doped graphene, PTAA: poly[bis(4-phenyl)(2,4,6-trimethylphenyl)amine].

an important role. In addition to various MoS2 hybrid heterostructures, MoS2 vdWHs with other 2D atomic layered nanomaterials have also been studied for developing self-powered photodetectors. For example, MoS<sub>2</sub>, <sup>173</sup> MoS<sub>2</sub>-PDPP3T, <sup>189</sup> MoS<sub>2</sub>/ MoTe<sub>2</sub>,<sup>205</sup> MoS<sub>2</sub>/P-Si,<sup>314</sup> MoS<sub>2</sub>/GaN,<sup>316</sup> MoS<sub>2</sub>/perovskite,<sup>327</sup> and MoS<sub>2</sub>/WS<sub>2</sub>,<sup>343</sup> based self-powered photodetectors show high photoresposivity, detectivity, fast photoresponse time and high current  $I_{\rm op}/I_{\rm off}$  ratio. The performance of self-powered MoS<sub>2</sub> photodetectors can be enhanced due to the piezoelectric effect.221,258,272 MoS2 based self-powered broadband photodetectors have been reported for n-MoS<sub>2</sub>/n-GaAs, 438 MoS<sub>2</sub>/β-Ga<sub>2</sub>O<sub>3</sub>,<sup>439</sup> Pd-MoS<sub>2</sub>/Si,<sup>440</sup> Pd/Al<sub>2</sub>O<sub>3</sub>/MoS<sub>2</sub>,<sup>441</sup> Pd/HfO<sub>2</sub>/MoS<sub>2</sub>,<sup>441</sup> graphene/InSe/MoS<sub>2</sub>,  $^{442}$  p-Cu<sub>9</sub>S<sub>5</sub>/n-MoS<sub>2</sub>,  $^{443}$  and MoS<sub>2(1-x)</sub>-Se<sub>2x</sub>.385,386,435 MoS<sub>2</sub> based self-powered photodetectors exhibit photoresponsivity from mA W<sup>-1</sup> to A W<sup>-1</sup>, detectivity from 10<sup>9</sup> to 10<sup>15</sup> Jones and response time from microseconds (µs) to seconds (s), depending on the measurement wavelengths and incident power densities which could be used for healthcare applications.

# 7. Stability of MoS<sub>2</sub> photodetectors

Photodetectors are generally used under harsh working environmental conditions for surveillance including imaging and optical communications; therefore, long-term stability of photodetectors are of immense importance for commercial applications. The environmental stability for extended period of time has been observed in some MoS2 hybrid heterostructurebased photodetectors. 162,187,192 A few examples are discussed here. The detectivity of 10<sup>13</sup> Jones and a fast response speed of 3 μs have been reported for the self-driven visible-NIR MoS<sub>2</sub>/Si heterojunction-based photodetector. 162 These MoS<sub>2</sub>/Si heterojunction photodetectors also showed negligible degradation of photovoltage in air for a period of one month under light illumination at 808 nm. The RGO-MoS<sub>2</sub>/pyramid Si heterojunctionbased photodetectors<sup>178</sup> showed environmental stability over three months of storing in the air under 808 nm and 1550 nm light illuminations due to the synergistic effect of RGO, MoS<sub>2</sub> and the graphene electrodes. Kang et al. 180 measured the stability of APTES-doped MoS<sub>2</sub> photodetectors, which were (i) as-doped, (ii) exposed to the air for 36 h and (iii) for 120 h. The on-current of APTES-doped MoS2 photodetectors was found to decrease by 15% from 273  $\mu A \mu m^{-1}$  to 231  $\mu A \mu m^{-1}$  after air exposing for 36 h and 37% decrease from 273  $\mu$ A  $\mu$ m<sup>-1</sup> to 171  $\mu$ A μm<sup>-1</sup> after air-exposing for 120 h. The environmental stability of various MoS<sub>2</sub> based photodetectors are shown in Fig. 28(a-e). MoS<sub>2</sub>/PDPP3T heterojunction-based self-powered phototransistor showed photodetection from UV (365 nm) to NIR (859 nm) region with photoresponsivity of 276, 445, and 269 mA  $W^{-1}$ and detectivity of  $2.59 \times 10^8$ ,  $3.14 \times 10^8$ , and  $2.53 \times 10^8$  Jones at 365, 660, and 850 nm wavelengths, respectively. 189 Flexible MoS<sub>2</sub>/PDPP3T photodetectors fabricated on the PET substrate were found to be mechanically stable up to 10 000 bending cycles with a little decrease in photocurrent under repeated bending test conducted at a bending radius of 9 mm with 660 nm. Furthermore, MoS<sub>2</sub>/PDPP3T heterojunction photodetectors also exhibited stability in air atmosphere up to 35 days in

dark and light illumination without any encapsulation of devices. Gold chloride hydrate in situ doped MoS2 based photodetectors retained 94% of the initial photocurrent value after a period of nine months, evidencing good environmental stability.337 The stability in air for one month has been measured for the self-driven an MoS<sub>2</sub>/GaAs heterojunction photodetectors when encapsulated with poly(methyl methacrylate) to avoid oxidation.318 High photoresponsivity and detectivity have been measured in MoS2/P(VDF-TrFE) hybrid photodetector where [P(VDF-TrFE)] ferroelectric copolymer was used as a gate. 137 This MoS<sub>2</sub>/P(VDF-TrFE) hybrid photodetector also displayed mechanical stability over 90 000 repeated cycles at incident light power of 100 nW at 635 nm light illumination. The mechanical stability of various flexible MoS2-based hybrid photodetectors including MoS<sub>2</sub>/Kapton and MoS<sub>2</sub>/PET, <sup>217</sup> MoS<sub>2</sub>/  $PI,^{220} MoS_2/graphene,^{233,234} MoS_2-MoS_2/CNT,^{256} MoS_2/WS_2,^{164}$ PEDOT:PSS/PVP/PEDOT:PSS/MoS<sub>2</sub>/ stacked PEN,<sup>219</sup> MoS<sub>2</sub>/perovskite,<sup>76</sup> MoS<sub>2</sub>/Ag nanocubes,<sup>186</sup> and surfacefunctionalized monolayer MoS2 293 have been discussed in details earlier. MoS<sub>2</sub>-based photodetectors display both environmental and mechanical stability for a long period of time against oxidative atmosphere to mechanical testing. Cu<sub>2</sub>-ZnSnS<sub>4</sub>/MoS<sub>2</sub> p-n heterojunction-based self-powered photodetectors showed stability up to 62.5 days of operation. 428 When Cu<sub>2</sub>ZnSnS<sub>4</sub> was used on an active electrode, the self-powered Cu2ZnSnS4/MoS2 photodetetcor exhibited even longer stability up to 166 days. 429 The photoresponse of a rigid p-i-n-type perovskite-based photodiode/solar cell bifunctional device (PPSB) device decreased by 38% after storing for 30 days under 30% humidity at 25 °C compared to 60% degradation of PEDOT:PSS HTL device after 10 days. The flexible PPSB devices showed 43% degradation of their initial photocurrent values after 3000 bending cycles at 4 mm a curvature radius. This demonstrated that use of MoS2 thin film as a HTL in perovskites-based self-powered PPBS devices and for improving their stability<sup>425</sup> The organic/inorganic perovskites/MoS<sub>2</sub> hybrid-based photodiode-solar cell nanosystem (PPSN) rigid device retained over 78% of the initial photoresponsivity after 30 days of storing period in ambient conditions and flexible device retained 80% of the initial photoresponsivity at 600 nm wavelength up to 1000 bending cycles demonstrating strong mechanical stability due to the synergistic effect between TETA-GR electrodes and BL-MoS<sub>2</sub> ETL. 426

# 8. Applications of MoS<sub>2</sub> photodetectors

The photoresponse of  $MoS_2$  photodetectors was also found to increase remarkably by the piezophototronic effect.  $^{226,263,265}$  The photoresponse of  $MoS_2$  photodetectors significantly increases after different types of doping.  $^{183,188,194,325}$  The photoresponsivity, detectivity and photoresponse of atomic layered  $MoS_2$ -based hybrid heterostructured photoconductors range over several orders of magnitude, from mA  $W^{-1}$  to  $10^{10}$  A  $W^{-1}$ ,  $^{122,138,187,199,280}$  from  $10^7$  to  $10^{15}$  Jones  $^{178,301-303}$  and from nano/microseconds to seconds,  $^{163,170,171,304,305}$  over an ultra-broadband spectral range

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varing from DUV wavelength<sup>316</sup> to LWIR,<sup>169,340</sup> respectively. As evident from these summarized data that MoS<sub>2</sub>-based photoconductors show outstanding performance with highest photoresponsivity of 10<sup>10</sup> A W<sup>-1</sup>, the capability of detecting a weak signal up to 10<sup>15</sup> Jones and a very fast photoresponse speed of nanosecond over a broad spectral bandwidth. Marin *et al.*<sup>444</sup> reported the integration of an MoS<sub>2</sub> photodetector with a silicon nitride (Si<sub>3</sub>N<sub>4</sub>) photonic circuit where near-unity lateral absorption was measured that gave rise to a higher photoresponsivity. The speed of the MoS<sub>2</sub> photodetector was found to increase when MoS<sub>2</sub> channel was combined with h-BN substrate. Furthermore, low power operation in MoS<sub>2</sub>

photodetector was also achieved by using graphene gates. Kim et al. 445 proposed the application of the Ge-gated MoS<sub>2</sub> photoconductor for developing a multilevel optic-neural synaptic device. Fig. 29 shows various applications of MoS<sub>2</sub> based ultrabroadband photodetectors. The MoS<sub>2</sub> based photodetectors can be used in a wide range of industrial products operating from DUV to LWIR spectral range that include optical communications, environmental monitoring, chemical and medical sensors, biomedical imaging, remote sensing, lasers, satellites, military, security systems, night vision, smartphones, laptops, computers, Internet-of-Things (IoT), LEDs, data storage, optical microscopy and other next-generation optoelectronic-based

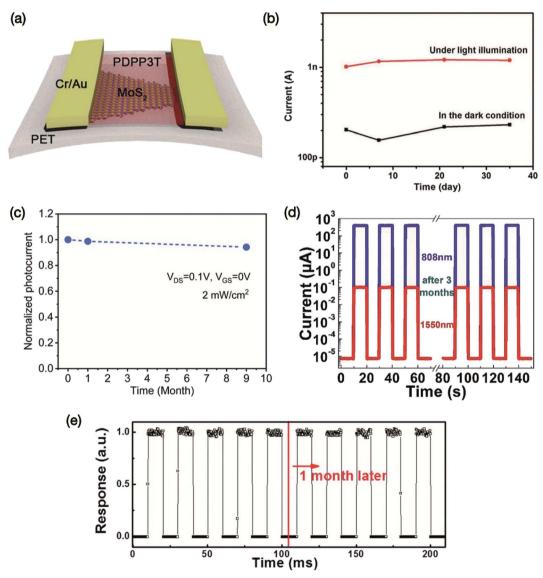


Fig. 28 (a) The schematic of the flexible  $MoS_2/PDPP3T$  photodetector on the PET substrate. (b) Current *versus* time curves in the dark and under 660 nm light illumination when photodetectors were stored in air up to 35 days. Reprinted with permission from ref. 189, copyright © Wiley. (c) The stability of photocurrent of the gold chloride hydrate *in situ* doped  $MoS_2$  photodetector measured over several months where 94% of the initial photocurrent value was retained after nine months. Reprinted with permission from ref. 337, copyright © American Chemical Society. (d) Photoresponse of RGO $-MoS_2/py$ ramid Si heterojunction photodetector measured at 808 and 1550 nm light illumination before and after storing devices in the air for three months. Reprinted with permission from ref. 178, copyright © Wiley. (e) Normalized response of the  $MoS_2/GaAs$  heterojunction-based self-driven photodetector measured after storage in air atmosphere for one month. Reprinted with permission from ref. 318, copyright © Elsevier.

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Fig. 29 Applications of atomic layered MoS<sub>2</sub> based ultra-broadband photodetectors.

devices. Self-powered flexible  $MoS_2$  photodetectors have a great potential in the field of healthcare for their applications in point-of-care wearable biosensors for monitoring vital signs and metabolic parameters, bioimaging, diagnostics, and cardiac pacemakers.

## Conclusions and perspective

The role of 2D TMDs, especially atomic layered MoS<sub>2</sub> and its diverse vdWHs, in developing photodetectors for optoelectronic applications has been discussed, where the photoresponse can be tailored over a broad spectral range from UV to IR regions. The review has particularly summarized the progress made in the design and fabrication of broadband photodetectors using atomic layered MoS2 and MoS2-based hybrid heterostructures for wearable optoelectronics. The performance of MoS2 photodetectors can be dramatically improved and optimized by forming MoS2 hybrid heterowith QDs, 193,194 structures 0Drials, 169,196,226,281,309,329,334-336 ferroelectric polymers, 137,324 halide perovskites, 179,191,192,327 piezo-phototronic effect, 221,258,272 and via chemical doping, 187,326 as has been studied for the phototransistor, photodiode and photoconductor components. The photoresponsivity, detectivity and photoresponse of MoS<sub>2</sub> hybrid heterostructure-based photodetectors vary by several orders of magnitude depending on the nature of the vdWHs, doping agents, optical wavelengths and intensity of applied power. 122,171,178,179,199,226,321,325,326,326 Temperaturedependent ultrahigh photoresponsivities of 5  $\times$  10<sup>8</sup> A W<sup>-1</sup> to  $1 \times 10^{10} \text{ A W}^{-1}$  have been observed for the monolayer graphene/ML MoS<sub>2</sub> hybrid vdWH-based photodetectors. 122 Similarly, an ultrahigh detectivity of  $3.8 \times 10^{15}$  Jones was recorded for the rGO-MoS<sub>2</sub>/pyramid Si hybrid heterostructurebased photodetector, which also operated in the ultrabroadband spectral range of 350 nm to 4.3 µm (UV to MIR)

due to the bandgap narrowing instigated by the sulfur (S) vacancy defects in MoS<sub>2</sub> crystals.<sup>178</sup> The MoS<sub>2</sub> hybrid heterostructure-based photodetectors also exhibit improved environmental stability for extended periods of time.<sup>162,187,192</sup> The flexible photodetectors developed from MoS<sub>2</sub> layers and MoS<sub>2</sub> hybrids with TMDs, graphene, CNTs, and ZnO and their applications in wearable optoelectronics have been discussed. The figures-of-merit of a very wide range of MoS<sub>2</sub>-based photodetectors have been compared in terms of their important parameters including photoresponsivity, detectivity, and response speed measured at different wavelengths and incident laser power densities.

The integration of MoS<sub>2</sub> photodetectors with other flexible electronic, photonic and optoelectronic functional devices remains challenging. Research activities on MoS<sub>2</sub> based photodetectors is emerging on a fast pace. 446-451 The large family of 2D materials can be explored for developing photodetection devices. For example, 2D TMDs such as MoSe<sub>2</sub>, MoTe<sub>2</sub>, WS<sub>2</sub>, WSe<sub>2</sub>, PtS<sub>2</sub>, PtSe<sub>2</sub>, PtTe<sub>2</sub>, PdS<sub>2</sub>, PdSe<sub>2</sub>, PdTe<sub>2</sub>, GeSe<sub>2</sub>, GeSe<sub>2</sub>, HfS<sub>2</sub>, TiS<sub>2</sub>, FeS<sub>2</sub>, CoS<sub>2</sub>, NiS<sub>2</sub>, SnS<sub>2</sub>, MoSe<sub>2</sub>, NbSe<sub>2</sub>, TaSe<sub>2</sub>, NiSe<sub>2</sub>, FeSe<sub>2</sub>, and CoSe<sub>2</sub> can be explored for developing new vdWHs for high-performance photodetectors. Tremendous opportunities exist for TMD-based vdWHs with other nanomaterials, including BP, graphene, h-BN, Janus TMDs, mono-chalcogenide layered materials (GaS, GaSe, GaTe, InS, InSe, InTe, SnS, SnSe, SnTe, PbS, PbTe, etc.), 2D transition-metal carbides, nitrides and carbonitrides (MXenes), transition-metal trichalcogenides (MX<sub>3</sub>; M = Ti, Zr, Hf, Nb, Ta, and X = S, Se, Te), perovskites, surface-functionalized 2D TMDs and transition metal oxides (TMOs), inorganic semiconductors and organic materials, which represent the future direction of TMD-based photodetectors for their application in fields from biomedical imaging to optical communication. TMDs are also advancing as multifunctional materials for future wearable electronic and optoelectronic devices as an inexpensive alternative to the costly manufactured semiconducting materials currently employed in the electronics industry. 2D atomic layered material-based hybrid vdWHs hold great potential for selfpowered flexible photodetectors in the healthcare industry especially for biomedical imaging, point-of-care wearable biosensors for monitoring vital signs and metabolic parameters, cardiac pacemakers, and for patients. There are many significant challenges to producing low-cost, large-scale high-performance photodetector devices for commercial applications, therefore factors such as optimization of the photoresponse, reproducibility, long-term environmental stability of photodetector devices, mechanical flexibility, packaging, and the toxicity of nanomaterials452-460 used in photodetectors need much more attention. TMDs are very promising nanomaterials for developing high-performance flexible photodetectors and for integration of such devices into the next generation of wearable technologies.

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## Conflicts of interest

There are no conflicts to declare.

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